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DESCRIPTION

PYRAZOLE COMPOUNDS AND USE THEREOF IN NOXIOUS ARTHROPOD PESTS CONTROLLING COMPOSITION

5 Technical Field

The present invention relates to pyrazole compounds, their use, and intermediate compounds.

Background art

Various compound have been developed and used for active ingredient of noxious arthropod pests controlling composition.

On the other hand, a certain type of pyrazole compounds is known as a intermediate of medically and pesticidal active compounds, and fungicidally active compounds. See Japanese Laid-Open patent specification No. sho 62-53970A.

Disclosure of Invention

The present invention provides a pyrazole compound of formula (a) (hereinafter, referred as the compound of the present invention):

wherein,

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R¹ represents a hydrogen atom, a C1 to C4 alkyl group or a tifluoromethyl group,

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R² represents a C1 to C4 alkyl group,

R³ represents a hydrogen atom, a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group, a C2 to C6 haloalkenyl group, a C2 to C6 alkynyl group, a C2 to C6 haloalkynyl group, a C1 to C5 hydroxyalkyl group, a C2 to C6 alkoxyalkyl group, a C2 to C6 alkoxyalkyl group, a C2 to C6 alkoxycarbonyl group, a C4 to C6 alkenyloxycarbonyl group, a C4 to C6 haloalkenyloxycarbonyl group, a halogen atom or a cyano group,

R⁴ represents a halogen atom, a C1 to C3 alkyl group, a C1 to C3 alkoxy group, a C1 to C3 haloalkyl group or a C1 to C3 haloalkoxy group,

m represents an integer of 0 to 4 and when m is an integer of 2 to 4, each of \mathbb{R}^4 s may be the same or different,

R⁵ represents a halogen atom, a C1 to C3 alkyl group, a C1 to C3 alkoxy group, a C1 to C3 haloalkyl group or a C1 to C3 haloalkoxy group,

n represents an integer of 0 to 4 and when n is an integer of 2 to 4, each of R^5 s may be the same or different,

each of R^6 and R^7 may be the same or different and represents a hydrogen atom, a halogen atom or a methyl group,

Q represents an oxygen atom, a sulfur atom or a C1 to C5 alkylidene group;

a noxious arthropod pests controlling composition comprising the compound of the present invention as an active ingredient and an inert carrier; and a method for controlling noxious arthropod pests comprising applying an effective amount of the compound of the present invention to noxious arthropod pests or habitat noxious arthropod pests. Furthermore, the present invention also provides a compound of formula (b) (hereinafter, referred as the intermediate compound of the present invention):

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 ${\ensuremath{\mathsf{R}}}^1$ represents a hydrogen atom, a C1 to C4 alkyl group or a tifluoromethyl group,

 ${\ensuremath{\mbox{R}}}^2$ represents a C1 to C4 alkyl group,

R⁶ represents a hydrogen atom, a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group, a C2 to C6 haloalkenyl group, a C2 to C6 alkynyl group, a C2 to C6 haloalkynyl group, a C1 to C5 hydroxyalkyl group, a C2 to C6 alkoxyalkyl group, a C2 to C6 alkoxyalkyl group, a C2 to C6 alkoxycarbonyl group, a C4 to C6 alkenyloxycarbonyl group, a C4 to C6 haloalkenyloxycarbonyl group, a carboxyl group,

15 a halogen atom or a cyano group,

R⁴ represents a halogen atom, a C1 to C3 alkyl group, a C1 to C3 alkoxy group, a C1 to C3 haloalkyl group or a C1 to C3 haloalkoxy group,

m represents an integer of 0 to 4 and when m is an integer of 2 to 4, each of \mathbb{R}^4 s may be the same or different,

R⁵ represents a halogen atom, a C1 to C3 alkyl group, a C1 to C3 alkoxy group, a C1 to C3 haloalkyl group or a C1 to C3 haloalkoxy group,

n represents an integer of 0 to 4 and when n is an integer of 25 2 to 4, each of R⁵s may be the same or different,

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Q represents an oxygen atom, a sulfur atom or a C1 to C5 alkylidene group;

which is useful as an intermediate of the compound of the present invention.

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Mode of Carrying Out the Invention

In the present invention, the description of "a C2 to C6" in "a C2 to C6 alkoxycarbonyl group" or the like means the total number of carbon atoms which constitutes the substituent.

In the compound of the present invention, the C1 to C4 alkyl group represented by R^1 and R^2 includes a methyl group, an ethyl group, a propyl group, anisopropyl group, a butyl group, an isobutyl group, a sec-butyl group and a tert-butyl group.

The C1 to C6 alkyl group represented by R^3 and R^8 includes, 15 for example, a methyl group, an ethyl group, a propyl group, an isopropyl group, a butyl group, an isobutyl group, a sec-butyl group, a pentyl group, an isopentyl group, a neopentyl group, 2-methylbutyl group, 1-methylbutyl group, 1,2-dimethylpropyl group and a hexyl group; 20 the C1 to C6 haloalkyl group includes, for example, a fluoromethyl group, a difluoromethyl group, a trifluoromethyl group, a group, a 2,2,2-trifluoroethyl 2-fluoroethyl 3-fluoropropyl group, a 3,3,3-trifluoropropyl group, group, a 4,4,4-trifluorobutyl 4-fluorobutyl group, 255,5,5-trifluoropentyl group, a 2-chloroethyl group, а 1,2-dichloroethyl group, a 2-bromoethyl group, 1,2-dibromoethyl group, a 3-chloropropyl group, а

3-bromopropyl group, a group, 2,3-dichloropropyl 2,3-dibromopropyl group, a 4-chlorobutyl group, a 4-bromobutyl group, a 5-choloropentyl group, a 5-bromopentyl group, a 6-cholorohexyl group and a 6-bromohexyl group; the C2 to C6 alkenyl group includes, for example, a vinyl group, 5 an allyl group, a 1-propenyl group, an isopropenyl group, a 1-butenyl group, a 2-butenyl group, a 3-butenyl group, a 1-methyl-1-propenyl group, a 1-methyl-2-propenyl group, a 2-methyl-1-propenyl group, a 2-methyl-2-propenyl group, an isobutenyl group, a 1-pentenyl group, a 1-methyl-1-butenyl group, 10 a 1-methyl-2-butenyl group, a 1-methyl-3-butenyl group, a 2-methyl-1-butenyl group, a 2-methyl-2-butenyl group, 2-methyl-3-butenyl group, a 3-methyl-1-butenyl group, 3-methyl-2-butenyl group, a 3-methyl-3-butenyl group, 1,2-dimethyl-1-propenyl group and a 1- hexenyl group; 15 the C2 to C6 haloalkenyl group includes, for example, a 2-chlorovinyl group, a 2,2-dichlorovinyl group, 2-chloro-1-propenyl group, a 3-chloro-2-propenyl group, a 2,3-dichloro-2-propenyl group, a3,3-dichloro-2-propenyl group, 2,2-dibromovinyl group, 20 2-bromovinyl group, a 2-bromo-1-propenyl group, a 3-bromo-2-propenyl group, a 3,3-dibromo-2-propenyl group, a2,3-dichloro-2-propenyl group, 3-chloro-2-butenyl group, 3-chloro-4,4,4-trifuluoro-2-butenyl group, 3-bromo-2-butenyl group, a 3,3,3-trifluoro-1-propenyl group, 25 group and 4,4,4-trifluoro-1-butenyl 5,5,5-trifluoro-2-pentenyl group; the C2 to C6 alkynyl group includes, for example, an ethynyl

group, a 1-propynyl group, a 2-propynyl group, a 1-butynyl group, a 2-butynyl group, a 3-butynyl group, a 1-methyl-2-propynyl group, a 1-pentynyl group, a 2-pentynyl group, a 3-pentynyl group, a 4-pentynyl group and a 4-hexynyl group;

the C2 to C6 haloalkynyl group includes, for example, a 2-chloroethynyl group, a 3-chloro-2-propynyl group, a 4-chloro-3-butynyl group, a 5-chloro-4-pentynyl group, a 6-choloro-5-hexynyl group, a 2-bromoethynyl group, a 3-bromo-2-propynyl group, a 4-bromo-3-butynyl group, a 5-bromo-4-pentynyl group and a 6-bromo-5-hexynyl group; the C1 to C5 hydroxyalkyl group includes, for example, a hydroxymethyl group, a 1-hydroxyethyl group, a 3-hydroxypropyl group, a 2-hydroxyethyl group, a 4-hydroxybuthyl group and a

5-hydroxypentyl group;

- the C2 to C6 alkoxyalkyl group includes, for example, a 15 methoxymethyl group, an ethoxymethyl group, a propoxymethyl group, an isopropoxymethyl group, a buthoxymethyl group, a 1-methoxyethyl group, a penthyloxymethyl group, 2-methoxyethyl group, a 2-ethoxyethyl group, a 2-propoxyethyl group, a 2-isopropoxyethyl group and a 3-ethoxypropyl group; 20 the C2 to C6 alkoxycarbonyl group includes, for example, a ethoxycarbonyl group, an methoxycarbonyl group, isopropoxycarbonyl group, propoxycarbonyl group, an butoxycarbonyl group and a tert-butoxycarbonyl group;
- the C4 to C6 alkenyoxycarbonyl group includes, for example, a 2-propenyloxycarbonyl group, a 1-methyl-2-propenyloxycarbonyl group, a 2-methyl-2-propenyloxycarbonyl group, a 2-butenyloxycarbonyl group, a 1-methyl-2-butenyloxycarbonyl

group.

2-methyl-2-butenyloxycarbonyl а and group group, 3-methyl-2-butenyloxycarbony group; the C4 to C6 haloalkenyoxycarbonyl group includes, for example, 3-chloro-2-propenyloxycarbonyl group, a а 3,3-dichloro-2-propenyloxycarbonyl group, 5 group, 3-chloro-2-butenyloxycarbonyl group, 3-bromo-2-propenyloxycarbonyl 3,3-dibromo-2-propenyloxycarbonyl group and 3-bromo-2-butenyloxycarbonyl group; the halogen atom includes a fluorine atom, a chlorine atom, a 10 bromine atom and an iodine atom. The halogen atom represented by ${\ensuremath{R^4}}$ and ${\ensuremath{R^5}}$ includes a fluorine atom, a chlorine atom, a bromine atom and an iodine atom; the C1 to C3 alkyl group includes a methyl group, an ethyl group, a propyl group and an isopropyl group; 15 the C1 to C3 alkoxy group includes a methoxy group, an ethoxy group, a propoxy group and an isopropoxy group; the C1 to C3 haloalkyl group includes a trifluoromethyl group, a 2-fluoroethyl group, a 2,2,2-trifluoroethyl group, 3,3,3-trifluoropropyl group, a 2-chloroethyl group and a 20 3-bromopropyl group; the C1 to C3 haloalkoxy group includes a trifluoromethoxy group, a 2,2,2-trifluoroethoxy group and a 3,3,3-trifluoropropoxy

The halogen atom represented by R^6 includes a fluorine atom, a chlorine atom, a bromine atom and an iodine atom. The halogen atom represented by R^7 includes a fluorine atom, a chlorine atom, a bromine atom and an iodine atom.

The C1 to C5 alkylidene group represented by Q includes, for example, a methylene group, an ethylene group, a propylidene group, a buthylidene group, a butane-2-ylidene group, a pentane-2-ylidene group and a pentane-3-ylidene group.

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The embodiments of the compound of the present invention are exemplified followings:

the pyrazole compound wherein R^1 is a methyl group or an ethyl group in the formula (a);

the pyrazole compound wherein R^1 is a methyl group or a trifluoromethyl group in the formula (a);

the pyrazole compound wherein R^1 is a methyl group in the formula (a);

the pyrazole compound wherein \mathbb{R}^2 is a methyl group in the formula

15 (a);

the pyrazole compound wherein \mathbb{R}^3 is a hydrogen atom or a cyano group in the formula (a);

the pyrazole compound wherein ${\ensuremath{R}^3}$ is a C1 to C6 alkyl group, a C2 to C6 alkenyl group or a C2 to C6 alkynyl group in the formula

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the pyrazole compound wherein R^3 is a C1 to C6 haloalkyl group, a C2 to C6 haloalkenyl group or a C2 to C6 haloalkynyl group in the formula (a);

the pyrazole compound wherein R³ is a C1 to C6 alkyl group, a C1 to C6 haloalkyl group or a C2 to C6 alkoxycarbonyl group in the formula (a);

the pyrazole compound wherein R^3 is a C2 to C6 alkenyl group, a C2 to C6 haloalkenyl group, a C4 to C6 alkenyloxycarbonyl group

or a C4 to C6 haloalkenyloxycarbonyl group in the formula (a); the pyrazole compound wherein R³ is a C1 to C5 hydroxyalkyl group or a C2 to C6 alkoxyalkyl group in the formula (a);

the pyrazole compound wherein R^3 is a C4 to C6 alkenyloxycarbonyl group or a C4 to C6 haloalkenyloxycarbonyl group in the formula (a);

the pyrazole compound wherein m is an integer 0 in the formula (a);

the pyrazole compound wherein n is an integer 0 in the formula (a);

the pyrazole compound wherein R^6 is a chlorine atom in the formula (a);

the pyrazole compound wherein R^6 and R^7 are chlorine atoms in the formula (a);

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the pyrazole compound wherein R^3 is a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group or a C2 to C6 alkynyl group in the formula (a);

the pyrazole compound wherein ${\ensuremath{\text{R}}}^3$ is a halogen atom in the formula

20 (a);

the pyrazole compound wherein R^1 is a C1 to C4 alkyl group or a trifluoromethyl group in the formula (a);

the pyrazole compound wherein R^1 is a C1 to C4 alkyl group or a trifluoromethyl group, and R^3 is a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group or a C2 to C6 alkynyl group in the formula (a);

the pyrazole compound wherein \mathbb{R}^1 is a C1 to C4 alkyl group or a trifluoromethyl group, and \mathbb{R}^3 is a halogen atom in the formula

(a);

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the pyrazole compound wherein R^1 is a hydrogen atom in the formula (a);

the pyrazole compound wherein R^1 is a hydrogen atom, R^3 is a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group or a C2 to C6 alkynyl group in the formula (a); the pyrazole compound wherein R^1 is a halogen atom, and R^3 is a halogen atom in the formula (a);

the pyrazole compound wherein Q is an oxygen atom in the formula
(a);

the pyrazole compound wherein R^3 is a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group or a C2 to C6 alkynyl group, and Q is an oxygen atom in the formula (a); the pyrazole compound wherein R^3 is a halogen atom, and Q is an oxygen atom in the formula (a);

the pyrazole compound wherein R^1 is a C1 to C4 alkyl group or a trifluoromethyl group, and Q is an oxygen atom in the formula (a);

the pyrazole compound wherein R¹ is a C1 to C4 alkyl group or a trifluoromethyl group, and R³ is a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group or a C2 to C6 alkynyl group, and Q is an oxygen atom in the formula (a); the pyrazole compound wherein R¹ is a C1 to C4 alkyl group or a trifluoromethyl group, and R³ is a halogen atom, and Q is an oxygen atom in the formula (a);

the pyrazole compound wherein R^1 is a hydrogen atom, and Q is an oxygen atom in the formula (a);

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the pyrazole compound wherein R^1 is a hydrogen atom, R^3 is a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group or a C2 to C6 alkynyl group, and Q is an oxygen atom in the formula (a);

the pyrazole compound wherein R¹ is a halogen atom, R³ is a halogen atom, and Q is an oxygen atom in the formula (a);

the pyrazole compound wherein Q is a sulfur atom or a C1 to C5 alkylidene group in the formula (a);

the pyrazole compound wherein R³ is a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group or a C2 to C6 alkynyl group, and Q is a sulfur atom or a C1 to C5 alkylidene group in the formula (a);

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the pyrazole compound wherein R^3 is a halogen atom, and Q is a sulfur atom or a C1 to C5 alkylidene group in the formula (a); the pyrazole compound wherein R^1 is a C1 to C4 alkyl group or a trifluoromethyl group, and Q is a sulfur atom or a C1 to C5 alkylidene group in the formula (a);

the pyrazole compound wherein R^1 is a C1 to C4 alkyl group or a trifluoromethyl group, and R^3 is a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group or a C2 to C6 alkynyl group, and Q is a sulfur atom or a C1 to C5 alkylidene group in the formula (a);

the pyrazole compound wherein R^1 is a C1 to C4 alkyl group or a trifluoromethyl group, and R^3 is a halogen atom, and Q is a sulfur atom or a C1 to C5 alkylidene group in the formula (a); the pyrazole compound wherein R^1 is a hydrogen atom, and Q is a sulfur atom or a C1 to C5 alkylidene group in the formula (a);

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the pyrazole compound wherein R^1 is a hydrogen atom, R^3 is a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group or a C2 to C6 alkynyl group, and Q is a sulfur atom or a C1 to C5 alkylidene group in the formula (a);

the pyrazole compound wherein R^1 is a halogen atom, R^3 is a halogen atom, and Q is a sulfur atom or a C1 to C5 alkylidene group in the formula (a);

the pyrazole compound wherein R^1 is a methyl group or an ethyl group and R^2 is a methyl group in the formula (a); the pyrazole compound wherein R^1 is a methyl group or a trifluoromethyl group and R^2 is a methyl group in the formula (a);

the pyrazole compound wherein R^1 is a methyl group and R^2 is a methyl group in the formula (a);

the pyrazole compound wherein R^1 is a methyl group or an ethyl group and R^6 is a chlorine atom in the formula (a); the pyrazole compound wherein R^1 is a methyl group or a trifluoromethyl group and R^6 is a chlorine atom in the formula (a);

the pyrazole compound wherein R^1 is a methyl group and R^6 is a chlorine atom in the formula (a);

the pyrazole compound wherein R^1 is a methyl group or an ethyl group and R^6 and R^7 are chlorine atoms in the formula (a); the pyrazole compound wherein R^1 is a methyl group or a trifluoromethyl group and R^6 and R^7 are chlorine atoms in the

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formula (a);

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the pyrazole compound wherein R1 is a methyl group and R6 and R^7 are chlorine atoms in the formula (a);

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- the pyrazole compound wherein R1 is a methyl group or an ethyl 5 group and Q is an oxygen atom in the formula (a); the pyrazole compound wherein R^1 is a methyl group or a trifluoromethyl group and Q is an oxygen atom in the formula (a);
- the pyrazole compound wherein ${\ensuremath{R}}^1$ is a methyl group and ${\ensuremath{Q}}$ is an 10 oxygen atom in the formula (a);

the pyrazole compound wherein R¹ is a methyl group or an ethyl group, R^2 is a methyl group, and R^6 is a chlorine atom in the formula (a);

the pyrazole compound wherein ${\boldsymbol{R}}^1$ is a methyl group or a trifluoromethyl group, R^2 is a methyl group, and R^6 is a chlorine atom in the formula (a);

the pyrazole compound wherein R^1 is a methyl group, R^2 is a methyl group, and R⁶ is a chlorine atom in the formula (a);

the pyrazole compound wherein R1 is a methyl group or an ethyl group, R^2 is a methyl group, and R^6 and R^7 are chlorine atoms in the formula (a);

the pyrazole compound wherein R1 is a methyl group or a 25 trifluoromethyl group, R^2 is a methyl group, and R^6 and R^7 are chlorine atoms in the formula (a);

the pyrazole compound wherein R¹ is a methyl group, R² is a methyl

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group, and R^6 and R^7 are chlorine atoms in the formula (a);

the pyrazole compound wherein R^1 is a methyl group or an ethyl group, R^2 is a methyl group, and Q is an oxygen atom in the formula (a);

the pyrazole compound wherein R^1 is a methyl group or a trifluoromethyl group, R^2 is a methyl group, and Q is an oxygen atom in the formula (a);

the pyrazole compound wherein R^1 is a methyl group, R^2 is a methyl group, and Q is an oxygen atom in the formula (a);

the pyrazole compound wherein R^1 is a methyl group or an ethyl group, R^2 is a methyl group, m is an integer 0 and n is an integer 0 in the formula (a);

the pyrazole compound wherein R¹ is a methyl group or a trifluoromethyl group, R² is a methyl group, m is an integer 0 and n is an integer 0 in the formula (a); the pyrazole compound wherein R¹ is a methyl group, R² is a methyl group, m is an integer 0 and n is an integer 0 in the formula (a);

the pyrazole compound wherein R^1 is a methyl group or an ethyl group, R^2 is a methyl group, m is an integer 0, n is an integer 0 and R^6 is a chlorine atom in the formula (a);

the pyrazole compound wherein R^1 is a methyl group or a trifluoromethyl group, R^2 is a methyl group, m is an integer 0, n is an integer 0 and R^6 is a chlorine atom in the formula (a);

the pyrazole compound wherein R^1 is a methyl group, R^2 is a methyl group, m is an integer 0, n is an integer 0 and R^6 is a chlorine atom in the formula (a);

- the pyrazole compound wherein R¹ is a methyl group or an ethyl group, R² is a methyl group, m is an integer 0, n is an integer 0 and Q is an oxygen atom in the formula (a); the pyrazole compound wherein R¹ is a methyl group or a trifluoromethyl group, R² is a methyl group, m is an integer 0, n is an integer 0 and Q is an oxygen atom in the formula (a); the pyrazole compound wherein R¹ is a methyl group, R² is a methyl group, m is an integer 0, n is an integer 0 and Q is an oxygen atom in the formula (a);
- the pyrazole compound wherein m is an integer 0 and n is an integer 0 in the formula (a);
 the pyrazole compound wherein m is an integer 0, n is an integer 0 and R⁶ is a chlorine atom in the formula (a);
 the pyrazole compound wherein m is an integer 0, n is an integer 0 and R⁶ and R⁷ are chlorine atoms in the formula (a);
 the pyrazole compound wherein m is an integer 0, n is an integer 0 and Q is an oxygen atom in the formula (a);
- the pyrazole compound wherein R¹ is a C1 to C4 alkyl group or a tifluoromethyl group, R³ is a hydrogen atom, a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group, a C2 to C6 haloalkenyl group, a C2 to C6 alkynyl group, a C2 to C6 haloalkynyl group, a C1 to C5 hydroxyalkyl group, a C2

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to C6 alkoxyalkyl group, a C2 to C6 alkoxycarbonyl group, a C4 to C6 alkenyloxycarbonyl group, a C4 to C6 haloalkenyloxycarbonyl group or a cyano group and Q is an oxygen atom in the formula (a);

the pyrazole compound wherein R¹ is a methyl group or an ethyl group, R³ is a hydrogen atom, a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group, a C2 to C6 haloalkenyl group, a C2 to C6 alkynyl group, a C2 to C6 haloalkynyl group, a C1 to C5 hydroxyalkyl group, a C2 to C6 alkoxyalkyl group, a C2 to C6 alkoxyalkyl group, a C2 to C6 alkoxycarbonyl group, a C4 to C6 alkenyloxycarbonyl group, a C4 to C6 haloalkenyloxycarbonyl group or a cyano group and Q is an oxygen atom in the formula (a);

the pyrazole compound wherein R¹ is a methyl group or a trifloromethyl group, R³ is a hydrogen atom, a Cl to C6 alkyl group, a Cl to C6 haloalkyl group, a C2 to C6 alkenyl group, a C2 to C6 haloalkenyl group, a C2 to C6 alkynyl group, a C2 to C6 haloalkynyl group, a C1 to C5 hydroxyalkyl group, a C2 to C6 alkoxyalkyl group, a C2 to C6 alkoxyalkyl group, a C4 to C6 alkoxyarbonyl group, a C4 to C6 alkenyloxycarbonyl group, a C4 to C6 haloalkenyloxycarbonyl group or a cyano group and Q is an oxygen atom in the formula (a);

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the pyrazole compound wherein R¹ is a methyl group, R³ is a hydrogen atom, a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 haloalkenyl group, a C2 to C6 alkynyl group, a C2 to C6 haloalkynyl group, a C1 to C5 hydroxyalkyl group, a C2 to C6 alkoxyalkyl group, a C2 to C6 alkoxyalkyl group, a C4 to C6 alkenyloxycarbonyl group, a C4 to C6 haloalkenyloxycarbonyl group or a cyano group and Q is an oxygen

atom in the formula (a);

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the pyrazole compound wherein R^1 is a methyl group or an ethyl group, R^3 is a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group, a C2 to C6 alkynyl group and Q is an oxygen atom in the formula (a);

the pyrazole compound wherein R^1 is a methyl group or a trifluoromethyl group, R^3 is a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group, a C2 to C6 alkynyl group and Q is an oxygen atom in the formula (a);

the pyrazole compound wherein R¹ is a methyl group, R³ is a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group, a C2 to C6 alkynyl group and Q is an oxygen atom in the formula (a);

the pyrazole compound wherein R^1 is a C1 to C4 alkyl group or a trifluoromethyl group, R^3 is a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group, a C2 to C6 alkynyl group and Q is an oxygen atom in the formula (a);

the pyrazole compound wherein R¹ is a C1 to C4 alkyl group or a tifluoromethyl group, R² is a methyl group, R³ is a hydrogen atom, a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group, a C2 to C6 haloalkenyl group, a C2 to C6 alkynyl group, a C2 to C6 haloalkynyl group, a C1 to C5 hydroxyalkyl group, a C2 to C6 alkoxyalkyl group, a C2 to C6 alkoxyalkyl group, a C2 to C6 alkoxycarbonyl group, a C4 to C6 haloalkenyloxycarbonyl group or a cyano group and Q is an oxygen atom in the formula (a);

the pyrazole compound wherein R1 is a C1 to C4 alkyl group or

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a tifluoromethyl group, R³ is a hydrogen atom, a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group, a C2 to C6 haloalkenyl group, a C2 to C6 alkynyl group, a C2 to C6 haloalkynyl group, a C1 to C5 hydroxyalkyl group, a C2 to C6 alkoxyalkyl group, a C2 to C6 alkoxyalkyl group, a C4 to C6 alkoxycarbonyl group, a C4 to C6 alkenyloxycarbonyl group, a C4 to C6 haloalkenyloxycarbonyl group or a cyano group, m is an integer 0, n is an integer 0 and Q is an oxygen atom in the formula (a);

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the pyrazole compound wherein R¹ is a C1 to C4 alkyl group or a tifluoromethyl group, R³ is a hydrogen atom, a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group, a C2 to C6 haloalkenyl group, a C2 to C6 alkynyl group, a C2 to C6 haloalkynyl group, a C1 to C5 hydroxyalkyl group, a C2 to C6 alkoxyalkyl group, a C2 to C6 alkoxyalkyl group, a C4 to C6 alkoxyarbonyl group, a C4 to C6 alkoxycarbonyl group, a C4 to C6 haloalkenyloxycarbonyl group or a cyano group, R⁶ is a chlorine atom and Q is an oxygen atom in the formula (a);

the pyrazole compound wherein R^1 is a C1 to C4 alkyl group or a tifluoromethyl group, R^3 is a hydrogen atom, a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group, a C2 to C6 haloalkenyl group, a C2 to C6 alkynyl group, a C2 to C6 haloalkynyl group, a C1 to C5 hydroxyalkyl group, a C2 to C6 alkoxyalkyl group, a C2 to C6 alkoxyalkyl group, a C4 to C6 alkoxyarbonyl group, a C4 to C6 alkenyloxycarbonyl group, a C4 to C6 haloalkenyloxycarbonyl group or a cyano group, R^6 is a chlorine atom, R^7 is a chlorine atom and Q is an oxygen atom in the formula (a); the pyrazole compound wherein R^1 is a C1 to C4 alkyl group or

a tifluoromethyl group, R³ is a hydrogen atom, a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group, a C2 to C6 haloalkenyl group, a C2 to C6 alkynyl group, a C2 to C6 haloalkynyl group, a C1 to C5 hydroxyalkyl group, a C2 to C6 alkoxyalkyl group, a C2 to C6 alkoxyalkyl group, a C4 to C6 alkoxycarbonyl group, a C4 to C6 alkenyloxycarbonyl group, a C4 to C6 haloalkenyloxycarbonyl group or a cyano group, m is an integer 0, n is an integer 0, R⁶ is a chlorine atom, R⁷ is a chlorine atom and Q is an oxygen atom in the formula (a);

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the pyrazole compound wherein R^1 is a methyl group, R^3 is a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group or a C2 to C6 alkynyl group, m is an integer 0, n is an integer 0 and Q is an oxygen atom in the formula (a);

the pyrazole compound wherein R^1 is a methyl group, R^3 is a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group or a C2 to C6 alkynyl group, R^6 is a chlorine atom, R^7 is a chlorine atom and Q is an oxygen atom in the formula (a); the pyrazole compound wherein R^1 is a methyl group, R^3 is a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group or a C2 to C6 alkynyl group, m is an integer 0, n is an integer 0, R^6 is a chlorine atom, R^7 is a chlorine atom and Q is an oxygen atom in the formula (a).

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The embodiments of the intermediate compound of the present invention are exemplified followings: the compound wherein R^8 is a hydrogen atom, a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group,

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a C2 to C6 haloalkenyl group, a C2 to C6 alkynyl group, a C2 to C6 haloalkynyl group, a C1 to C5 hydroxyalkyl group, a C2 to C6 alkoxyalkyl group, a C2 to C6 alkoxycarbonyl group, a C4 to C6 alkenyloxycarbonyl group, a C4 to C6 haloalkenyloxycarbonyl group or a cyano group in the formula (b);

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the compound wherein R^8 is a C1 to C6 alkyl group, a C2 to C6 alkenyl group or a C2 to C6 alkynyl group in the formula (b); the compound wherein R⁸ is a C1 to C6 haloalkyl group, a C2 to C6 haloalkenyl group or a C2 to C6 haloalkynyl group in the formula

(b); the compound wherein R^8 is a C1 to C6 alkyl group, a C1 to C6 haloalkyl group or a C2 to C6 alkoxycarbonyl group in the formula (b);

the compound wherein R⁸ is a C2 to C6 alkenyl group, a C2 to C6 haloalkenyl group, a C4 to C6 alkenyloxycarbonyl group or a C4 to C6 haloalkenyloxycarbonyl group in the formula (b); the compound wherein R⁸ is a carbxyl group in the formula (b); the compound wherein Q is an oxygen atom in the formula (b); the compound wherein R¹ is a C1 to C4 alkyl group or a tifluoromethyl group, R⁸ is a hydrogen atom, a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group, a C2 to C6 haloalkenyl group, a C2 to C6 alkynyl group, a C2 to C6 haloalkynyl group, a C1 to C5 hydroxyalkyl group, a C2 to C6 alkoxyalkyl group, a C2 to C6 alkoxycarbonyl group, a C4 to C6 alkenyloxycarbonyl group, a C4 to C6 haloalkenyloxycarbonyl group a carboxyl group or a cyano group and Q is an oxygen atom in the formula (b); the compound wherein \mathbb{R}^1 is a C1 to C4 alkyl group or a tifluoromethyl group, R⁸ is a hydrogen atom, a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group, a C2 to C6 haloalkenyl group, a C2 to C6 alkynyl group, a C2 to C6 haloalkynyl group, a C1 to C5 hydroxyalkyl group, a C2 to C6 alkoxyalkyl group, a C2 to C6 alkoxycarbonyl group, a C4 to C6 alkenyloxycarbonyl group, a C4 to C6 haloalkenyloxycarbonyl group or a cyano group and Q is an oxygen atom in the formula (b); the compound wherein R¹is a C1 to C4 alkyl group or a tifluoromethyl group, R⁸ is a carboxyl group and Q is an oxygen atom in the formula (b);

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the compound wherein R¹ is a C1 to C4 alkyl group or a tifluoromethyl group, R⁸ is a C1 to C6 alkyl group, a C2 to C6 alkenyl group or a C2 to C6 alkynyl group and Q is an oxygen atom in the formula (b);

the compound wherein R^1 is a C1 to C4 alkyl group or a tifluoromethyl group, R^8 is C1 to C6 haloalkyl group, C2 to C6 haloalkenyl group or a C2 to C6 haloalkynyl group and Q is an oxygen atom in the formula (b);

the compound wherein R^1 is a C1 to C4 alkyl group or a tifluoromethyl group, R^8 is a C1 to C6 alkyl group, a C1 to C6 haloalkyl group or a C2 to C6 alkoxycarbonyl group and Q is an oxygen atom in the formula (b);

the compound wherein R^1 is a C1 to C4 alkyl group or a tifluoromethyl group, R^8 is a C2 to C6 alkenyl group, a C2 to C6 haloalkenyl group, a C4 to C6 alkenyloxycarbonyl group or a C4 to C6 haloalkenyloxycarbonyl group and Q is an oxygen atom in the formula (b).

The compound of the present invention can be produced

by the following method such as Production Method 1 to Production Method 8.

Production Method 1

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A method of carrying out a reaction of the inetrmediate compound of the present invention, which is shown by the formula (b-x):

wherein R^1 represents a hydrogen atom, a C1 to C4 alkyl group or a tifluoromethyl group,

R² represents a C1 to C4 alkyl group,

R³ represents a hydrogen atom, a C1 to C6 alkyl group, a C1 to C6 haloalkyl group, a C2 to C6 alkenyl group, a C2 to C6 haloalkenyl group, a C2 to C6 alkynyl group, a C2 to C6 haloalkynyl group, a C1 to C5 hydroxyalkyl group, a C2 to C6 alkoxyalkyl group, a C2 to C6 alkoxycarbonyl group, a C4 to C6 alkenyloxycarbonyl group, a C4 to C6 haloalkenyloxycarbonyl group, a halogen atom or a cyano group,

R⁴ represents a halogen atom, a C1 to C3 alkyl group, a C1 to C3 alkoxy group, a C1 to C3 haloalkyl group or a C1 to C3 haloalkoxy group,

m represents an integer of 0 to 4 and when m is an integer of 2 to 4, each of \mathbb{R}^4 s may be the same or different,

R⁵ represents a halogen atom, a C1 to C3 alkyl group, a C1 to C3 alkoxy group, a C1 to C3 haloalkyl group or a C1 to C3 haloalkoxy

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group,

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n represents an integer of 0 to 4 and when n is an integer of 2 to 4, each of R^5 s may be the same or different; and the compound shown by the formula (c)

5 L-CH₂CH=C(\mathbb{R}^6)(\mathbb{R}^7) (c)

wherein each of R^6 and R^7 may be the same or different and represents a hydrogen atom, a halogen atom or a methyl group, and L represents a halogen atom (such as a chlorine atom or bromine atom), methanesulfonyloxy group, benzensulfonyloxy group or toluenesulfonyloxy group.

The reaction is carried out in the presence of a base usually in a solvent.

Examples of the solvents used for the reaction include ketones such as acetone, methyl ethyl ketone and so on; aromatic hydrocarbons such as benzene, toluene, xylene and so on; aliphatic hydrocarbons such as hexane, heptane and so on; ethers ether, tetrahydrofuran, 1,4-dioxane, diethyl as such 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; halogenated hydrocarbons such as chlorobenzene, dichlorobenzene and so on; amides such as N, N-dimethylformamide, N, N-diethylacetamide and and so acetonitrile on; nitriles such on; so dimethylsulfoxide; and the mixture thereof.

Examples of the bases used for the reaction include inorganic bases such as hydroxides of alkali metal or alkaline earth metal (sodium hydroxide, potassium hydroxide, calcium hydroxide and so on), hydrides of alkali metal or alkaline earth metal (sodium hydride, potassium hydride, calcium hydride and so on), carbonates of alkali metal or alkaline earth metal (sodium

carbonate, potassium carbonate and so on); and organic bases such as triethylamine and so on.

The amount of the reagents to be used in the reaction is usually 1 to 3 moles of the compound shown by the formula (c) and 1 to 3 moles of the base based on one mole of the compound shown by the formula (b-x). The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is usually in the range of 0.1 to 24 hours.

After the reaction, the compound of the present invention can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like.

The isolated compound of the present invention can be purified by a technique such as chromatography, recrystallization and the like.

Production Method 2

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A production method of the compound of the present invention, wherein $\ensuremath{\mathbb{R}}^3$ is a cyano group.

The compound of the present invention, which is shown by the formula (d):

wherein R^1 , R^2 , R^4 , R^5 , R^6 , R^7 , Q, m and n have the same meaning as described above;

can be produced by dehydration reaction of the compound shown

by the formula (e):

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wherein R^1 , R^2 , R^4 , R^5 , R^6 , R^7 , Q, m and n have the same meaning as described above.

The reaction is carried out in the presence of a dehydration agent, and without a solvent or in a solvent.

Examples of the solvents used for the reaction include ketones such as acetone, methyl ethyl ketone and so on; aromatic hydrocarbons such as benzene, toluene, xylene and so on; aliphatic hydrocarbons such as hexane, heptane and so on; ethers tetrahydrofuran, 1,4-dioxane, such diethyl ether, 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; halogenated hydrocarbons such as chlorobenzene, dichlorobenzene and so on; amides such as N, N-dimethylformamide, N, N-diethylacetamide and nitriles such acetonitrile and as on; so dimethylsulfoxide; and the mixture thereof.

Examples of the dehydration agents used for the reaction include acid anhydrides such as acetic anhydride and so on.

The amount of the dehydration agent to be used in the reaction is usually 1 mole to excess amount based on one mole of the compound shown by the formula (e). In case of excess amount of dehydration agent based on the compound shown by the formula (e), a solvent may be needless.

The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is usually in the range of 0.1 to 24 hours.

After the reaction, the compound shown by the formula (d) can be isolated, for example, by subjecting the reaction mixture to ordinary post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated compound shown by the formula (d) can be purified by a technique such as chromatography, recrystallization and the like.

10 Production Method 3

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A production method of the compound of the present invention, wherein ${\bf R}^3$ is a group of the formula ${\bf CHR}^9{\bf OH}$

wherein R⁹ is a hydrogen atom or a C1 to C4 alkyl group.

The compound of the present invention, which is shown by the formula (f):

wherein R^1 , R^2 , R^4 , R^5 , R^6 , R^7 , R^9 , Q, m and n have the same meaning as described above;

can be produced by reduction reaction of the compound shown by the formula (g):

wherein R^1 , R^2 , R^4 , R^5 , R^6 , R^7 , R^9 , Q, m and n have the same meaning as described above.

The reaction is carried out in the presence of a reductant usually in a solvent.

Examples of the reductants used for the reaction include sodium borohydride and so on.

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Examples of the solvents used for the reaction include organic solvents selected from alchols such as methanol, ethanol and so on; aromatic hydrocarbons such as benzene, toluene, xylene and so on; aliphatic hydrocarbons such as hexane, heptane and so on; ethers such as diethylether, tetrahydrofuran, 1,4-dioxane, 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; halogenated hydrocarbons such as dichloromethane, chloroform, 1,2-dichloroethane, chlorobenzene, dichlorobenzene and so on; the mixture thereof; and the mixture of water and an organic solvent described above.

The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is usually in the range of 0.1 to 24 hours.

The amount of the reductant to be used in the reaction is, although it is various depend on the reductant to be used, usually 0.25 to 3 moles based on one mole of the compound shown by the formula (g).

After the reaction, the compound shown by the formula (f) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated compound

shown by the formula (f) can be purified by a technique such as chromatography, recrystallization and the like.

Production Method 4

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A production method of the compound of the present invention, wherein ${\rm R}^3$ is a group of the formula ${\rm CHR}^9 {\rm OR}^{10}$

wherein R^9 is the same meaning as described above, R^{10} is a C1 to C5 alkyl group.

The compound of the present invention, which is shown by the formula (h):

$$R^{1}$$
 OR^{10} OR^{10} $OCH_{2}CH=C(R^{6})(R^{7})$ (h) $OCH_{2}CH=C(R^{6})(R^{7})$

wherein R^1 , R^2 , R^4 , R^5 , R^6 , R^7 , R^9 , R^{10} , Q, m and n have the same meaning as described above;

can be produced by the reaction of the compound shown by the formula (g) with the compound shown by the formula ${\it R}^{10}{\it OH}$

wherein \mathbb{R}^{10} have the same meaning as described above; in the presence of an acid and reductant.

The reaction is carried out in a solvent or without a 20 solvent.

Examples of the solvents used for the reaction include organic solvents selected from aromatic hydrocarbons such as benzene, toluene, xylene and so on; aliphatic hydrocarbons such as hexane, heptane and so on; ethers such as diethyl ether,

tetrahydrofuran, 1,4-dioxane, 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; halogenated hydrocarbons such as dichloromethane, chloroform, 1,2-dichloroethane, chlorobenzene, dichlorobenzene and so on; the mixture thereof; and an mixture of water and the organic solvent described above.

Examples of the reductant used for the reaction include sodium borohydride and triethylsilane.

Examples of the acid used for the reaction include inorganic acid such as hydrochloric acid, sulfuric acid and so on; organic acid such as acetic acid, trifluoroacetic acid snd so on.

The amount of reagents to be used in the reaction is usually 1 mole to excess amount of the reductant and 1 mole to excess amount of the alcohol compound shown by the formula

15 R¹⁰OH

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based on one mole of the compound shown by the formula (g).

The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is usually in the range of 0.1 to 24 hours.

After the reaction, the compound shown by the formula

(h) can be isolated, for example, by subjecting the reaction

mixture to post-treatment, such as the reaction mixture is poured

into water, extracted with an organic solvent, the organic layer

is dried and concentrated and the like. The isolated compound

shown by the formula (h) can be purified by a technique such

as chromatography, recrystallization and the like.

Production Method 5

A production method of the compound of the present invention, wherein \mathbb{R}^3 is a group of the formula $\mathbb{R}^9 C = C\left(\mathbb{R}^{12}\right) \left(\mathbb{R}^{13}\right)$

wherein R^9 is the same meaning as described above, each R^{12} and R^{13} is a hydrogen atom or an alkyl group.

The compound of the present invention, which is shown by the formula (k):

wherein R^1 , R^2 , R^4 , R^5 , R^6 , R^7 , R^9 , R^{10} , R^{12} , R^{13} , Q, m and n have the same meaning as described above;

10 can be produced by the reaction of the compound shown by the formula (g) with phosphorus ylide compound shown by the formula (p)

$$(R^{12}) (R^{13}) C=P (C_6H_5)_3$$
 (p)

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wherein ${
m R}^{12}$ and ${
m R}^{13}$ have the same meaning as described above.

The reaction is usually carried out in a solvent.

Examples of the solvents used for the reaction include ethers such as diethyl ether, tetrahydrofuran, 1,4-dioxane, 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; halogenated hydrocarbons such as chlorobenzene, dichlorobenzene and so on; amides such as N,N-dimethylformaide, N,N-dimethylacetamide; nitriles such as acetnitrile; dimethylsulfoxide and the mixture thereof.

The amount of the phosphorus ylide compound shown by the formula (p) to be used in the reaction is usually 1 to 3 moles

based on one mole of the compound shown by the formula (g).

The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is usually in the range of 0.1 to 24 hours.

After the reaction, the compound shown by the formula (k) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated compound shown by the formula (k) can be purified by a technique such as chromatography, recrystallization and the like.

The phosphorus ylide compound by the formula (p) can be produced by the reaction of the compound shown by the formula

15 (r)

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$$(R^{12}) (R^{13}) CHP (C_6H_5)_3Z$$
 (r)

wherein R^{12} and R^{13} have the same meaning as described above, Z represents a halogen atom such as a iodine atom or a bromine atom;

20 with a base.

The reaction is usually carried out in a solvent.

Examples of the solvents used for the reaction include ethers such as diethyl ether, tetrahydrofuran, 1,4-dioxane, 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; halogenated hydrocarbons such as chlorobenzene, dichlorobenzene and so on; amides such as N,N-dimethylformaide, N,N-dimethylacetamide; nitriles such as acetnitrile; dimethylsulfoxide and the mixture thereof.

Example of the bases used for the reaction include hydrides of alkali metal such as sodium hydride and so on; organoalkaline metal compound such as n-butyllithium and so on.

The amount of the base to be used in the reaction is usually $1 \ \mbox{to 3 moles based on one mole of the compound shown by the formula} \ \mbox{(r)} \; .$

The reaction temperature is usually in the range of -78 to 150 $^{\circ}$ C, and the reaction period is usually in the range of 0.1 to 24 hours.

The produced phosphorus ylide compound can be used to the reaction of Production Method 5 without isolation and purification.

Production Method 6

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15 A production method of the compound of the present invention, wherein ${\bf R}^3$ is a guoyp of the formula ${\bf C} \equiv {\bf C} {\bf R}^9$

wherein R9 is the same meaning as described above.

The compound of the present invention, which is shown by the formula (q):

wherein R^1 , R^2 , R^4 , R^5 , R^6 , R^7 , R^9 , Q, m and n have the same meaning as described above;

can be produced by the reaction of the compound shown by the formula (g) with lithium salt of trimethylsilyldiazomethane.

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The reaction is usually carried out in a solvent.

Examples of the solvents used for the reaction include aromatic hydrocarbons such as benzene, toluene, xylene and so on; aliphatic hydrocarbons such as hexane, heptane and so on; ethers such as diethyl ether, tetrahydrofuran, 1,4-dioxane, 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; and the mixture thereof.

The amount of the lithium salt of trimethylsilyldiazomethane to be used in the reaction is usually 1 to 3 moles based on one mole of the compound shown by the formula (g).

The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is usually in the range of 0.1 to 24 hours.

After the reaction, the compound shown by the formula (q) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated compound shown by the formula (q) can be purified by a technique such as chromatography, recrystallization and the like.

Production Method 7

A production method of the compound of the present invention, wherein \mbox{R}^3 is a group of the formula $\mbox{CF}_2\mbox{R}^9$

wherein R9 is the same meaning as described above.

The compound of the present invention, which is shown

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by the formula (Z):

$$R^{1}$$
 $CF_{2}R^{9}$
 Q
 Q
 $CH_{2}CH=C(R^{6})(R^{7})$
 $CF_{2}R^{9}$
 $CF_{2}R^{9}$

wherein R^1 , R^2 , R^4 , R^5 , R^6 , R^7 , R^9 , Q, m and n have the same meaning as described above;

can be produced by the reaction of the compound shown by the formula (g) with fluorination reagent agent such as (dimethylamino) sulfur trifluoride.

The reaction is usually carried out in a solvent.

Examples of the solvents used for the reaction include aromatic hydrocarbons such as benzene, toluene, xylene and so on; aliphatic hydrocarbons such as hexane, heptane and so on; ethers such as diethyl ether, tetrahydrofuran, 1,4-dioxane, 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; halogenated hydrocarbons such as dichloromethane, chloroform, 1,2-dichloroethane, chlorobenzene, dichlorobenzene and so on; nitriles such as acetonitrile and so on; and the mixture thereof.

The amount of the fluorinating reagent to be used in the reaction is usually 1 to 3 moles based on one mole of the compound shown by the formula (g).

The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is usually in the range of 0.1 to 24 hours.

After the reaction, the compound shown by the formula (z) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured

into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated compound shown by the formula (z) can be purified by a technique such as chromatography, recrystallization and the like.

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Production Method 8

A production method of the compound of the present invention, wherein R^3 is a group of the formula $\label{eq:cooch} \text{COOCH}_2\text{CH=C}\left(R^6\right)\left(R^7\right)$

wherein R^6 and R^7 is the same meaning as described above.

The compound of the present invention, which is shown by the formula (aa):

wherein R^1 , R^2 , R^4 , R^5 , R^6 , R^7 , m and n have the same meaning as described above,

can be produced by the reaction of the compound shown by the formula (ab)

$$\begin{array}{c} R^{1} \xrightarrow{COOH} \\ N \cdot N \xrightarrow{Q} O \xrightarrow{L} Q \xrightarrow{L} OH \\ R^{2} \xrightarrow{(R^{4})_{m}} (R^{5})_{n} \end{array} \tag{ab}$$

wherein R^1 , R^2 , R^4 , R^5 , m and n have the same meaning as described above;

with a compound shown by the formula (c) in the presence of a base.

The reaction is carried out in the presence of a base usually in a solvent.

Examples of the solvents used for the reaction include ketones such as acetone, methyl ethyl ketone and so on; aromatic hydrocarbons such as benzene, toluene, xylene and so on; aliphatic hydrocarbons such as hexane, heptane and so on; ethers ether, tetrahydrofuran, 1,4-dioxane, such diethyl 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; halogenated hydrocarbons such as chlorobenzene, dichlorobenzene and so on; amides such as N, N-dimethylformamide, N, N-diethylacetamide and acetonitrile and so on; such as so on; nitriles dimethylsulfoxide; and the mixture thereof.

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Examples of the bases used for the reaction include inorganic bases such as hydroxides of alkali metal or alkaline earth metal (sodium hydroxide, potassium hydroxide, calcium hydroxide and so on), carbonates of alkali metal or alkaline earth metal (sodium carbonate, potassium carbonate and so on); and organic bases such as triethylamine and so on.

The amount of the reagents to be used in the reaction is usually 2 to 4 moles of the compound shown by the formula (c) and 2 to 5 moles of the base based on one mole of the compound shown by the formula (ab). The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is usually in the range of 0.1 to 24 hours.

After the reaction, the compound shown by the formula (aa) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like.

The isolated compound shown by the formula (aa) can be

purified by a technique such as chromatography, recrystallization and the like.

Next, the intermediate compound of the present invention are described following.

The intermediate compound of the present invention shown by the formula (b) can be produced, for example, by the reaction of the compound shown by the formula (s):

$$R^1$$
 R^8
 R^2
 R^2
 R^3
 R^2

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wherein R^1 , R^2 and R^8 have the same meaning as described above; with the compound shown by the formula (t):

$$HO \xrightarrow{} Q \xrightarrow{} Q \xrightarrow{} OH$$
 (t)

wherein R^4 , R^5 , Q, m and n have the same meaning as described above.

The reaction is carried out in the presence of a base usually in a solvent.

Examples of the solvents used for the reaction include aromatic hydrocarbons such as toluene, xylene and so on; aliphatic hydrocarbons such as hexane, heptane and so on; ethers such as diethyl ether, tetrahydrofuran, 1,4-dioxane, 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; amides such as N,N-dimethylformamide, N,N-diethylacetamide and so on; dimethylsulfoxide; and the mixture thereof.

Examples of the bases used for the reaction include

inorganic bases such as hydroxides of alkali metal or alkaline earth metal (sodium hydroxide, potassium hydroxide, calcium hydroxide and so on), hydrides of alkali metal or alkaline earth metal (sodium hydride, potassium hydride, calcium hydride and so on), carbonates of alkali metal or alkaline earth metal (sodium carbonate, potassium carbonate and so on); and organic bases such as triethylamine and so on.

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The amount of the reagents to be used in the reaction is usually 0.5 to 3 moles of the compound shown by the formula (t) and 1 to 3 moles of the base based on one mole of the compound shown by the formula (s). The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is usually in the range of 0.1 to 24 hours.

The reaction may be carried out in the presence of a catalyst such as copper or copper(I) chloride, if necessary. The amount of the catalyst to be used in the reaction is 0.01 to 0.2 moles based on one mole of the compound shown by the formula (s).

After the reaction, the intermediate compound of the present invention shown by the formula (b) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated intermediate compound of the present invention shown by the formula (b) can be purified by a technique such as chromatography, recrystallization and the like.

In case of the compound shown by the formula (t) is

unsymmetrical, the intermediate compound of the present invention shown by the formula (b) can be produced by protecting one of the two phenolic hydroxy group in the compound shown by the formula (t) with an appropriate protecting group (such as benzyl, tert-butyldimethylsilylandmethoxymethyl), subjecting with the reaction described above, and removing the protecting group.

The intermediate compound of the present invention, which is shown by the formula (b-1):

wherein R^1 , R^2 , R^4 , R^5 , R^9 , R^{12} , R^{13} , Q, m and n have the same meaning as described above;

can be produced by the reaction of the compound shown by the formula (u)

wherein R^1 , R^2 , R^4 , R^5 , R^9 , Q, m and n have the same meaning as described above;

with with phosphorus ylide compound shown by the formula (p).

The reaction is usually carried out in a solvent.

Examples of the solvents used for the reaction include 20 ethers such as diethyl ether, tetrahydrofuran, 1,4-dioxane,

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1,2-dimethoxyethane, 1,2-diethoxyethane and so on; halogenated hydrocarbons such as chlorobenzene, dichlorobenzene and so on; amides such as N,N-dimethylformaide, N,N-dimethylacetamide; nitriles such as acetnitrile; dimethylsulfoxide and the mixture thereof.

The amount of the phosphorus ylide compound shown by the formula (p) to be used in the reaction is usually 2 to 4 moles based on one mole of the compound shown by the formula (u).

The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is usually in the range of 0.1 to 24 hours.

After the reaction, the compound shown by the formula (b-1) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated compound shown by the formula (b-1) can be purified by a technique such as chromatography, recrystallization and the like.

The intermediate compound of the present invention, which is shown by the formula (b-2):

$$R^{1}$$
 R^{10}
 $R^$

wherein R^1 , R^2 , R^4 , R^5 , R^9 , R^{12} , R^{13} ; Q, m and n have the same meaning as described above;

can be produced by the catalytic hydrogenation of the compound

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shown by the formula (b-1) in the presence of transition metal catalyst such as palladium-carbon.

The reaction is usually carried out in a solvent.

Examples of the solvents used for the reaction include ketones such as acetone, methyl ethyl ketone, and so on; alcohols such as methanol, ethanol and so on; aromatic hydrocarbons such as benzene, toluene, xylene and so on; aliphatic hydrocarbons such as hexane, heptane and so on; ethers such as diethyl ether, tetrahydrofuran, 1,4-dioxane, 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; halogenated hydrocarbons such as chlorobenzene, dichlorobenzene and so on; amides such as N,N-dimethylformaide, N,N-dimethylacetamide; nitriles such as acetnitrile; dimethylsulfoxide and the mixture thereof.

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The amount of the transition metal catalyst to be used in the reaction is usually 0.01 to 0.2 moles based on one mole of the compound shown by the formula (b-1).

The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is usually in the range of 0.1 to 24 hours.

After the reaction, the compound shown by the formula (b-2) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is filtered, filtrate is dried and concentrated and the like. The isolated compound shown by the formula (b-2) can be purified by a technique such as chromatography, recrystallization and the like.

The intermediate compound of the present invention, which

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is shown by the formula (b-3):

$$\begin{array}{c|c}
R^{1} & C \equiv CR^{9} \\
\hline
N & O & Q & D & OH
\end{array}$$

$$\begin{array}{c|c}
C \equiv CR^{9} & OH & (b-3) \\
\hline
R^{2} & (R^{4})_{m} & (R^{5})_{n}
\end{array}$$

wherein R^1 , R^2 , R^4 , R^5 , R^9 , Q, m and n have the same meaning as described above;

can be produced by the reaction of the compound shown by the formula (u) with lithium salt of lithium salt of trimethylsilyldiazomethane.

The reaction is usually carried out in a solvent.

Examples of the solvents used for the reaction include aromatic hydrocarbons such as benzene, toluene, xylene and so on; aliphatic hydrocarbons such as hexane, heptane and so on; ethers such as diethyl ether, tetrahydrofuran, 1,4-dioxane, 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; and the mixture thereof.

The amount of the lithium salt of trimethylsilyldiazomethane to be used in the reaction is usually 2 to 4 moles based on one mole of the compound shown by the formula (u).

The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is usually in the range of 0.1 to 24 hours.

After the reaction, the compound shown by the formula (b-3) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer

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is dried and concentrated and the like. The isolated compound shown by the formula (b-3) can be purified by a technique such as chromatography, recrystallization and the like.

The intermediate compound of the present invention, which is shown by the formula (b-4):

wherein R^1 , R^2 , R^4 , R^5 , Q, m and n have the same meaning as described above;

can be produced by the hydrolysis reaction of the compound shown by the formula (w)

wherein R^1 , R^2 , R^4 , R^5 , Q, m and n have the same meaning as described above, R^{14} represents a protective group of carboxyl group such as a methyl group or an ethyl group; in the presence of a base.

The reaction is carried out in the presence water and usually in a solvent.

Examples of the solvents used for the reaction include ketones such as acetone, methyl ethyl ketone, and so on; aromatic hydrocarbons such as benzene, toluene, xylene and so on; aliphatic hydrocarbons such as hexane, heptane and so on; ethers such as diethyl ether, tetrahydrofuran, 1,4-dioxane,

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1,2-dimethoxyethane, 1,2-diethoxyethane and so on; halogenated hydrocarbons such as chlorobenzene, dichlorobenzene and so on; amides such as N,N-dimethylformaide, N,N-dimethylacetamide; nitriles such as acetnitrile; dimethylsulfoxide and the mixture thereof.

Examples of the bases used for the reaction include inorganic bases such as hydroxides of alkali metal or alkaline earth metal (sodium hydroxide, potassium hydroxide, calcium hydroxide and so on), carbonates of alkali metal or alkaline earth metal (for example sodium carbonate, potassium carbonate and so on); and organic bases such as triethylamine and so on.

The amount of the base to be used in the reaction is usually 1 to 3 moles based on one mole of the compound shown by the formula (w).

The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is usually in the range of 0.1 to 24 hours.

After the reaction, the compound shown by the formula (b-4) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, acidified by adding an acid (for example hydrochloric acid, sulfuricacid and so on), extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated compound shown by the formula (b-4) can be purified by a technique such as chromatography, recrystallization and the like.

The intermediate compound of the present invention, which

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is shown by the formula (b-5):

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$$R^{1}$$
 R^{9}
 R^{2}
 R^{2}
 R^{4}
 R^{2}
 R^{4}
 R^{5}
 R^{5}
 R^{5}

wherein R^1 , R^2 , R^4 , R^5 , R^9 , Q, m and n have the same meaning as described above;

can be produced by reduction reaction of the compound shown by the formula (u) with hydrazine in the presence of a base.

The reaction is usually carried out in a solvent.

Examples of the solvents used for the reaction include aromatic hydrocarbons such as benzene, toluene, xylene and so on; aliphatic hydrocarbons such as hexane, heptane and so on; alcohols such as methanol, ethanol, ethylene glycol, diethylene glycol and so on, ethers such as diethýl ether, tetrahydrofuran, 1,4-dioxane, 1,2-dimethoxyethane, 1,2-diethoxyethane and so chlorobenzene, hydrocarbons such as on; halogenated dichlorobenzene and so on; amides such as N, N-dimethylformaide, as acetnitrile; nitriles such N, N-dimethylacetamide; dimethylsulfoxide and the mixture thereof.

Examples of the bases used for the reaction include inorganic bases such as hydroxides of alkali metal or alkaline earth metal (sodium hydroxide, potassium hydroxide, calcium hydroxide and so on), alkoxides of alkali metal such as sodium ethoxide; hydrides of alkali metal or alkaline earth metal (sodium hydride, potassium hydride, calcium hydride and so on), carbonates of alkali metal or alkaline earth metal (sodium carbonate, potassium carbonate and so on); and organic bases

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such as triethylamine and so on.

The amount of the reagents to be used in the reaction is usually 2 to 4 moles of the base and 1 to 3 moles of hydrazine based on one mole of the compound shown by the formula (u).

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The reaction temperature is usually in the range of 0 to 250 $^{\circ}$ C, and the reaction period is usually in the range of 0.1 to 24 hours.

After the reaction, the compound shown by the formula (b-5) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated compound shown by the formula (b-5) can be purified by a technique such as chromatography, recrystallization and the like.

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The intermediate compound of the present invention, which is shown by the formula (b-6):

wherein R^1 , R^2 , R^4 , R^5 , m and n have the same meaning as described above;

can be produced by decarboxylate reaction of the compound shown by the formula (b-4).

The reaction is carried out without a solvent or in a solvent, and in the presence of an acid or a base, if necessary.

Examples of the solvents used for the reaction include organic solvents selected from ketones such as acetone, methyl

ethyl ketone, and so on; aromatic hydrocarbons such as benzene, toluene, xylene and so on; aliphatic hydrocarbons such as hexane, heptane and so on; alcohols such as methanol, ethanol and so on; ethers such as diethyl ether, tetrahydrofuran, 1,4-dioxane, 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; halogenated hydrocarbons such as chlorobenzene, dichlorobenzene and so on; amides such as N,N-dimethylformaide, N,N-dimethylacetamide; nitriles such as acetnitrile; dimethylsulfoxide; acid anhydride such as acetic anhydride; the mixture thereof; and the mixture of water and an organic solvent described above.

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Examples of the acids used for the reaction include inorganic acids such as hydrochloric acid, sulfuric acid and so on.

Examples of the bases used for the reaction include inorganic bases such as hydroxides of alkali metal or alkaline earth metal (sodium hydroxide, potassium hydroxide, calcium hydroxide and so on), carbonates of alkali metal or alkaline earth metal (sodium carbonate, potassium carbonate and so on); and organic bases such as triethylamine, quinoline and so on.

The amount of the reagents to be used in the reaction is usually 1 mole to excess amount of the acid or 1 mole to excess amount of the base based on one mole of the compound shown by the formula (b-4).

The reaction temperature is usually in the range of 0 to 250 $^{\circ}$ C, and the reaction period is usually in the range of 0.1 to 24 hours.

The reaction may be carried out in the presence of a catalyst such as copper or copper(I) chloride, if necessary.

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The amount of catalyst to be used in the reaction is 0.01 to 0.1 moles based on one mole of the compound shown by the formula (b-4).

After the reaction, the compound shown by the formula (b-6) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, acidified by adding an acid (for example hydrochloric acid, sulfuric acid and so on), extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated compound shown by the formula (b-6) can be purified by a technique such as chromatography, recrystallization and the like.

The intermediate compound of the present invention, which is shown by the formula (b-7):

wherein R^1 , R^2 , R^4 , R^5 , m and n have the same meaning as described above, X represents a halogen atom such as chlorine atom, bromine atom and iodine atom;

can be produced by the reaction of the compound shown by the formula (b-6) with the N-halo succinimide compound shown by the formula (y):

wherein X have the same meaning as described above.

The reaction is usually carried out in a solvent.

Examples of the solvens used for the reaction include aliphatic hydrocarbons such as hexane, heptane and so on; ethers such as diethyl ether, tetrahydrofuran, 1,4-dioxane, 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; halogenated hydrocarbons such as chlorobenzene, dichlorobenzene and so on; amides such as N,N-dimethylformaide, N,N-dimethylacetamide; nitriles such as acetnitrile; dimethylsulfoxide; and the mixture thereof.

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The amount of the N-halo succinimide compound to be used in the reaction is usually 1 to 3 moles based on one mole of the compound shown by the formula (b-6).

The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is usually in the range of 0.1 to 24 hours.

After the reaction, the compound shown by the formula (b-7) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated compound shown by the formula (b-7) can be purified by a technique such as chromatography, recrystallization and the like.

The compound shown by the formula (e) can be produced by the reaction of the compound shown by the formula (g) in which R^9 is a hydrogen atom with hydroxyl amine or its salt (for example hydrocloric acid salt).

The reaction is carried out in the presence of a base

usually in a solvent. The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is in the range of 0.1 to 24 hours.

Examples of the solvents used for the reaction include alcohols such as methanol, ethanol and so on; aromatic hydrocarbons such as benzene, toluene, xylene and so on; aliphatic hydrocarbons such as hexane, heptane and so on; ethers such as diethyl ether, tetrahydrofuran, 1,4-dioxane, 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; chlorinated hydrocarbons such as dichloromethane, chloroform, 1,2-dichloroethane, chlorobenzene, dichlorobenzene and so on; amides such as N, N-dimethylformamide, N, N-diethylacetamide and nitriles so on; such as acetonitrile and so on; dimethylsulfoxide; water and the mixture thereof.

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Examples of the bases used for the reaction include inorganic bases such as hydrides of alkali metal or alkaline earth metal (sodium hydride, potassium hydride, calcium hydride and so on), sodium carbonate, potassium carbonate and so on; and organic bases such as triethylamine, pyridine and so on.

Based on one mole of the compound shown by the formula (g), 1 to 3 moles of the hydroxyl amine or the salt thereof and 1 to 3 moles of the base are used.

After the reaction, the compound shown by the formula (e) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated compound shown by the formula (e) can be purified by a technique such

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as chromatography, recrystallization and the like.

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The compound shown by the formula (g) can be produced by the reaction of the compound shown by the formula (u) with the compound shown by the formula (c).

The reaction is carried out in the presence of a base usually in a solvent.

Examples of the solvents used for the reaction include ketones such as acetone, methyl ethyl ketone and so on; aromatic hydrocarbons such as benzene, toluene, xylene and so on; aliphatic hydrocarbons such as hexane, heptane and so on; ethers 1,4-dioxane, ether, tetrahydrofuran, diethyl such 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; halogenated hydrocarbons such as chlorobenzene, dichlorobenzene and so on; amides such as N, N-dimethylformamide, N, N-diethylacetamide and acetonitrile such as and so on; nitriles so on; dimethylsulfoxide; and the mixture thereof.

Examples of the bases used for the reaction include inorganic bases such as hydroxides of alkali metal or alkaline earth metal (sodium hydroxide, potassium hydroxide, calcium hydroxide and so on), carbonates of alkali metal or alkaline earth metal (sodium carbonate, potassium carbonate and so on); and organic bases such as triethylamine and so on.

The amount of the reagents to be used in the reaction is usually 1 to 3 moles of the compound shown by the formula (c) and 1 to 3 moles of the base based on one mole of the compound shown by the formula (u). The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is usually

in the range of 0.1 to 24 hours.

After the reaction, the compound shown by the formula (g) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated compound shown by the formula (g) can be purified by a technique such as chromatography, recrystallization and the like.

The compound shown by the formula (u) can be produced by the reaction of the compound shown by the formula (ad):

$$R^1$$
 $N \cdot N$
 R^2
(ad)

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wherein ${\mbox{R}}^1, \ {\mbox{R}}^2$ and ${\mbox{R}}^9$ have the same meaning as described above; with the compound shown by the formula (t).

The reaction is carried out in the presence of a base usually in a solvent.

Examples of the solvents used for the reaction include aromatic hydrocarbons such as toluene, xylene and so on; aliphatic hydrocarbons such as hexane, heptane and so on; ethers such as diethyl ether, tetrahydrofuran, 1,4-dioxane, 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; amides such as N,N-dimethylformamide, N,N-diethylacetamide and so on; dimethylsulfoxide; and the mixture thereof.

Examples of the bases used for the reaction include inorganic bases such as hydroxides of alkali metal or alkaline

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earth metal (sodium hydroxide, potassium hydroxide, calcium hydroxide and so on), hydrides of alkali metal or alkaline earth metal (sodium hydride, potassium hydride, calcium hydride and so on), carbonates of alkali metal or alkaline earth metal (sodium carbonate, potassium carbonate and so on); and organic bases such as triethylamine and so on.

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The amount of the reagents to be used in the reaction is usually 0.5 to 3 moles of the compound shown by the formula (t) and 1 to 3 moles of the base based on one mole of the compound shown by the formula (ad).

The reaction temperature is usually in the range of -78 to 150 $^{\circ}$ C, and the reaction period is usually in the range of 0.1 to 24 hours.

The reaction may be carried out in the presence of a catalyst such as copper or copper(I) chloride, if necessary.

The amount of the catalyst to be used in the reaction is 0.01 to 0.2 moles based on one mole of the compound shown by the formula (ad).

After the reaction, the compound shown by the formula (u) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated compound shown by the formula (u) can be purified by a technique such as chromatography, recrystallization and the like.

In case of the compound shown by the formula (t) is unsymmetrical, the compound shown by the formula (u) can be

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produced by protecting one of the two phenolic hydroxy group in the compound shown by the formula (t) with an appropriate protecting group (such as benzyl, tert-butyldimethylsilyl and methoxymethyl), subjecting with the reaction described above, and removing the protecting group.

The compound shown by the formula (w) can be produced by the reaction of the compound shown by the formula (ae):

$$R^1$$
 $COOR^{14}$
 $N \cdot N$
 R^2
(ae)

wherein R^1 , R^2 and R^{14} have the same meaning as described above; with the compound shown by the formula (t).

The reaction is carried out in the presence of a base usually in a solvent.

Examples of the solvents used for the reaction include aromatic hydrocarbons such as toluene, xylene and so on; aliphatic hydrocarbons such as hexane, heptane and so on; ethers such as diethyl ether, tetrahydrofuran, 1,4-dioxane, 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; amides such as N,N-dimethylformamide, N,N-diethylacetamide and so on; dimethylsulfoxide; and the mixture thereof.

Examples of the bases used for the reaction include inorganic bases such as hydroxides of alkali metal or alkaline earth metal (sodium hydroxide, potassium hydroxide, calcium hydroxide and so on), hydrides of alkali metal or alkaline earth metal (sodium hydride, potassium hydride, calcium hydride and so on), carbonates of alkali metal or alkaline earth metal (sodium

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carbonate, potassium carbonate and so on); and organic bases such as triethylamine and so on.

The amount of the reagents to be used in the reaction is usually 0.5 to 3 moles of the compound shown by the formula (t) and 1 to 3 moles of the base based on one mole of the compound shown by the formula (ae). The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is usually in the range of 0.1 to 24 hours.

The reaction may be carried out in the presence of a catalyst such as copper or copper(I) chloride, if necessary. The amount of the catalyst to be used in the reaction is 0.01 to 0.2 moles based on one mole of the compound shown by the formula (ae).

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After the reaction, the compound shown by the formula (w) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated compound shown by the formula (w) can be purified by a technique such as chromatography, recrystallization and the like.

In case of the compound shown by the formula (t) is unsymmetrical, the compound shown by the formula (w) can be produced by protecting one of the two phenolic hydroxy group in the compound shown by the formula (t) with an appropriate protecting group (such as benzyl, tert-butyldimethylsilyl and methoxymethyl), subjecting with the reaction described above, and removing the protecting group.

The compound shown by the formula (t-1), which Q is an oxygen atom in the compound shown by the formula (t):

$$HO - (t-1)$$
 $(R^4)_m \qquad (R^5)_n$

wherein R⁴, R⁵, m and n have the same meaning as described above; can be produced, for example, by deprotection of the protecting group of the compound shown by the formula (tt-1):

$$HO \longrightarrow O \longrightarrow OL^1$$
 (tt-1)

wherein R^4 , R^5 , m and n have the same meaning as described above, $10 \quad L^1 \quad \text{represents} \quad \text{a} \quad \text{protective} \quad \text{group} \quad \text{(benzyl group,} \\ \text{tert-buthyldimethylsilyl group, methyoxymethyl group, and the} \\ \text{like)}.$

The condition of depretection of the protecting group of the compound shown by the formula (tt-1) can be adopted known depretection condition for each protecting group.

The compound shown by the formula (tt-1) can be produced, for example, by the reaction of the compound shown by the formula (s-1):

$$HO \xrightarrow{=|=} OH$$
 $(s-1)$ $(R^4)_m$

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wherein R^4 and m have the same meaning as described above; and the compound shown by the formula (s-2):

$$L^{2} \longrightarrow OL^{1} \qquad (s-2)$$

$$(R^{5})_{n}$$

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wherein R^5 , n and L^1 have have the same meaning as described above, L^2 represents a halogen atom (chlorine atom, bromine atom, iodine atom, and the like).

The reaction is carried out in the presence of a base usually in a solvent.

Examples of the solvents used for the reaction include ketones such as acetone, methylethylketone and so on; ethers such as diethyl ether, tetrahydrofuran, 1,4-dioxane, 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; amides such as N,N-dimethylformamide, N,N-diethylacetamide and so on; dimethylsulfoxide; and the mixture thereof.

Examples of the bases used for the reaction include inorganic bases such as hydroxides of alkali metal or alkaline earth metal (sodium hydroxide, potassium hydroxide, calcium hydroxide and so on), carbonates of alkali metal or alkaline earth metal (sodium carbonate, potassium carbonate, cesium carbonete and so on); and organic bases such as triethylamine and so on.

The amount of the reagents to be used in the reaction is usually 1 to 3 moles of the compound shown by formula (s-2) and 1 to 3 moles of the base based on one mole of the compound of the formula (s-1). The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is usually in the range of 0.1 to 24 hours.

The reaction may be carried out in the presence of a

catalyst such as copper, copper (I) chloride and so on, if necessary.

The amount of the catalyst to be used in the reaction is 0.01 to 0.2 moles based on one mole of the compound shown by the formula (s-1).

After the reaction, the compound shown by the formula (tt-1) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated compound shown by the formula (tt-1) can be purified by a technique such as chromatography, recrystallization and the like.

The compound shown by the formula (tt-1) can also be produced by the reaction of the compound shown by the formula (s-1) and the compound shown by the formula (s-4):

$$(HO)_2B - OL^1$$
 (s-4)

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wherein R^5 , n and L^1 have the seme meaning as described above.

The reaction is carried out in the presence of copper acetate and a organic base, usually in a solvent.

Examples of the solvents used for the reaction include halogenated hydrocarbons such as dichloromethane, chloroform, 1,2-dichloroethane and so on.

Examples of the organic bases used for the reaction include

pyridine derivatives such as pyridine and so on, tertiary amines such as triethylamine and so on.

The amount of the reagents to be used in the reaction is usually 1 to 3 moles of the compound of formula (s-4), 1 to 3 moles s of copper acetate and 1 mole to excess amount of the organic base based on one mole of the compound shown by the formula (s-1).

The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is usually in the range of 0.1 to 24 hours.

The reaction may be carried out in the presence of a molecular seives, if necessary.

After the reaction, the compound shown by the formula (tt-1) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated compound shown by the formula (tt-1) can be purified by a technique such as chromatography, recrystallization and the like.

The compound shown by the formula (t-2), which Q is a sulfur atom in the compound shown by the formula (t):

HO-
$$\langle S - S - S - S \rangle$$
 OH (t-2)

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wherein R^4 , R^5 , m and n have the same meaning as described above; can be produced, for example, by the reaction of the compound shown by the formula (s-5):

$$HO \longrightarrow SH$$
 (s-5)

wherein R^4 and m have the same meaning as described above; and the compound shown by the formula (s-6):

$$L^2$$
 OH (s-6)

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5 wherein R^5 , n and L^2 have have the same meaning as described above.

The reaction is carried out in the presence of a base usually in a solvent.

Examples of the solvents used for the reaction include

ketones such as acetone, methylethylketone and so on; ethers

such as diethyl ether, tetrahydrofuran, 1,4-dioxane,

1,2-dimethoxyethane, 1,2-diethoxyethane and so on; amides such

as N,N-dimethylformamide, N,N-diethylacetamide and so on; and

the mixture thereof.

Examples of the bases used for the reaction include inorganic bases such as hydroxides of alkali metal or alkaline earth metal (sodium hydroxide, potassium hydroxide, calcium hydroxide and so on), carbonates of alkali metal or alkaline earth metal (sodium carbonate, potassium carbonate, cesium carbonete and so on) and so on.

The amount of the reagents to be used in the reaction is usually 1 to 3 moles of the compound of formula (s-6) and 1 to 3 moles of the base based on one mole of the compound shown by the formula (s-5).

The reaction temperature is usually in the range of -78 to 150 $^{\circ}$ C, and the reaction period is usually in the range of 0.1 to 24 hours.

The reaction may be carried out in the presence of a catalyst such as copper, copper (I) chloride and so on, if necessary.

The amount of the catalyst to be used in the reaction is 0.01 to 0.2 moles based on one mole of the compound shown by the formula (s-5).

After the reaction, the compound shown by the formula (t-2) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated compound shown by the formula (t-2) can be purified by a technique such as chromatography, recrystallization and the like.

The compound shown by the formula (t-2) can also be produced by deprotection of the protective group of the compound shown by the formula (tt-2):

HO
$$\sim$$
 S \sim OL¹ (tt-2)

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wherein R^4 , R^5 , m, n and L^1 have the same meaning as described above.

The condition of depretection of the protecting group of the compound shown by the formula (tt-2) can be adopted known depretection condition for the each protecting group.

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The condition of deprorection of the prorecting group of the compound shown by the formula (tt-2) can be adopted known deprotection condition for each compound.

The compound shown by the formula (tt-2) can be produced, for example, by the reaction of the compound shown by the formula (s-7):

$$HO - SH$$
 (s-7)

wherein R^4 and m have have the same meaning as described above; and the compound shown by the formula (s-2).

The reaction is carried out in the presence of a base usually in a solvent.

Examples of the solvents used for the reaction include ketones such as acetone, methylethylketone and so on; ethers such as diethyl ether, tetrahydrofuran, 1,4-dioxane, 1,2-dimethoxyethane, 1,2-diethoxyethane and so on; amides such as N,N-dimethylformamide, N,N-diethylacetamide and so on; dimethylsulfoxide; and the mixture thereof.

Examples of the bases used for the reaction include inorganic bases such as hydroxides of alkali metal or alkaline earth metal (sodium hydroxide, potassium hydroxide, calcium hydroxide and so on), carbonates of alkali metal or alkaline earth metal (sodium carbonate, potassium carbonate, cesium carbonete and so on); and organic bases such as triethylamine and so on.

The amount of the reagents to be used in the reaction

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is usually 1 to 3 moles of the compound shown by the formula (s-2) and 1 to 3 moles of the base based on one mole of the compound shown by the formula (s-7). The reaction temperature is usually in the range of -78 to 150 $^{\circ}$ C, and the reaction period is usually in the range of 0.1 to 24 hours.

The reaction may be carried out in the presence of a catalyst such as copper, copper (I) chloride and so on, if necessary.

The amount of the catalyst to be used in the reaction is 0.01 to 0.2 moles based on one mole of the compound shown by the formula (s-7).

After the reaction, the compound shown by the formula (tt-2) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated compound shown by the formula (tt-2) can be purified by a technique such as chromatography, recrystallization and the like.

20 The compound shown by the formula (t-3), which Q is a C1-C5 alkylidene group in the compound shown by the formula (t):

$$+O - Q^1 - Q^1 - OH$$
 $(t-3)$

wherein R^4 , R^5 , m and n have the same meaning as described above, Q^1 represents a C1-C5 alkylidene group;

can be produced, for example, by the reaction of the compound shown by the formula (s-9):

$$HO - Q^1OH (s-9)$$
 $(R^4)_m$

wherein R^4 , m and Q^2 have have the same meaning as described above;

and the compound shown by the formula (s-10):

$$H \longrightarrow OH$$
 (s-10)

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wherein R⁵ and n have the same meaning as described above.

The reaction is carried out in the presence of an acid, in a solvent or without a solvent.

Examples of the solvents used for the reaction include

10 ethers such as diethyl ether, tetrahydrofuran, 1,4-dioxane,
1,2-dimethoxyethane, 1,2-diethoxyethane and so on; halogenated
hydrocarbons such as dichlorometane, chloroform,
1,2-dichloroethane and so on; and the mixture thereof.

Examples of the acids used for the reaction include sulfric acid, phosphoric acid, aluminium chloride, boron trifluoride diethyl etherate and so on.

The amount of the reagents to be used in the reaction is usually 1 to 3 moles of the compound shown by the formula (s-10) and 1 mole to excess amount of the base based on one mole shown by the compound of the formula (s-9).

The reaction temperature is usually in the range of -78 to 150 °C, and the reaction period is usually in the range of 0.1 to 24 hours.

After the reaction, the compound shown by the formula

(t-3) can be isolated, for example, by subjecting the reaction mixture to post-treatment, such as the reaction mixture is poured into water, extracted with an organic solvent, the organic layer is dried and concentrated and the like. The isolated compound shown by the formula (t-3) can be purified by a technique such as chromatography, recrystallization and the like.

The compounds of the present invention are exemplified below.

The pyrazole compound shown by the formula (I) to (XC).

$$R^1$$
 R^3
 CI
 $OCH_2CH=CCI_2$
 R^2
 R^2

$$R^1$$
 R^3
 CI
 $OCH_2CH=CCI_2$
 R^2
 CI
 $OCH_2CH=CCI_2$
 CI

$$R^{1} \xrightarrow{R^{3}} \xrightarrow{H_{3}C} \xrightarrow{H_{3}C} \xrightarrow{OCH_{2}CH=CCl_{2}} (XI)$$

$$R^{2} \xrightarrow{R^{3}} \xrightarrow{H_{3}CH_{2}C} \xrightarrow{OCH_{2}CH=CCl_{2}} (XII)$$

$$R^{2} \xrightarrow{R^{3}} \xrightarrow{H_{3}CH_{2}CH_{2}C} \xrightarrow{OCH_{2}CH=CCl_{2}} (XIII)$$

$$R^{2} \xrightarrow{R^{3}} \xrightarrow{H_{3}CH_{2}CH} \xrightarrow{OCH_{2}CH=CCl_{2}} (XIV)$$

$$R^{2} \xrightarrow{R^{3}} \xrightarrow{H_{3}CH_{2}CH} \xrightarrow{OCH_{2}CH=CCl_{2}} (XV)$$

$$R^{3} \xrightarrow{R^{3}} \xrightarrow{H_{3}CH_{2}CH} \xrightarrow{OCH_{2}CH=CCl_{2}} (XVI)$$

$$R^{2} \xrightarrow{R^{3}} \xrightarrow{OCH_{2}CH_{2}CH_{3}} (XVII)$$

$$R^{4} \xrightarrow{R^{3}} \xrightarrow{OCH_{2}CH=CCl_{2}} (XVIII)$$

$$R^{2} \xrightarrow{R^{3}} \xrightarrow{OCH_{2}CH=CCl_{2}} (XVIII)$$

$$R^{2} \xrightarrow{R^{3}} \xrightarrow{OCH_{2}CH=CCl_{2}} (XIIX)$$

$$R^{4} \xrightarrow{R^{3}} \xrightarrow{F_{3}C} \xrightarrow{OCH_{2}CH=CCl_{2}} (XIX)$$

$$R^{1} \xrightarrow{R^{3}} CI \longrightarrow OCH_{2}CH=CCI_{2} (XXI)$$

$$R^{1} \xrightarrow{R^{3}} O \longrightarrow OCH_{2}CH=CGI_{2} (XXII)$$

$$R^{1} \xrightarrow{R^{3}} O \longrightarrow OCH_{2}CH=CH_{2} (XXIII)$$

$$R^{1} \xrightarrow{R^{3}} O \longrightarrow OCH_{2}CH=CH_{2} (XXIII)$$

$$R^{1} \xrightarrow{R^{2}} R^{3} \longrightarrow OCH_{2}CH=CHCI (XXIV)$$

$$R^{2} \xrightarrow{R^{3}} O \longrightarrow OCH_{2}CH=CHCI (XXIV)$$

$$R^{2} \xrightarrow{R^{3}} O \longrightarrow OCH_{2}CH=C(CI)(Br) (XXVII)$$

$$R^{1} \xrightarrow{R^{2}} R^{3} \longrightarrow OCH_{2}CH=C(CI)(CH_{3} (XXVIII))$$

$$R^{1} \xrightarrow{R^{2}} R^{3} \longrightarrow OCH_{2}CH=C(CI)CH_{3} (XXVIII)$$

$$R^{2} \xrightarrow{R^{3}} OCH_{2}CH=C(CI)CH_{3} (XXIII)$$

$$R^{2} \xrightarrow{R^{3}} OCH_{2}CH=C(CI)CH_{3} (XXIII)$$

$$R^{2} \xrightarrow{R^{3}} OCH_{2}CH=C(CI)CH_{3} (XXIII)$$

$$R^{2} \xrightarrow{R^{3}} OCH_{2}CH=C(CI)CH_{3} (XXIII)$$

$$R^{3} \xrightarrow{R^{3}} OCH_{2}CH=C(CI)CH_{3} (XXIII)$$

$$R^{1} \xrightarrow{R^{3}} O \longrightarrow S \longrightarrow OCH_{2}CH=CCl_{2} \qquad (XXXII)$$

$$R^{1} \xrightarrow{R^{3}} O \longrightarrow S \longrightarrow OCH_{2}CH=CCl_{2} \qquad (XXXIII)$$

$$R^{1} \xrightarrow{R^{3}} O \longrightarrow S \longrightarrow OCH_{2}CH=CCl_{2} \qquad (XXXIII)$$

$$R^{1} \xrightarrow{R^{3}} O \longrightarrow S \longrightarrow OCH_{2}CH=CCl_{2} \qquad (XXXIV)$$

$$R^{1} \xrightarrow{R^{3}} O \longrightarrow S \longrightarrow OCH_{2}CH=CCl_{2} \qquad (XXXVI)$$

$$R^{1} \xrightarrow{R^{3}} O \longrightarrow S \longrightarrow OCH_{2}CH=CCl_{2} \qquad (XXXVII)$$

$$R^{1} \xrightarrow{R^{3}} O \longrightarrow S \longrightarrow OCH_{2}CH=CCl_{2} \qquad (XXXVIII)$$

$$R^{1} \xrightarrow{R^{3}} Cl \longrightarrow S \longrightarrow OCH_{2}CH=CCl_{2} \qquad (XXXVIII)$$

$$R^{1} \xrightarrow{R^{3}} Cl \longrightarrow S \longrightarrow OCH_{2}CH=CCl_{2} \qquad (XXXVIII)$$

$$R^{1} \xrightarrow{R^{3}} Cl \longrightarrow S \longrightarrow OCH_{2}CH=CCl_{2} \qquad (XXXVIII)$$

$$R^{1} \xrightarrow{R^{3}} Cl \longrightarrow S \longrightarrow OCH_{2}CH=CCl_{2} \qquad (XXXVIII)$$

$$R^{1} \xrightarrow{R^{3}} Cl \longrightarrow S \longrightarrow OCH_{2}CH=CCl_{2} \qquad (XXXVIII)$$

$$R^{1} \xrightarrow{R^{3}} Cl \longrightarrow S \longrightarrow OCH_{2}CH=CCl_{2} \qquad (XXXXIII)$$

$$R^{1} \xrightarrow{R^{3}} Cl \longrightarrow S \longrightarrow OCH_{2}CH=CCl_{2} \qquad (XXXXIII)$$

$$R^{1} \xrightarrow{R^{3}} Cl \longrightarrow S \longrightarrow OCH_{2}CH=CCl_{2} \qquad (XXXXIII)$$

$$R^{1} \xrightarrow{R^{3}} CI$$

$$R^{2} \xrightarrow{R^{3}} CI$$

$$R^{3} \xrightarrow{R^{3}} CI$$

$$R^{3} \xrightarrow{R^{3}} CI$$

$$R^{3} \xrightarrow{R^{3}} CI$$

$$R^{2} \xrightarrow{R^{3}} CI$$

$$R^{3} \xrightarrow{R^{3}} CI$$

$$R^{2} \xrightarrow{R^{3}} CI$$

$$R^{3} \xrightarrow{R^{3}} CI$$

$$R^{3} \xrightarrow{R^{3}} CI$$

$$R^{4} \xrightarrow{R^{3}} CI$$

$$R^{5} \xrightarrow{R^{3}} CI$$

$$CH_{2}CH = CI$$

$$CH_{2}CH = CI$$

$$CIUI$$

$$CLVII$$

$$CLVII$$

$$R^{7} \xrightarrow{R^{3}} CI$$

$$CLVIII$$

$$R^{7} \xrightarrow{R^{3}} CI$$

$$CLVIII$$

$$R^{7} \xrightarrow{R^{3}} CI$$

$$CLVIII$$

$$R^{7} \xrightarrow{R^{3}} CI$$

$$CLVIII$$

$$\begin{array}{c|c}
R^{1} & R^{3} \\
N & N \\
N & R^{2}
\end{array}$$

$$\begin{array}{c|c}
C & \text{OCH}_{2}\text{CH=CCI}_{2}
\end{array}$$
(LXI)

$$\begin{array}{c|c} R^{1} & R^{3} & CI \\ \hline & N & \\ & N & \\ & & \\$$

$$R^{1}$$
 R^{3}
 R^{3}
 R^{3}
 R^{2}
 R^{2}
 R^{2}
 R^{2}
 R^{3}
 R^{3

$$R^1$$
 N
 N
 R^2
 CI
 H_2
 $CH=CCI_2$
 $CLXVII$

$$R^1$$
 R^3
 R^3

$$R^{1} \xrightarrow{R^{3}} CI$$

$$C_{1} \xrightarrow{C_{1}} CCH_{2}CH=CCI_{2} \qquad (LXXXII)$$

$$R^{2} \xrightarrow{R^{3}} CI$$

$$R^{3} \xrightarrow{R^{3}} CI$$

$$R^{3} \xrightarrow{R^{3}} CI$$

$$R^{2} \xrightarrow{R^{3}} CI$$

$$R^{3} \xrightarrow{R^{3}} CI$$

$$R^{4} \xrightarrow{R^{3}} CI$$

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Each of ${\mbox{R}}^1, \ {\mbox{R}}^2$ and ${\mbox{R}}^3$ in the formula (I) to (XC) is any one of the combination described in Table 1 to 50.

Table 1

I abic i		
R.1	R ²	R ³
CH ₃	CH ₃	Н
CH ₃	CH ₃	CH ₃
CH ₃	CH ₃	CH ₂ CH ₃
CH ₃	CH₃	CH ₂ CH ₂ CH ₃
CH ₃	CH ₃	CH (CH ₃) ₂
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₃
·CH ₃	CH ₃	CH (CH ₃) CH ₂ CH ₃
CH ₃	CH ₃	CH ₂ CH (CH ₃) ₂
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₃
CH ₃	CH ₃	CH ₂ CH ₂ CH (CH ₃) ₂
CH ₃	CH ₃	CH (CH ₃) CH ₂ CH ₂ CH ₃
CH ₃	CH ₃	CH_2CH (CH_3) CH_2CH_3
CH ₃	CH ₃	CH (CH ₃) CH (CH ₃) ₂
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ CH ₃
CH ₃	CH ₃	CH ₂ F
CH ₃	CH ₃	CF ₃
CH ₃	CH ₃	CH ₂ CH ₂ F
CH ₃	CH ₃	CH ₂ CF ₃
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ F
CH ₃	CH ₃	CH ₂ CH ₂ CF ₃
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ F
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CF ₃
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CF ₃
CH ₃	CH ₃	CH ₂ CH ₂ Cl
CH ₃	CH ₃	CHC1CH2C1
CH ₃	CH ₃	CH ₂ CH ₂ Br
CH ₃	CH ₃	CHBrCH ₂ Br
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ Cl
CH ₃	CH ₃	CH2CHClCH2Cl
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ Br
CH ₃	CH ₃	CH ₂ CHBrCH ₂ Br
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ Cl
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ Br
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ Cl
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ Br

Table 2

Table 2		
R ¹	R ²	R ³
CH ₃	CH ₃	CH2CH2CH2CH2CH2CL
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br
CH ₃	CH ₃	CH=CH ₂
CH ₃	CH ₃	CH ₂ CH=CH ₂
CH ₃	CH ₃	CH=CHCH ₃
CH ₃	CH ₃	$C(CH_3) = CH_2$
CH ₃	CH ₃ .	CH=CHCH ₂ CH ₃
CH ₃	CH ₃	CH ₂ CH=CHCH ₃
CH ₃	CH ₃	CH ₂ CH ₂ CH=CH ₂
CH ₃	CH ₃	$C(CH_3) = CHCH_3$
CH ₃	CH ₃	CH (CH ₃) CH=CH ₂
CH ₃	CH ₃	$CH=C(CH_3)_2$
CH ₃	CH ₃	$CH_2C(CH_3) = CH_2$
CH ₃	CH ₃	$C(CH_2CH_3) = CH_2$
CH ₃	CH ₃	CH=CHCH ₂ CH ₂ CH ₃
CH ₃	CH ₃	$C(CH_3) = CHCH_2CH_3$
CH ₃	CH ₃	CH (CH ₃) CH=CHCH ₃
CH ₃	CH ₃	CH (CH ₃) CH ₂ CH=CH ₂
CH ₃	CH ₃	$CH=C(CH_3)CH_2CH_3$
CH ₃	CH ₃	CH_2C (CH_3) = $CHCH_3$
CH ₃	CH ₃	CH ₂ CH (CH ₃) CH=CH ₂
CH ₃	CH ₃	CH=CHCH (CH ₃) ₂
CH ₃	CH ₃	$CH_2CH=C(CH_3)_2$
CH ₃	CH ₃	$CH_2CH_2C (CH_2) = CH_2$
CH ₃	CH ₃	$CH_2CH=C(CH_3)_2$
CH ₃	CH ₃	CH=CHCH ₂ CH ₂ CH ₂ CH ₃
CH ₃	CH ₃	CH=CHC1
CH ₃	CH ₃	CH=CCl ₂
CH ₃	CH ₃	CH=C(CH ₃)Cl
CH ₃	CH ₃	CH ₂ CH=CHCl
CH ₃	CH ₃	CH ₂ CCl=CHCl
CH ₃	CH ₃	CH ₂ CH=CCl ₂
CH ₃	CH ₃	CH=CHBr
CH ₃	CH ₃	CH=CBr ₂
CH ₃	CH ₃	CH=C(CH ₃)Br

Table 3

R 1	R ²	R ³
CH ₃	CH ₃	CH ₂ CH=CHBr
CH ₃	CH ₃	CH ₂ CBr=CHBr
CH ₃	CH ₃	CH ₂ CH=CBr ₂
CH ₃	CH ₃	CH ₂ CH=C (CH ₃) Cl
CH ₃	CH ₃	CH ₂ CH=C (CF ₃) Cl
CH ₃	CH ₃	CH ₂ CH=C (CH ₃) Br
CH ₃	CH ₃	CH ₂ CH=C(CF ₃)Br CH=CHCF ₃
CH ₃	CH ₃	CH=CHCH ₂ CF ₃
CH ₃	CH ₃	CH_CH=CHCH ₂ CF ₃ CH ₂ CH=CHCH ₂ CF ₃
CH ₃	CH ₃ CH ₃	C≡CH
	CH ₃	C≡CCH ₃
CH ₃	I .	-
CH ₃	CH ₃	CH ₂ C≡CH
CH ₃	CH ₃	C≡CCH ₂ CH ₃
CH ₃	CH ₃	CH ₂ C≡CCH ₃
CH ₃	CH ₃	CH ₂ CH ₂ C≡CH
CH ₃	CH ₃	CH (CH ₃) C≡CH
CH ₃	CH ₃	C≡CCH ₂ CH ₂ CH ₃
CH ₃	CH ₃	$CH_2C \equiv CCH_2CH_3$
CH ₃	CH ₃	CH ₂ CH ₂ C≡CCH ₃
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ C≡CH
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ C≡CCH ₃
CH ₃	CH ₃	c≡cc1
CH ₃	CH3	CH ₂ C≡CCl
CH ₃	CH ₃	CH ₂ CH ₂ C≡CCl
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ C≡CCl
CH ₃	CH ₃	C≡CBr
CH ₃	CH ₃	CH ₂ C≡CBr
CH ₃	CH ₃	CH ₂ CH ₂ C≡CBr
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ C≡CBr
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ C≡CCl
CH ₃	CH ₃	CH ₂ OH
CH ₃	CH ₃	CH ₂ CH ₂ OH
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ OH
CH ₃	CH3	CH ₂ CH ₂ CH ₂ CH ₂ OH

Table 4

R ¹	R ²	R ³
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ OH
CH ₃	CH ₃	CH ₂ OCH ₃
CH ₃	CH ₃	CH ₂ OCH ₂ CH ₃
CH ₃	CH ₃	CH ₂ OCH ₂ CH ₂ CH ₃
CH ₃	CH ₃	CH ₂ OCH (CH ₃) ₂
CH ₃	CH ₃	CH ₂ OCH ₂ CH ₂ CH ₃
CH ₃	CH ₃	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₃
CH ₃	CH ₃	CH ₂ CH ₂ OCH ₃
CH ₃	CH ₃	CH ₂ CH ₂ OCH ₂ CH ₃
CH ₃	CH ₃	CH ₂ CH ₂ OCH ₂ CH ₂ CH ₃
CH ₃	CH ₃	CH ₂ CH ₂ OCH (CH ₃) ₂
CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ OCH ₃
CH ₃	CH ₃	C (=O) OCH ₃
CH ₃	CH₃	C (=0) OCH2CH3
CH ₃	CH ₃	C (=0) OCH2CH2CH3
CH ₃	CH ₃	$C (=O) OCH (CH_3)_2$
CH ₃	CH ₃	C (=O) OCH2CH2CH2CH3
CH ₃	CH ₃	C (=0) OCH2CH=CH2
CH ₃	CH ₃	C (=0) OCH (CH3) CH=CH2
CH ₃	CH ₃	C (=0) OCH (CH3) C (CH3) = CH2
CH ₃	CH ₃	C (=0) OCH2CH=CHCH3
CH₃	CH ₃	C (=0) OCH (CH3) CH=CHCH3
CH ₃	CH ₃	$C (=0) OCH_2CH=C (CH_3)_2$
CH ₃	CH ₃	C (=0) OCH2CH=CHCl
CH ₃	CH ₃	C (=0) OCH2CH=CCl2
CH ₃	CH ₃	C (=0) OCH2CH=CC1 (CH3)
CH ₃	CH ₃	C(=O)OCH ₂ CH=CHBr
CH ₃	CH ₃	$C (=0) OCH_2CH=CBr_2$
CH ₃	CH ₃	$C (=0) OCH_2CH=CBr (CH_3)$

Table 5

Table 2		
R 1	R ²	R ³
CH ₃	CH ₂ CH ₃	Н
CH ₃	CH ₂ CH ₃	CH ₃
CH ₃	CH ₂ CH ₃	CH ₂ CH ₃
CH ₃	CH₂CH3	CH ₂ CH ₂ CH ₃
CH ₃	CH ₂ CH ₃	CH (CH ₃) ₂
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₃
CH ₃	CH ₂ CH ₃	CH (CH ₃) CH ₂ CH ₃
CH ₃	CH ₂ CH ₃	·CH ₂ CH (CH ₃) ₂
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₃
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH (CH ₃) ₂
CH ₃	CH ₂ CH ₃	CH (CH ₃) CH ₂ CH ₂ CH ₃
CH ₃	CH ₂ CH ₃	CH ₂ CH (CH ₃) CH ₂ CH ₃
CH ₃	CH ₂ CH ₃	CH (CH ₃) CH (CH ₃) ₂
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₃
CH ₃	CH ₂ CH ₃	CH ₂ F
CH ₃	CH ₂ CH ₃	CF ₃
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ F
CH ₃	CH ₂ CH ₃	CH ₂ CF ₃
. CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ F
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CF ₃
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ F
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CF ₃
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CF ₃
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ Cl
CH ₃	CH ₂ CH ₃	CHC1CH2C1
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ Br
CH ₃	CH ₂ CH ₃	CHBrCH ₂ Br
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ Cl
CH ₃	CH ₂ CH ₃	CH ₂ CHClCH ₂ Cl
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ Br
CH ₃	CH ₂ CH ₃	CH ₂ CHBrCH ₂ Br
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ Cl
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ Br
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CL
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br

Table 6

Table 6		
R 1	R ²	R ³
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ CL
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br
CH ₃	CH ₂ CH ₃	CH=CH ₂
CH ₃	CH ₂ CH ₃	CH ₂ CH=CH ₂
CH ₃	CH ₂ CH ₃	CH=CHCH ₃
CH ₃	CH ₂ CH ₃	$C(CH_3) = CH_2$
CH ₃	CH ₂ CH ₃	CH=CHCH ₂ CH ₃
CH ₃	CH ₂ CH ₃	CH ₂ CH=CHCH ₃
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH=CH ₂
CH ₃	CH ₂ CH ₃	$C(CH_3) = CHCH_3$
CH ₃	CH ₂ CH ₃	CH (CH ₃) CH=CH ₂
CH ₃	CH ₂ CH ₃	CH=C (CH ₃) ₂
CH ₃	CH ₂ CH ₃	$CH_2C(CH_3) = CH_2$
CH ₃	CH ₂ CH ₃	$C(CH_2CH_3) = CH_2$
CH ₃	CH ₂ CH ₃	CH=CHCH ₂ CH ₂ CH ₃
CH ₃	CH ₂ CH ₃	$C(CH_3) = CHCH_2CH_3$
CH ₃	CH ₂ CH ₃	CH (CH ₃) CH=CHCH ₃
CH ₃	CH ₂ CH ₃	CH (CH ₃) CH ₂ CH=CH ₂
CH ₃	CH ₂ CH ₃	CH=C (CH ₃) CH ₂ CH ₃
CH ₃	CH ₂ CH ₃	$CH_2C(CH_3) = CHCH_3$
CH ₃	CH ₂ CH ₃	CH_2CH (CH_3) $CH=CH_2$
CH ₃	CH ₂ CH ₃	CH=CHCH·(CH ₃) ₂
CH ₃	CH ₂ CH ₃	$CH_2CH=C (CH_3)_2$
CH ₃	CH ₂ CH ₃	$CH_2CH_2C (CH_2) = CH_2$
CH ₃	CH ₂ CH ₃	$CH_2CH=C(CH_3)_2$
CH ₃	CH ₂ CH ₃	CH=CHCH ₂ CH ₂ CH ₂ CH ₃
CH ₃	CH ₂ CH ₃	CH=CHC1
CH ₃	CH ₂ CH ₃	CH=CCl ₂
CH ₃	CH ₂ CH ₃	CH=C(CH ₃)Cl
CH ₃	CH ₂ CH ₃	CH ₂ CH=CHCl
CH ₃	CH ₂ CH ₃	CH ₂ CCl=CHCl
CH ₃	CH ₂ CH ₃	CH ₂ CH=CCl ₂
CH ₃	CH ₂ CH ₃	CH=CHBr
CH ₃	CH ₂ CH ₃	CH=CBr ₂
CH ₃	CH ₂ CH ₃	CH=C(CH ₃)Br

Table 7

	Table /		
	R 1	R ²	R ³
	CH ₃	CH ₂ CH ₃	CH ₂ CH=CHBr
	CH ₃	CH ₂ CH ₃	CH ₂ CBr=CHBr
	CH ₃	CH ₂ CH ₃	CH ₂ CH=CBr ₂
	CH ₃	CH ₂ CH ₃	CH ₂ CH=C (CH ₃) Cl
	CH ₃	CH ₂ CH ₃	CH ₂ CH=C (CF ₃) Cl
	CH ₃	CH ₂ CH ₃	CH ₂ CH=C (CH ₃) Br
	CH ₃	CH ₂ CH ₃	CH ₂ CH=C (CF ₃) Br
	CH ₃	CH ₂ CH ₃	CH=CHCF ₃
	CH ₃	CH ₂ CH ₃	CH=CHCH ₂ CF ₃
	CH ₃	CH ₂ CH ₃	CH ₂ CH=CHCH ₂ CF ₃
	CH ₃	CH ₂ CH ₃	C≡CH
	CH ₃	CH ₂ CH ₃	C≡CCH ₃
	CH ₃	CH ₂ CH ₃	CH ₂ C≡CH
	CH ₃	CH ₂ CH ₃	C≡CCH ₂ CH ₃
	CH ₃	CH ₂ CH ₃	CH ₂ C≡CCH ₃
	CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ C≡CH
	CH ₃	CH ₂ CH ₃	CH (CH ₃) C≡CH
	-CH ₃	CH ₂ CH ₃	C≡CCH ₂ CH ₂ CH ₃
	CH₃	CH ₂ CH ₃	CH ₂ C≡CCH ₂ CH ₃
	CH₃	CH ₂ CH ₃	CH ₂ CH ₂ C≡CCH ₃
	CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ C≡CH
	CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ C≡CCH ₃
	CH ₃	CH ₂ CH ₃	c≡ccl
	CH ₃	CH ₂ CH ₃	CH ₂ C≡CCl
	CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ C≡CCl
	CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ C≡CCl
	CH ₃	CH ₂ CH ₃	C≡CBr
	CH ₃	CH ₂ CH ₃	CH ₂ C≡CBr
	CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ C≡CBr
	CH₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ C≡CBr
	CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ C≡CCl
	CH ₃	CH ₂ CH ₃	CH ₂ OH
	CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ OH
	CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ OH
1	CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ OH

Table 8

R ¹	R 2	R ³
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ OH
CH ₃	CH ₂ CH ₃	CH₂OCH₃
CH ₃	CH ₂ CH ₃	CH ₂ OCH ₂ CH ₃
CH ₃	CH ₂ CH ₃	CH ₂ OCH ₂ CH ₂ CH ₃
CH ₃	CH ₂ CH ₃	CH ₂ OCH (CH ₃) ₂
CH ₃	CH ₂ CH ₃	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₃
CH ₃	CH ₂ CH ₃	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₂ CH ₃
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ OCH ₃
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ OCH ₂ CH ₃
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ OCH ₂ CH ₂ CH ₃
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ OCH (CH ₃) 2
CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ OCH ₃
CH ₃	CH ₂ CH ₃	C (=O) OCH ₃
CH ₃	CH ₂ CH ₃	C (=0) OCH2CH3
CH ₃	CH ₂ CH ₃	C (=0) OCH2CH2CH3
CH ₃	CH ₂ CH ₃	C (=0) OCH (CH3)2
CH ₃	CH ₂ CH ₃	C (=0) OCH2CH2CH2CH3
CH ₃	CH ₂ CH ₃	$C (=0) OCH_2CH=CH_2$
CH ₃	CH ₂ CH ₃	C (=O) OCH (CH3) CH=CH2
CH ₃	CH ₂ CH ₃	C (=O) OCH (CH3) C (CH3) = CH2
CH ₃	CH ₂ CH ₃	C (=O) OCH ₂ CH=CHCH ₃
CH ₃	CH ₂ CH ₃	C (=O) OCH (CH3) CH=CHCH3
CH ₃	CH ₂ CH ₃	$C (=O) OCH_2CH=C (CH_3)_2$
CH ₃	CH ₂ CH ₃	C(=O)OCH ₂ CH=CHCl
CH ₃	CH ₂ CH ₃	$C (=0) OCH_2CH=CCl_2$
CH ₃	CH ₂ CH ₃	$C (=O) OCH_2CH=CCl (CH_3)$
CH ₃	CH ₂ CH ₃	C (=O) OCH ₂ CH=CHBr
CH ₃	CH ₂ CH ₃	$C (=0) OCH_2CH=CBr_2$
CH ₃	CH ₂ CH ₃	$C (=0) OCH_2CH=CBr (CH_3)$

Table 9

Table 9		
R ¹	R ²	R ³
CH ₃	CH (CH ₃) ₂	Н
CH ₃	CH(CH ₃) ₂	CH ₃
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₃
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₃
CH ₃	CH(CH ₃) ₂	CH (CH ₃) ₂
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₃
CH ₃	$CH(CH_3)_2$	CH (CH ₃) CH ₂ CH ₃
CH ₃	CH (CH ₃) ₂	CH ₂ CH (CH ₃) ₂
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₃
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH (CH ₃) ₂
CH ₃	CH (CH ₃) ₂	CH (CH ₃) CH ₂ CH ₂ CH ₃
CH ₃	CH (CH ₃) ₂	CH ₂ CH (CH ₃) CH ₂ CH ₃
CH ₃	CH (CH ₃) ₂	CH (CH ₃) CH (CH ₃) ₂
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ CH ₃
CH ₃	CH (CH ₃) ₂	CH ₂ F
CH ₃	CH (CH ₃) ₂	CF ₃
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ F
CH ₃	CH (CH ₃) ₂	CH ₂ CF ₃
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ F
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CF ₃
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ F
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CF ₃
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ CF ₃
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ Cl
CH ₃	CH (CH ₃) ₂	CHClCH ₂ Cl
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ Br
CH ₃	CH (CH ₃) ₂	CHBrCH ₂ Br
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ Cl
CH ₃	CH (CH ₃) ₂	CH ₂ CHClCH ₂ Cl
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ Br
CH ₃	CH (CH ₃) ₂	CH ₂ CHBrCH ₂ Br
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br

Table 10

R 1	R ²	R ³
CH ₃	CH(CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Cl
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br
CH ₃	CH (CH ₃) ₂	CH=CH ₂
CH ₃	CH (CH ₃) ₂	CH ₂ CH=CH ₂
CH ₃	CH (CH ₃) ₂	CH=CHCH ₃
CH ₃	CH (CH ₃) ₂	$C(CH_3) = CH_2$
CH ₃	CH (CH ₃) ₂	CH=CHCH ₂ CH ₃
CH ₃	CH (CH ₃) ₂	CH ₂ CH=CHCH ₃
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH=CH ₂
CH ₃	CH (CH ₃) ₂	$C(CH_3) = CHCH_3$
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	CH (CH ₃) CH ₂ CH=CH ₂
.CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	l
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	_
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	· · · · · · · · · · · · · · · · · · ·
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	1
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	CH=C(CH ₃)Br

Table 11

Table II		
R 1	R ²	R 3
CH ₃	CH (CH ₃) ₂	CH ₂ CH=CHBr
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃ CH ₃	CH (CH ₃) ₂	CH=CHCF ₃ CH=CHCH ₂ CF ₃
CH ₃	CH (CH ₃) ₂	1
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	-
CH ₃	CH (CH ₃) ₂	l =
CH ₃	CH (CH ₃) ₂	l '
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ C≡CH
CH ₃	CH (CH ₃) ₂	CH(CH ₃)C≡CH
CH ₃	CH (CH ₃) ₂	C≡CCH ₂ CH ₂ CH ₃
CH ₃	CH (CH ₃) ₂	$CH_2C \equiv CCH_2CH_3$
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ C≡CCH ₃
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ C≡CH
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ C≡CCH ₃
CH ₃	CH (CH ₃) ₂	C≡CCl
CH ₃	CH (CH ₃) ₂	CH ₂ C≡CCl
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ C≡CCl
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ C≡CCl
CH ₃	CH (CH ₃) 2	
CH ₃	CH (CH ₃) ₂	=
CH ₃	CH(CH ₃) ₂	
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ C≡CBr
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CE≡CCl
CH ₃	CH (CH ₃) ₂	CH ₂ OH
CH ₃	CH (CH ₃) ₂	
CH ₃		CH ₂ CH ₂ CH ₂ OH
CH ₃	$CH(CH_3)_2$	CH ₂ CH ₂ CH ₂ CH ₂ OH

Table 12

R ¹	R ²	R ³
CH ₃	CH(CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ OH
CH ₃	CH (CH ₃) ₂	CH ₂ OCH ₃
CH ₃	CH(CH ₃) ₂	CH ₂ OCH ₂ CH ₃
CH ₃	CH (CH ₃) ₂	CH ₂ OCH ₂ CH ₂ CH ₃
CH ₃	CH (CH ₃) ₂	CH ₂ OCH (CH ₃) ₂
CH ₃	CH (CH ₃) ₂	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₃
CH ₃	CH (CH ₃) ₂	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₃
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ OCH ₃
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ OCH ₂ CH ₃
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ OCH ₂ CH ₂ CH ₃
CH ₃	CH(CH ₃) ₂	CH ₂ CH ₂ OCH (CH ₃) ₂
CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ OCH ₃
CH ₃	CH (CH ₃) ₂	$C (=0) OCH_3$
CH ₃	CH (CH ₃) ₂	
CH ₃	CH(CH ₃) ₂	C (=0) OCH2CH2CH3
CH ₃	CH (CH ₃) ₂	C (=0) OCH (CH3)2
CH ₃	CH(CH ₃) ₂	C (=0) OCH2CH2CH2CH3
CH ₃	CH (CH ₃) ₂	$C (=0) OCH_2CH=CH_2$
CH ₃	CH (CH ₃) ₂	C (=O) OCH (CH3) CH=CH2
CH ₃	CH(CH ₃) ₂	$^{\circ}$ C (=0) OCH (CH ₃) C (CH ₃) =CH ₂
CH ₃	CH (CH ₃) ₂	C (=O) OCH ₂ CH=CHCH ₃
CH ₃	CH (CH ₃) ₂	C (=O) OCH (CH ₃) CH=CHCH ₃
CH ₃	CH (CH ₃) ₂	$C (=O) OCH_2CH=C (CH_3)_2$
CH ₃	CH (CH ₃) ₂	C (=O) OCH ₂ CH=CHCl
CH ₃	CH (CH ₃) ₂	$C (=0) OCH_2CH=CCl_2$
CH ₃		$C (=0) OCH_2CH=CCl (CH_3)$
CH ₃	CH (CH ₃) ₂	$C (=0) OCH_2CH=CHBr$
CH ₃	CH (CH ₃) ₂	C (=O) OCH ₂ CH=CBr ₂
CH ₃	CH (CH ₃) ₂	C (=0) OCH2CH=CBr (CH3)

Table 13

R ¹	R ²	R ³
CH ₃	C(CH ₃) ₃	Н
CH ₃	C(CH ₃) ₃	CH ₃
CH ₃	C(CH ₃) ₃	CH ₂ CH ₃
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH ₃
CH ₃	C(CH ₃) ₃	CH (CH ₃) ₂
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₃
CH ₃	C(CH ₃) ₃	CH (CH ₃) CH ₂ CH ₃
CH ₃	C(CH ₃) ₃	CH ₂ CH (CH ₃) ₂
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₃
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH (CH ₃) ₂
CH ₃	C(CH ₃) ₃	CH (CH ₃) CH ₂ CH ₂ CH ₃
CH ₃	C (CH ₃) ₃	CH ₂ CH (CH ₃) CH ₂ CH ₃
CH ₃	C(CH ₃) ₃	CH (CH ₃) CH (CH ₃) ₂
CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₃
CH ₃	C(CH ₃) ₃	CH ₂ F
CH ₃	C(CH ₃) ₃	CF ₃
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ F
CH ₃	C(CH ₃) ₃	CH ₂ CF ₃
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH ₂ F
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ CF ₃
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ F
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH ₂ CF ₃
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH ₂ CF ₃
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ Cl
CH ₃	C(CH ₃) ₃	CHClCH ₂ Cl
CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ Br
CH ₃	C(CH ₃) ₃	CHBrCH2Br
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH ₂ Cl
CH ₃	C(CH ₃) ₃	CH2CHClCH2Cl
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH ₂ Br
CH ₃	C (CH ₃) ₃	CH2CHBrCH2Br
CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ Cl
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ Br
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Cl
CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br

Table 14

Table 14		
R ¹	R ²	R ³
CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Cl
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br
CH ₃	C(CH ₃) ₃	CH=CH ₂
CH ₃	C(CH ₃) ₃	CH ₂ CH=CH ₂
CH ₃	C (CH ₃) ₃	CH=CHCH ₃
CH ₃	C(CH ₃) ₃	$C(CH_3) = CH_2$
CH ₃	$C(CH_3)_3$	CH=CHCH ₂ CH ₃
CH ₃	C (CH ₃) ₃	CH ₂ CH=CHCH ₃
CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH=CH ₂
CH ₃	C (CH ₃) ₃	$C(CH_3) = CHCH_3$
CH ₃	C(CH ₃) ₃	CH (CH ₃) CH=CH ₂
CH ₃	C(CH ₃) ₃	$CH=C(CH_3)_2$
CH ₃	C(CH ₃) ₃	$CH_2C(CH_3) = CH_2$
CH ₃	$C(CH_3)_3$	$C(CH_2CH_3) = CH_2$
CH ₃	$C(CH_3)_3$	CH=CHCH ₂ CH ₂ CH ₃
CH ₃	C (CH ₃) ₃	$C(CH_3) = CHCH_2CH_3$
CH ₃	$C(CH_3)_3$	CH (CH ₃) CH=CHCH ₃
CH ₃	C (CH ₃) ₃	CH (CH ₃) CH ₂ CH=CH ₂
.CH ₃	$C(CH_3)_3$	$CH=C(CH_3)CH_2CH_3$
CH ₃	C (CH ₃) ₃	$CH_2C(CH_3) = CHCH_3$
CH ₃	C (CH ₃) ₃	CH ₂ CH (CH ₃) CH=CH ₂
CH ₃	C (CH ₃) ₃	CH=CHCH (CH ₃) ₂
CH ₃	C (CH ₃) ₃	$CH_2CH=C(CH_3)_2$
CH ₃	C (CH ₃) ₃	$CH_2CH_2C (CH_2) = CH_2$
CH ₃	C (CH ₃) ₃	CH ₂ CH=C (CH ₃) ₂
CH ₃	C (CH ₃) ₃	CH=CHCH ₂ CH ₂ CH ₂ CH ₃
CH ₃	C (CH ₃) ₃	CH=CHCl
CH ₃	C (CH ₃) ₃	CH=CCl ₂
CH ₃	C (CH ₃) ₃	CH=C (CH ₃)Cl
CH ₃	C (CH ₃) ₃	CH ₂ CH=CHCl
CH ₃	C (CH ₃) ₃	CH ₂ CCl=CHCl
CH ₃	C (CH ₃) ₃	CH ₂ CH=CCl ₂
CH ₃	C (CH ₃) ₃	CH=CHBr
CH ₃	C (CH ₃) ₃	CH=CBr ₂
CH ₃	C (CH ₃) ₃	CH=C (CH ₃) Br

Table 15

10010 10		
R 1	R ²	R ³
CH ₃	C (CH ₃) ₃	CH ₂ CH=CHBr
CH ₃	C(CH ₃) ₃	CH ₂ CBr=CHBr
CH ₃	C(CH ₃) ₃	CH ₂ CH=CBr ₂
CH ₃	C (CH ₃) ₃	CH ₂ CH=C (CH ₃) Cl
CH ₃	C (CH ₃) ₃	$CH_2CH=C(CF_3)Cl$
CH ₃	C (CH ₃) ₃	CH ₂ CH=C (CH ₃) Br
CH ₃	C (CH ₃) ₃	CH ₂ CH=C(CF ₃)Br CH=CHCF ₃
CH ₃	$C(CH_3)_3$ $C(CH_3)_3$	CH=CHCH ₂ CF ₃
CH ₃	$C(CH_3)_3$	CH ₂ CH=CHCH ₂ CF ₃
CH ₃	C (CH ₃) ₃	C≡CH
CH ₃	C (CH ₃) ₃	C≡CCH ₃
CH ₃	C (CH ₃) ₃	CH ₂ C≡CH
CH ₃	C (CH ₃) ₃	C≡CCH ₂ CH ₃
CH ₃	C (CH ₃) ₃	CH ₂ C≡CCH ₃
CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ C≡CH
CH ₃	C(CH ₃) ₃	СН (СН3) С≡СН
CH ₃	C (CH ₃) ₃	C≡CCH ₂ CH ₂ CH ₃
CH ₃	C(CH ₃) ₃	$CH_2C \equiv CCH_2CH_3$
CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ C≡CCH ₃
CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ C≡CH
CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ C≡CCH ₃
CH ₃	C (CH ₃) ₃	C≡CCl
CH ₃	C (CH ₃) ₃	CH ₂ C≡CCl
CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ C≡CCl
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH ₂ C≡CCl
CH ₃	C (CH ₃) ₃	C≡CBr
CH ₃	C (CH ₃) ₃	CH ₂ C≡CBr
CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ C≡CBr
CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ C≡CBr
CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CE CCl
CH ₃	C (CH ₃) ₃	CH ₂ OH
CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ OH
CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ OH
CH ₃	$C(CH_3)_3$	CH ₂ CH ₂ CH ₂ CH ₂ OH

Table 16

R¹	R²	R ³
CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ OH
CH ₃	C(CH ₃) ₃	CH ₂ OCH ₃
CH ₃	C(CH ₃) ₃	CH ₂ OCH ₂ CH ₃
CH ₃	C(CH ₃) ₃	CH ₂ OCH ₂ CH ₂ CH ₃
CH ₃	$C(CH_3)_3$	CH ₂ OCH (CH ₃) ₂
CH ₃	C(CH ₃) ₃	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₃
CH ₃	C(CH ₃) ₃	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₃
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ OCH ₃
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ OCH ₂ CH ₃
CH₃	C(CH ₃) ₃	CH ₂ CH ₂ OCH ₂ CH ₂ CH ₃
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ OCH (CH ₃) ₂
CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH ₂ OCH ₃
CH ₃	C(CH ₃) ₃	$C (=0) OCH_3$
CH ₃	C(CH ₃) ₃	C (=0) OCH2CH3
CH ₃	C(CH ₃) ₃	C (=0) OCH2CH2CH3
CH ₃	$C(CH_3)_3$	C (=0) OCH (CH3)2
CH ₃	C(CH ₃) ₃	C (=0) OCH2CH2CH2CH3
CH ₃	C(CH ₃) ₃	$C (=0) OCH_2CH=CH_2$
CH ₃	C(CH ₃) ₃	C (=0) OCH (CH3) CH=CH2
CH ₃	C(CH ₃) ₃	C (=0) OCH (CH3) C (CH3) = CH2
CH ₃	C(CH ₃) ₃	C (=0) OCH2CH=CHCH3
CH ₃	C(CH ₃) ₃	C (=0) OCH (CH3) CH=CHCH3
CH ₃	C(CH ₃) ₃	C (=0) OCH2CH=C (CH3)2
CH ₃	C(CH ₃) ₃	$C (=0) OCH_2CH=CHCl$
CH ₃	C(CH ₃) ₃	$C (=0) OCH_2CH=CCl_2$
CH ₃	C(CH ₃) ₃	C (=0) OCH2CH=CC1 (CH3)
CH ₃	C (CH ₃) ₃	C(=0)OCH ₂ CH=CHBr
CH ₃	C(CH ₃) ₃	$C (=0) OCH_2CH=CBr_2$
CH ₃	$C(CH_3)_3$	C (=0) OCH2CH=CBr (CH3)

Table 17

· · · · ·	0	— 3
R ¹	R ²	R 3
CH ₂ CH ₃	CH ₃	H
CH ₂ CH ₃	CH ₃	CH ₃
CH ₂ CH ₃	CH ₃	CH ₂ CH ₃
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH ₃	CH (CH ₃) ₂
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH ₃	CH (CH ₃) CH ₂ CH ₃
CH ₂ CH ₃	CH ₃	CH ₂ CH (CH ₃) ₂
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH (CH ₃) ₂
CH ₂ CH ₃	CH ₃	CH (CH ₃) CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH ₃	CH ₂ CH (CH ₃) CH ₂ CH ₃
CH ₂ CH ₃	CH ₃	CH (CH ₃) CH (CH ₃) ₂
CH ₂ CH ₃	CH₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	.CH ₃	CH ₂ F
CH ₂ CH ₃	CH ₃	CF ₃
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ F
CH ₂ CH ₃	CH ₃	CH ₂ CF ₃
.CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ F
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CF ₃
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ F
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CF ₃
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CF ₃
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ Cl
CH ₂ CH ₃	CH ₃	CHC1CH2C1
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ Br
CH ₂ CH ₃	CH ₃	CHBrCH ₂ Br
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ Cl
CH ₂ CH ₃	CH ₃	CH2CHClCH2Cl
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ Br
CH ₂ CH ₃	CH ₃	CH ₂ CHBrCH ₂ Br
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ Cl
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ Br
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Cl
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br

Table 18

Table 10			
R ¹	R ²	R ³	
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ CL	
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br	
CH ₂ CH ₃	CH ₃	CH=CH ₂	
CH ₂ CH ₃	CH ₃	CH ₂ CH=CH ₂	
CH ₂ CH ₃	CH ₃	CH=CHCH ₃	
CH ₂ CH ₃	CH ₃	$C(CH_3) = CH_2$	
CH ₂ CH ₃	CH ₃	CH=CHCH ₂ CH ₃	
CH ₂ CH ₃	CH ₃	CH ₂ CH=CHCH ₃	
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH=CH ₂	
CH ₂ CH ₃	CH ₃	$C(CH_3) = CHCH_3$	
CH ₂ CH ₃	CH ₃	CH (CH ₃) CH=CH ₂	
CH ₂ CH ₃	CH ₃	$CH=C(CH_3)_2$	
CH ₂ CH ₃	CH ₃	CH_2C (CH_3) = CH_2	
CH ₂ CH ₃	CH ₃	$C(CH_2CH_3) = CH_2$	
CH ₂ CH ₃	CH ₃	CH=CHCH ₂ CH ₂ CH ₃	
CH ₂ CH ₃	CH ₃	$C(CH_3) = CHCH_2CH_3$	
CH ₂ CH ₃	CH ₃	CH (CH ₃) CH=CHCH ₃	
CH ₂ CH ₃	CH ₃	CH (CH ₃) CH ₂ CH=CH ₂	
CH ₂ CH ₃	CH ₃	$CH=C(CH_3)CH_2CH_3$	
CH ₂ CH ₃	CH ₃	CH_2C (CH_3) = $CHCH_3$	
CH ₂ CH ₃	CH ₃	CH ₂ CH (CH ₃) CH=CH ₂	
CH ₂ CH ₃	CH ₃	CH=CHCH (CH ₃) ₂	
CH ₂ CH ₃	CH ₃	$CH_2CH=C(CH_3)_2$	
CH ₂ CH ₃	CH ₃	$CH_2CH_2C (CH_2) = CH_2$	
CH ₂ CH ₃	CH ₃	CH ₂ CH=C (CH ₃) ₂	
CH ₂ CH ₃	CH ₃	CH=CHCH ₂ CH ₂ CH ₂ CH ₃	
CH ₂ CH ₃	CH ₃	CH=CHC1	
CH ₂ CH ₃	CH ₃	CH=CCl ₂	
CH ₂ CH ₃	CH ₃	CH=C(CH ₃)Cl	
CH ₂ CH ₃	CH ₃	CH ₂ CH=CHCl	
CH ₂ CH ₃	CH ₃	CH ₂ CCl=CHCl	
CH ₂ CH ₃	CH ₃	CH ₂ CH=CCl ₂	
CH ₂ CH ₃	CH ₃	CH=CHBr	
CH ₂ CH ₃	CH ₃	CH=CBr ₂	
CH ₂ CH ₂	CH ₃	CH=C(CH ₃)Br	

Table 19

			· · · · · · · · · · · · · · · · · · ·	_
	R¹	R ²	R ³	
İ	CH ₂ CH ₃	CH ₃	CH ₂ CH=CHBr	
ļ	CH ₂ CH ₃	CH ₃	CH ₂ CBr=CHBr	İ
١	CH ₂ CH ₃	CH ₃	CH ₂ CH=CBr ₂	
١	CH ₂ CH ₃	CH₃	$CH_2CH=C(CH_3)Cl$	Ì
١	CH ₂ CH ₃	CH ₃	CH ₂ CH=C (CF ₃) Cl	1
ı	CH ₂ CH ₃	CH₃	CH ₂ CH=C (CH ₃) Br	١
	CH ₂ CH ₃	CH ₃	CH ₂ CH=C (CF ₃)Br	ı
ı	CH ₂ CH ₃	CH ₃	CH=CHCF ₃ CH=CHCH ₂ CF ₃	١
	CH ₂ CH ₃	CH₃ CH₃	CH_CHCH ₂ CF ₃ CH ₂ CH=CHCH ₂ CF ₃	
	CH ₂ CH ₃ CH ₂ CH ₃	CH ₃	C≡CH ·	1
	CH ₂ CH ₃	CH ₃	C≡CCH ₃	1
	CH ₂ CH ₃	CH ₃	CH ₂ C≡CH	
	CH ₂ CH ₃	CH ₃	C≡CCH ₂ CH ₃	Ì
	CH ₂ CH ₃	CH ₃	CH ₂ C≡CCH ₃	
	CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ C≡CH	
	CH ₂ CH ₃	CH ₃	CH (CH ₃) C≡CH	
	CH ₂ CH ₃	CH ₃	C≡CCH ₂ CH ₂ CH ₃	1
	CH ₂ CH ₃	CH ₃	CH ₂ C≡CCH ₂ CH ₃	}
	CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ C≡CCH ₃	
	CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ C≡CH	
	CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ C≡CCH ₃	
	CH ₂ CH ₃	CH ₃	C≡CCl	
	CH ₂ CH ₃	CH ₃	CH ₂ C≡CCl	
	CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ C≡CCl	1
	CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ C≡CCl	
	CH ₂ CH ₃	CH ₃	C≡CBr	
	CH ₂ CH ₃	CH ₃	CH ₂ C≡CBr	
	CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ C≡CBr	
	CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ C≡CBr	
	CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ C≡CCl	
	CH ₂ CH ₃	CH ₃	CH ₂ OH	
	CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ OH	
	CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ OH	
	CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ OH	

Table 20

R ¹	R ²	R ³
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ OH
CH ₂ CH ₃ .	CH ₃	CH ₂ OCH ₃
CH ₂ CH ₃	CH ₃	CH ₂ OCH ₂ CH ₃
CH ₂ CH ₃	CH ₃	CH ₂ OCH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH ₃	CH ₂ OCH (CH ₃) ₂
CH ₂ CH ₃	CH ₃	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH ₃	CH2OCH2CH2CH2CH3
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ OCH ₃
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ OCH ₂ CH ₃
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ OCH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ OCH (CH ₃) ₂
CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₂ OCH ₃
CH ₂ CH ₃	CH ₃	$C (=0) OCH_3$
CH ₂ CH ₃	CH ₃	$C (=O) OCH_2CH_3$
CH ₂ CH ₃	CH ₃	C (=0) OCH2CH2CH3
CH ₂ CH ₃	CH₃	C (=0) OCH (CH ₃) ₂
CH ₂ CH ₃	CH ₃	C (=O) OCH2CH2CH2CH3
CH ₂ CH ₃	CH₃	$C (=O) OCH_2CH=CH_2$
CH ₂ CH ₃	CH ₃	C (=O) OCH (CH3) CH=CH2
CH ₂ CH ₃	CH₃	C (=O) OCH (CH3) C (CH3) = CH2
CH ₂ CH ₃	CH ₃	$C (=0) OCH_2CH=CHCH_3$
CH ₂ CH ₃	CH ₃	C (=0) OCH (CH3) CH=CHCH3
CH ₂ CH ₃	CH ₃	$C (=O) OCH_2CH=C (CH_3)_2$
CH ₂ CH ₃	CH ₃	$C (=0) OCH_2CH=CHC1$
CH ₂ CH ₃	CH ₃	$C (=0) OCH_2CH=CCl_2$
CH ₂ CH ₃	CH ₃	C (=0) OCH2CH=CC1 (CH3)
CH ₂ CH ₃	CH ₃	C(=O)OCH ₂ CH=CHBr
CH ₂ CH ₃	CH ₃	$C (=0) OCH_2CH=CBr_2$
CH ₂ CH ₃	CH ₃	C (=0) OCH2CH=CBr (CH3)

Table 21

rapre 7T		
R ¹	R ²	R ³
CH ₂ CH ₃	CH ₂ CH ₃	Н
CH ₂ CH ₃	CH ₂ CH ₃	CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH (CH ₃) ₂
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH (CH ₃) CH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH (CH ₃) ₂
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH (CH ₃) ₂
CH ₂ CH ₃	CH ₂ CH ₃	CH (CH ₃) CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH (CH ₃) CH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH (CH ₃) CH (CH ₃) ₂
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ F
CH ₂ CH ₃	CH ₂ CH ₃	CF ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ F
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CF ₃
.CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ F
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CF ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ F
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CF ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CF ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ Cl
CH ₂ CH ₃	CH ₂ CH ₃	CHClCH2Cl
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ Br
CH ₂ CH ₃	CH ₂ CH ₃	CHBrCH ₂ Br
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ Cl
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CHClCH ₂ Cl
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ Br
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CHBrCH ₂ Br
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ Cl
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ Br
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CL
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br

Table 22

10016 22		
R ¹	R ²	R ³
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ CL
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br
CH ₂ CH ₃	CH ₂ CH ₃	CH=CH ₂
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH=CH ₂
CH ₂ CH ₃	CH ₂ CH ₃	CH=CHCH ₃
CH ₂ CH ₃	CH ₂ CH ₃	$C(CH_3) = CH_2$
CH ₂ CH ₃	CH ₂ CH ₃	CH=CHCH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH=CHCH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH=CH ₂
CH ₂ CH ₃	CH ₂ CH ₃	$C(CH_3) = CHCH_3$
CH ₂ CH ₃	CH ₂ CH ₃	CH (CH ₃) CH=CH ₂
CH ₂ CH ₃	CH ₂ CH ₃	CH=C(CH ₃) ₂
CH ₂ CH ₃	CH ₂ CH ₃	$CH_2C(CH_3) = CH_2$
CH ₂ CH ₃	CH ₂ CH ₃	C (CH2CH3) = CH2
CH ₂ CH ₃	CH ₂ CH ₃	CH=CHCH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	$C(CH_3) = CHCH_2CH_3$
CH ₂ CH ₃	CH ₂ CH ₃	CH (CH ₃) CH=CHCH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH (CH ₃) CH ₂ CH=CH ₂
CH ₂ CH ₃	CH ₂ CH ₃	$CH=C(CH_3)CH_2CH_3$
CH ₂ CH ₃	CH ₂ CH ₃	$CH_2C(CH_3) = CHCH_3$
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH (CH ₃) CH=CH ₂
CH ₂ CH ₃	CH ₂ CH ₃	CH=CHCH (CH ₃) ₂
CH ₂ CH ₃	CH ₂ CH ₃	$CH_2CH=C(CH_3)_2$
CH ₂ CH ₃	CH ₂ CH ₃	CH_2CH_2C (CH_2) = CH_2
CH ₂ CH ₃	CH ₂ CH ₃	$CH_2CH=C(CH_3)_2$
CH ₂ CH ₃	CH ₂ CH ₃	CH=CHCH ₂ CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH=CHC1
CH ₂ CH ₃	CH ₂ CH ₃	CH=CCl ₂
CH ₂ CH ₃	CH ₂ CH ₃	CH=C(CH ₃)Cl
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH=CHCl
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CCl=CHCl
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH=CCl ₂
CH ₂ CH ₃	CH ₂ CH ₃	CH=CHBr
CH ₂ CH ₃	CH ₂ CH ₃	CH=CBr ₂
CH ₂ CH ₃	CH ₂ CH ₃	CH=C(CH ₃)Br

Table 23

,		
R ¹	R ²	R ³
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH=CHBr
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CBr=CHBr
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH=CBr ₂
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH=C (CH ₃)Cl
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH=C (CF ₃) Cl
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH=C(CH ₃)Br
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH=C(CF ₃)Br CH=CHCF ₃
CH ₂ CH ₃	CH ₂ CH ₃ CH ₂ CH ₃	CH=CHCH ₂ CF ₃
CH ₂ CH ₃ CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH=CHCH ₂ CF ₃
CH ₂ CH ₃	CH ₂ CH ₃	C≡CH
CH ₂ CH ₃	CH ₂ CH ₃	C≡CCH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ C≡CH
CH ₂ CH ₃	CH ₂ CH ₃	C≡CCH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ C≡CCH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ C≡CH
CH ₂ CH ₃	CH ₂ CH ₃	СН (СН3) С≡СН
CH ₂ CH ₃	CH ₂ CH ₃	C≡CCH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ C≡CCH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ C≡CCH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ C≡CH
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ C≡CCH ₃
CH ₂ CH ₃	CH ₂ CH ₃	c≡ccl
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ C≡CCl
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ C≡CCl
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ C≡CCl
CH ₂ CH ₃	CH ₂ CH ₃	C≡CBr
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ C≡CBr
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ C≡CBr
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ C≡CBr
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ C≡CCl
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ OH
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ OH
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ OH
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ OH

Table 24

Table 24		
R¹	R ²	R ³
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ OH
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ OCH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ OCH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ OCH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ OCH (CH ₃) ₂
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ OCH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ OCH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ OCH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ OCH (CH ₃) ₂
CH ₂ CH ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ OCH ₃
CH ₂ CH ₃	CH ₂ CH ₃	$C (=0) OCH_3$
CH ₂ CH ₃	CH ₂ CH ₃	C (=O) OCH2CH3
CH ₂ CH ₃	CH ₂ CH ₃	C (=0) OCH2CH2CH3
CH ₂ CH ₃	CH ₂ CH ₃	C (=O) OCH (CH3)2
CH ₂ CH ₃	CH ₂ CH ₃	C (=O) OCH2CH2CH2CH3
CH ₂ CH ₃	CH ₂ CH ₃	C (=0) OCH2CH=CH2
CH ₂ CH ₃	CH ₂ CH ₃	C (=O) OCH (CH3) CH=CH2
CH ₂ CH ₃	CH ₂ CH ₃	C (=0) OCH (CH3) C (CH3) = CH2
CH ₂ CH ₃	CH ₂ CH ₃	C (=0) OCH2CH=CHCH3
CH ₂ CH ₃	CH ₂ CH ₃	C (=O) OCH (CH3) CH=CHCH3
CH ₂ CH ₃	CH ₂ CH ₃	C (=0) OCH2CH=C (CH3)2
CH ₂ CH ₃	CH ₂ CH ₃	C (=0) OCH2CH=CHCl
CH ₂ CH ₃	CH ₂ CH ₃	$C (=0) OCH_2CH=CCl_2$
CH ₂ CH ₃	CH ₂ CH ₃	C (=0) OCH2CH=CCl (CH3)
CH ₂ CH ₃	CH ₂ CH ₃	C(=O)OCH ₂ CH=CHBr
CH ₂ CH ₃	CH ₂ CH ₃	C (=O) OCH ₂ CH=CBr ₂
CH ₂ CH ₃	CH ₂ CH ₃	$C (=0) OCH_2CH=CBr (CH_3)$

Table 25

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R¹	R ²	R ³	
CH ₂ CH ₃	CH (CH ₃) ₂	Н	
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₃	
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₃	
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₃	
CH ₂ CH ₃	ĊH (CH ₃) ₂	CH (CH ₃) ₂	
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₃	
CH ₂ CH ₃	CH (CH ₃) ₂	CH (CH ₃) CH ₂ CH ₃	
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH (CH ₃) ₂	
CH ₂ CH ₃	CH(CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ CH ₃	
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH (CH ₃) ₂	
CH ₂ CH ₃	CH (CH ₃) ₂	CH (CH ₃) CH ₂ CH ₂ CH ₃	
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH (CH ₃) CH ₂ CH ₃	
CH ₂ CH ₃	CH (CH ₃) ₂	CH (CH ₃) CH (CH ₃) ₂	
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ CH ₃	
CH ₂ CH ₃	CH(CH ₃) ₂	CH ₂ F	
CH ₂ CH ₃	CH (CH ₃) ₂	CF ₃	
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ F	
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CF ₃	
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ F	
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CF ₃	
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ F	
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CF ₃	
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CF ₃	
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ Cl	
CH ₂ CH ₃	CH (CH ₃) ₂	CHClCH2Cl	
CH ₂ CH ₃	CH(CH ₃) ₂	CH ₂ CH ₂ Br	
CH ₂ CH ₃	CH(CH ₃) ₂	CHBrCH ₂ Br	
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ Cl	
CH ₂ CH ₃	CH(CH ₃) ₂	CH2CHClCH2Cl	
CH ₂ CH ₃	CH(CH ₃) ₂	CH ₂ CH ₂ CH ₂ Br	
CH ₂ CH ₃	CH(CH ₃) ₂	CH ₂ CHBrCH ₂ Br	
CH ₂ CH ₃	CH(CH ₃) ₂	CH ₂ CH ₂ CH ₂ Cl	
CH ₂ CH ₃	CH(CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ Br	
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ C1	
CH ₂ CH ₃	CH(CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br	

Table 26

R ¹	R ²	R ³
CH ₂ CH ₃	CH (CH ₃) ₂	CH2CH2CH2CH2CH2CL
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br
CH ₂ CH ₃	CH (CH ₃) ₂	CH=CH ₂
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH=CH ₂
CH ₂ CH ₃	CH (CH ₃) ₂	CH=CHCH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	$C(CH_3) = CH_2$
CH ₂ CH ₃	CH (CH ₃) ₂	CH=CHCH ₂ CH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH=CHCH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH=CH ₂
CH ₂ CH ₃	CH (CH ₃) ₂	$C(CH_3) = CHCH_3$
CH ₂ CH ₃	CH (CH ₃) ₂	CH (CH ₃) CH=CH ₂
CH ₂ CH ₃	CH (CH ₃) ₂	CH=C(CH ₃) ₂
CH ₂ CH ₃	CH(CH ₃) ₂	$CH_2C(CH_3) = CH_2$
CH ₂ CH ₃	CH (CH ₃) ₂	$C(CH_2CH_3) = CH_2$
CH ₂ CH ₃	CH (CH ₃) ₂	CH=CHCH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	$C(CH_3) = CHCH_2CH_3$
CH ₂ CH ₃	CH (CH ₃) ₂	CH (CH ₃) CH=CHCH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	CH (CH ₃) CH ₂ CH=CH ₂
CH ₂ CH ₃	CH (CH ₃) ₂	$CH=C(CH_3)CH_2CH_3$
CH ₂ CH ₃	CH (CH ₃) ₂	$CH_2C(CH_3) = CHCH_3$
CH ₂ CH ₃	CH (CH ₃) ₂	CH_2CH (CH_3) $CH=CH_2$
CH ₂ CH ₃	CH (CH ₃) ₂	CH=CHCH (CH ₃) ₂
CH ₂ CH ₃	CH (CH ₃) ₂	$CH_2CH=C(CH_3)_2$
CH ₂ CH ₃	CH (CH ₃) ₂	$CH_2CH_2C (CH_2) = CH_2$
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH=C (CH ₃) ₂
CH ₂ CH ₃	CH (CH ₃) ₂	CH=CHCH ₂ CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	CH=CHC1
CH ₂ CH ₃	CH (CH ₃) ₂	CH=CCl ₂
CH ₂ CH ₃	CH (CH ₃) ₂	CH=C(CH ₃)Cl
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH=CHCl
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CCl=CHCl
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH=CCl ₂
CH ₂ CH ₃	CH (CH ₃) ₂	CH=CHBr
CH ₂ CH ₃	CH (CH ₃) ₂	CH=CBr ₂
CH ₂ CH ₃	CH (CH ₃) ₂	CH=C(CH ₃)Br

Table 27

R 1	R ²	R ³
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH=CHBr CH ₂ CBr=CHBr
CH ₂ CH ₃	CH (CH ₃) ₂ CH (CH ₃) ₂	CH ₂ CH=CBr ₂
CH ₂ CH ₃ CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH=C (CH ₃) Cl
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH=C (CF ₃) Cl
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH=C(CH ₃)Br
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH=C(CF ₃)Br
CH ₂ CH ₃	CH (CH ₃) ₂	CH=CHCF ₃
CH ₂ CH ₃	CH (CH ₃) ₂	CH=CHCH ₂ CF ₃
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH=CHCH ₂ CF ₃
CH ₂ CH ₃	CH (CH ₃) ₂	C≡CH
CH ₂ CH ₃	CH (CH ₃) ₂	C≡CCH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ C≡CH
CH ₂ CH ₃	CH (CH ₃) ₂	C≡CCH ₂ CH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ C≡CCH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ C≡CH
CH ₂ CH ₃	CH (CH ₃) ₂	CH (CH ₃) C≡CH
CH ₂ CH ₃	CH (CH ₃) ₂	C≡CCH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ C≡CCH ₂ CH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ C≡CCH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ C≡CH
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ C≡CCH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	C≡CC1
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ C≡CCl
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ C≡CCl
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ C≡CCl
CH ₂ CH ₃	CH (CH ₃) ₂	C≡CBr
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ C≡CBr
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ C≡CBr
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ C≡CBr
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ C≡CCl
CH ₂ CH ₃	CH (CH ₃) ₂	
CH ₂ CH ₃	CH (CH ₃) ₂	
CH ₂ CH ₃		CH ₂ CH ₂ CH ₂ OH
CH ₂ CH ₃	$ CH(CH_3)_2 $	CH ₂ CH ₂ CH ₂ CH ₂ OH

Table 28

R 1	R ²	R ³
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ OH
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ OCH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ OCH ₂ CH ₃
CH ₂ CH ₃	$CH(CH_3)_2$	CH ₂ OCH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ OCH (CH ₃) ₂
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ OCH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ OCH ₂ CH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ OCH ₂ CH ₂ CH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ OCH (CH ₃) ₂
CH ₂ CH ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ OCH ₃
CH ₂ CH ₃	CH (CH ₃) ₂	$C (=0) OCH_3$
CH ₂ CH ₃	CH (CH ₃) ₂	
CH ₂ CH ₃	CH (CH ₃) ₂	C (=O) OCH2CH2CH3
CH ₂ CH ₃	CH (CH ₃) ₂	C (=0) OCH (CH3)2
CH ₂ CH ₃	CH (CH ₃) ₂	C (=O) OCH2CH2CH2CH3
CH ₂ CH ₃	CH (CH ₃) ₂	$C (=O) OCH_2CH=CH_2$
CH ₂ CH ₃	CH (CH ₃) ₂	C (=O) OCH (CH3) CH=CH2
CH ₂ CH ₃	CH (CH ₃) ₂	C (=O) OCH (CH3) C (CH3) = CH2
CH ₂ CH ₃	CH (CH ₃) ₂	
CH ₂ CH ₃	CH (CH ₃) ₂	
CH2CH3	CH (CH ₃) ₂	
CH ₂ CH ₃	CH(CH ₃) ₂	$C (=0) OCH_2CH=CHCl$
CH ₂ CH ₃	CH (CH ₃) ₂	$C (=0) OCH_2CH=CCl_2$
CH ₂ CH ₃	CH (CH ₃) ₂	C (=0) OCH2CH=CCl (CH3)
CH ₂ CH ₃	CH (CH ₃) ₂	C(=O)OCH ₂ CH=CHBr
CH ₂ CH ₃	CH (CH ₃) ₂	C(=0)OCH ₂ CH=CBr ₂
CH ₂ CH ₃	CH (CH ₃) ₂	C(=0)OCH ₂ CH=CBr(CH ₃)

Table 29

R¹	R ²	R³
CH ₂ CH ₃	C (CH ₃) ₃	Н
CH ₂ CH ₃	C (CH ₃) ₃	CH ₃
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₃
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	C (CH ₃) ₃	CH (CH ₃) ₂
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	C(CH ₃) ₃	CH (CH ₃) CH ₂ CH ₃
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH (CH ₃) ₂
CH ₂ CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH (CH ₃) ₂
CH ₂ CH ₃	C(CH ₃) ₃	CH (CH ₃) CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	C (CH ₃) ₃	CH_2CH (CH_3) CH_2CH_3
CH ₂ CH ₃	C (CH ₃) ₃	$CH (CH_3) CH (CH_3)_2$
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ F
CH ₂ CH ₃	C (CH ₃) ₃	CF ₃
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ F
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CF ₃
.CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ F
CH2CH3	C (CH ₃) ₃	CH ₂ CH ₂ CF ₃
CH ₂ CH ₃	$C(CH_3)_3$	CH ₂ CH ₂ CH ₂ CH ₂ F
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CF ₃
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ CF ₃
CH ₂ CH ₃	$C(CH_3)_3$	CH ₂ CH ₂ Cl
CH ₂ CH ₃	C (CH ₃) ₃	CHClCH ₂ Cl
CH ₂ CH ₃	$C(CH_3)_3$	CH ₂ CH ₂ Br
CH ₂ CH ₃	$C(CH_3)_3$	CHBrCH ₂ Br
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ Cl
CH ₂ CH ₃	$C(CH_3)_3$	CH2CHClCH2Cl
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ Br
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CHBrCH ₂ Br
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CL
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ Br
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ Cl
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br

Table 30

R 1	R ²	R ³	
CH ₂ CH ₃	C (CH ₃) ₃	CH2CH2CH2CH2CH2CH2C1	
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br	
CH ₂ CH ₃	C (CH ₃) ₃	CH=CH ₂	
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH=CH ₂	
CH ₂ CH ₃	C (CH ₃) ₃	CH=CHCH ₃	
CH ₂ CH ₃	C (CH ₃) ₃	$C(CH_3) = CH_2$	
CH ₂ CH ₃	C (CH ₃) ₃	CH=CHCH ₂ CH ₃	
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH=CHCH ₃	
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH=CH ₂	
CH ₂ CH ₃	C(CH ₃) ₃	$C(CH_3) = CHCH_3$	
CH ₂ CH ₃	C(CH ₃) ₃	CH (CH ₃) CH=CH ₂	
CH ₂ CH ₃	C (CH ₃) ₃	CH=C(CH ₃) ₂	
CH ₂ CH ₃	C(CH ₃) ₃	$CH_2C(CH_3) = CH_2$	
CH ₂ CH ₃	$C(CH_3)_3$	$C(CH_2CH_3) = CH_2$	
CH ₂ CH ₃	C (CH ₃) ₃	CH=CHCH ₂ CH ₂ CH ₃	
CH ₂ CH ₃	C (CH ₃) ₃	$C(CH_3) = CHCH_2CH_3$	
CH ₂ CH ₃	C (CH ₃) ₃	CH (CH ₃) CH=CHCH ₃	
CH ₂ CH ₃	C (CH ₃) ₃	CH (CH ₃) CH ₂ CH=CH ₂	
CH ₂ CH ₃	C (CH ₃) ₃	$CH=C(CH_3)CH_2CH_3$	
CH ₂ CH ₃	C (CH ₃) ₃	CH_2C (CH_3) = $CHCH_3$	
CH ₂ CH ₃	C(CH ₃) ₃	CH ₂ CH (CH ₃) CH=CH ₂	
CH ₂ CH ₃	C (CH ₃) ₃	CH=CHCH (CH ₃) ₂	
CH ₂ CH ₃	C (CH ₃) ₃	$CH_2CH=C(CH_3)_2$	
CH ₂ CH ₃	C (CH ₃) ₃	$CH_2CH_2C (CH_2) = CH_2$	
CH ₂ CH ₃	C (CH ₃) ₃	$CH_2CH=C(CH_3)_2$	
CH ₂ CH ₃	C (CH ₃) ₃	CH=CHCH ₂ CH ₂ CH ₂ CH ₃	
CH ₂ CH ₃	C (CH ₃) ₃	CH=CHC1	
CH ₂ CH ₃	C (CH ₃) ₃	CH=CCl ₂	
CH ₂ CH ₃	C (CH ₃) ₃	$CH=C(CH_3)Cl$	
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH=CHCl	
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CCl=CHCl	
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH=CCl ₂	
CH ₂ CH ₃	C (CH ₃) ₃	CH=CHBr	
CH ₂ CH ₃	C (CH ₃) ₃	CH=CBr ₂	
CH ₂ CH ₃	C (CH ₃) ₃	CH=C(CH ₃)Br	

Table 31

R 1	R ²	R ³
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH=CHBr
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CBr=CHBr
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH=CBr ₂
CH ₂ CH ₃	C (CH ₃) ₃	$CH_2CH=C(CH_3)Cl$
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH=C (CF ₃)Cl
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH=C(CH ₃)Br CH ₂ CH=C(CF ₃)Br
CH ₂ CH ₃	C (CH ₃) ₃ C (CH ₃) ₃	CH=CHCF ₃
CH ₂ CH ₃ CH ₂ CH ₃	$C (CH_3)_3$	CH=CHCH ₂ CF ₃
CH ₂ CH ₃	$C(CH_3)_3$	CH ₂ CH=CHCH ₂ CF ₃
CH ₂ CH ₃	C (CH ₃) ₃	C≡CH
CH ₂ CH ₃	C (CH ₃) ₃	C≡CCH ₃
CH ₂ CH ₃	C (CH ₃) ₃	CH₂C≡CH
CH ₂ CH ₃	C (CH ₃) ₃	C≡CCH ₂ CH ₃
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ C≡CCH ₃
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ C≡CH
CH ₂ CH ₃	C (CH ₃) ₃	CH(CH ₃)C≡CH
CH ₂ CH ₃	C (CH ₃) ₃	$C \equiv CCH_2CH_2CH_3$
CH ₂ CH ₃	C (CH ₃) ₃	$CH_2C \equiv CCH_2CH_3$
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ C≡CCH ₃
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ C≡CH
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ C≡CCH ₃
CH ₂ CH ₃	C (CH ₃) ₃	C≡CCl
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ C≡CCl
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ C≡CCl
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ C≡CCl
CH ₂ CH ₃	C(CH ₃) ₃	C≡CBr
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ C≡CBr
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ C≡CBr
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ C≡CBr
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ C≡CCl
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ OH
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ OH
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ OH
CH ₂ CH ₃	$C(CH_3)_3$	CH ₂ CH ₂ CH ₂ CH ₂ OH

Table 32

R ¹	R ²	R ³
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ OH
CH ₂ CH ₃	C(CH ₃) ₃	CH ₂ OCH ₃
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ OCH ₂ CH ₃
CH ₂ CH ₃	C(CH ₃) ₃	CH ₂ OCH ₂ CH ₂ CH ₃
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ OCH (CH ₃) ₂
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₃
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ OCH ₃
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ OCH ₂ CH ₃
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ OCH ₂ CH ₂ CH ₃
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ OCH (CH ₃) ₂
CH ₂ CH ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ OCH ₃
CH ₂ CH ₃	C(CH ₃) ₃	$C (=0) OCH_3$
CH ₂ CH ₃	C(CH ₃) ₃	C (=O) OCH2CH3
CH ₂ CH ₃	C(CH ₃) ₃	C (=0) OCH2CH2CH3
CH ₂ CH ₃	C(CH ₃) ₃	C (=O) OCH (CH3)2
CH ₂ CH ₃	C (CH ₃) ₃	$C (=O) OCH_2CH_2CH_2CH_3$
CH ₂ CH ₃	C (CH ₃) ₃	$C (=O) OCH_2CH=CH_2$
CH ₂ CH ₃	C(CH ₃) ₃	C (=O) OCH (CH3) CH=CH2
CH ₂ CH ₃	C (CH ₃) ₃	C (=O) OCH (CH3) C (CH3) = CH2
CH ₂ CH ₃	C(CH ₃) ₃	C (=0) OCH2CH=CHCH3
CH ₂ CH ₃	C (CH ₃) ₃	C (=O) OCH (CH3) CH=CHCH3
CH ₂ CH ₃	$C(CH_3)_3$	C (=0) OCH2CH=C (CH3)2
CH ₂ CH ₃	C (CH ₃) ₃	C (=O) OCH ₂ CH=CHCl
CH ₂ CH ₃	$C(CH_3)_3$	$C (=0) OCH_2CH=CCl_2$
CH ₂ CH ₃	C (CH ₃) ₃	C (=O) OCH ₂ CH=CCl (CH ₃)
CH ₂ CH ₃	C (CH ₃) ₃	C (=O) OCH ₂ CH=CHBr
CH ₂ CH ₃	C (CH ₃) ₃	C (=O) OCH ₂ CH=CBr ₂
CH ₂ CH ₃	$C(CH_3)_3$	C(=O)OCH ₂ CH=CBr(CH ₃)

Table 33

	R¹	R ²	R ³	
ſ	CF ₃	CH ₃	H .	
1	CF ₃	CH ₃	CH ₃	
١	CF ₃	CH ₃	CH ₂ CH ₃	
1	CF ₃	CH ₃ .	CH ₂ CH ₂ CH ₃	
I	CF ₃	CH ₃	CH (CH ₃) ₂	
١	CF ₃	CH₃	CH ₂ CH ₂ CH ₂ CH ₃	
١	CF ₃	CH₃	CH (CH ₃) CH ₂ CH ₃	
١	CF ₃	CH ₃	CH ₂ CH (CH ₃) ₂	
١	CF ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₃	
	CF ₃	CH ₃	CH ₂ CH ₂ CH (CH ₃) ₂	
	CF ₃	CH ₃	CH (CH ₃) CH ₂ CH ₂ CH ₃	
١	CF ₃	CH ₃	CH ₂ CH (CH ₃) CH ₂ CH ₃	
	CF ₃	CH ₃	CH (CH ₃) CH (CH ₃) ₂	
	CF ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₃	
	CF ₃	CH ₃	CH ₂ F	
	CF ₃	CH ₃	CF ₃	
	CF ₃	CH ₃	CH ₂ CH ₂ F	
	CF ₃	CH ₃	CH ₂ CF ₃	
	.CF ₃	CH ₃	CH ₂ CH ₂ CH ₂ F	
į	CF ₃	CH ₃	CH ₂ CH ₂ CF ₃	
	CF ₃	CḤ3	CH ₂ CH ₂ CH ₂ CH ₂ F	
	CF ₃	CH ₃	CH ₂ CH ₂ CH ₂ CF ₃	
	CF ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CF ₃	
	CF3	CH ₃	CH ₂ CH ₂ Cl	
	CF ₃	CH ₃	CHC1CH2C1	
	CF3	CH ₃	CH ₂ CH ₂ Br	
	CF ₃	CH ₃	CHBrCH ₂ Br	
	CF ₃	CH ₃	CH ₂ CH ₂ CH ₂ Cl	
	CF ₃	CH ₃	CH2CHClCH2Cl	
	CF ₃	CH ₃	CH ₂ CH ₂ CH ₂ Br	
	CF ₃	CH ₃	CH ₂ CHBrCH ₂ Br	
	CF3	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ Cl	
	CF3	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ Br	
	CF3	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Cl	
	CF ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br	

Table 34

R 1	R ²	R ³
CF ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ CL
CF ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br
CF ₃	CH ₃	CH=CH ₂
CF ₃	CH ₃	CH ₂ CH=CH ₂
CF ₃	CH₃	CH=CHCH ₃
CF ₃	CH ₃	$C(CH_3) = CH_2$
CF ₃	CH ₃	CH=CHCH ₂ CH ₃
CF ₃	CH ₃	CH ₂ CH=CHCH ₃
CF ₃	CH ₃	CH ₂ CH ₂ CH=CH ₂
CF ₃	CH ₃	$C(CH_3) = CHCH_3$
CF ₃	CH ₃	CH (CH ₃) CH=CH ₂
CF ₃	CH ₃	CH=C (CH ₃) ₂
CF ₃	CH ₃	$CH_2C(CH_3) = CH_2$
CF ₃	CH ₃	$C(CH_2CH_3) = CH_2$
CF ₃	CH ₃	CH=CHCH ₂ CH ₂ CH ₃
CF ₃	CH ₃	$C(CH_3) = CHCH_2CH_3$
CF ₃	CH ₃	CH (CH ₃) CH=CHCH ₃
CF ₃	CH ₃	CH (CH ₃) CH ₂ CH=CH ₂
CF ₃	CH ₃	$CH=C(CH_3)CH_2CH_3$
CF ₃	CH ₃	$CH_2C(CH_3) = CHCH_3$
CF ₃	CH ₃	CH ₂ CH (CH ₃) CH=CH ₂
CF ₃	CH ₃	CH=CHCH (CH ₃) ₂
CF ₃	CH ₃	$CH_2CH=C(CH_3)_2$
CF ₃	CH ₃	CH_2CH_2C (CH_2) = CH_2
CF ₃	CH ₃	CH ₂ CH=C (CH ₃) ₂
CF ₃	CH ₃	CH=CHCH ₂ CH ₂ CH ₂ CH ₃
CF ₃	CH ₃	CH=CHCl
CF ₃	CH ₃	CH=CCl ₂
CF ₃	CH ₃	CH=C(CH ₃)Cl
CF ₃	CH ₃	CH ₂ CH=CHCl
CF ₃	CH ₃	CH ₂ CCl=CHCl
CF ₃	CH ₃	CH ₂ CH=CCl ₂
CF ₃	CH ₃	CH=CHBr
CF ₃	CH ₃	CH=CBr ₂
CF ₃	CH ₃	CH=C(CH ₃)Br

Table 35

Table 33		
R ¹	R ²	R ³
CF ₃	CH ₃	CH ₂ CH=CHBr
CF ₃	CH ₃	CH ₂ CBr=CHBr
CF ₃	CH ₃	CH ₂ CH=CBr ₂
CF ₃	CH ₃	CH ₂ CH=C (CH ₃) Cl
CF ₃	CH ₃	CH ₂ CH=C (CF ₃)Cl
CF ₃	CH ₃	CH ₂ CH=C (CH ₃)Br
CF ₃	CH ₃	CH ₂ CH=C (CF ₃)Br CH=CHCF ₃
CF ₃	CH ₃	CH=CHCH ₂ CF ₃
CF ₃	CH ₃ CH ₃	CH ₂ CH=CHCH ₂ CF ₃
CF ₃	CH ₃	C≡CH
CF ₃	CH ₃	C≡CCH ₃
CF ₃	CH ₃	CH ₂ C≡CH
CF ₃	CH ₃	C≡CCH ₂ CH ₃
CF ₃	CH ₃	CH ₂ C≡CCH ₃
CF ₃	CH ₃	CH ₂ CH ₂ C≡CH
CF ₃	CH ₃	CH (CH ₃) C≡CH
_	CH ₃	C≡CCH ₂ CH ₂ CH ₃
CF ₃	1 -	
CF ₃	CH ₃	CH ₂ C≡CCH ₂ CH ₃
CF ₃	CH ₃	CH ₂ CH ₂ C≡CCH ₃
CF ₃	CH ₃	CH ₂ CH ₂ CH ₂ C≡CH
CF ₃	CH ₃	CH ₂ CH ₂ CH ₂ C≡CCH ₃
CF ₃	CH ₃	C≡CC1
CF ₃	CH ₃	CH ₂ C≡CCl
CF ₃	CH ₃	CH ₂ CH ₂ C≡CCl
CF3	CH₃	CH ₂ CH ₂ CH ₂ C≡CCl
CF ₃	CH ₃	C≡CBr
CF ₃	CH ₃	CH ₂ C≡CBr
CF ₃	CH ₃	CH ₂ CH ₂ C≡CBr
CF ₃	CH ₃	CH ₂ CH ₂ CH ₂ C≡CBr
CF ₃	CH₃	CH ₂ CH ₂ CH ₂ CE CCl
CF ₃	CH ₃	CH ₂ OH
CF ₃	CH ₃	CH ₂ CH ₂ OH
CF ₃	CH ₃	CH ₂ CH ₂ CH ₂ OH
CF3	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ OH

Table 36

R 1	R ²	R ³
CF ₃	CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ OH
CF ₃	CH ₃	CH ₂ OCH ₃
CF ₃	CH ₃	CH ₂ OCH ₂ CH ₃
CF ₃	CH ₃	CH ₂ OCH ₂ CH ₂ CH ₃
CF ₃	CH ₃	CH ₂ OCH (CH ₃) ₂
CF ₃	CH ₃	CH ₂ OCH ₂ CH ₂ CH ₃
CF ₃	CH ₃	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₃
CF ₃ ·	CH ₃	CH ₂ CH ₂ OCH ₃
CF ₃	CH ₃	CH ₂ CH ₂ OCH ₂ CH ₃
CF ₃	CH ₃	CH ₂ CH ₂ OCH ₂ CH ₂ CH ₃
CF ₃	CH ₃	CH ₂ CH ₂ OCH (CH ₃) ₂
CF ₃	CH ₃	CH ₂ CH ₂ CH ₂ OCH ₃
CF ₃	CH ₃	C(=0) OCH ₃
CF ₃	CH ₃	C (=0) OCH2CH3
CF ₃	CH ₃	C (=0) OCH2CH2CH3
CF ₃	CH ₃	C (=0) OCH (CH ₃) ₂
CF ₃	CH ₃	C (=0) OCH2CH2CH2CH3
CF ₃	CH ₃	$C (=0) OCH_2CH=CH_2$
CF ₃	CH ₃	C (=O) OCH (CH3) CH=CH2
CF ₃	CH ₃	C (=0) OCH (CH3) C (CH3) = CH2
CF ₃	CH ₃	C(=O)OCH ₂ CH=CHCH ₃
CF ₃	CH ₃	C (=0) OCH (CH3) CH=CHCH3
CF ₃	CH ₃	C (=0) OCH2CH=C (CH3)2
CF ₃	CH ₃	C(=O)OCH ₂ CH=CHCl
CF ₃	CH ₃	$C (=0) OCH_2CH=CCl_2$
CF ₃	CH ₃	$C (=0) OCH_2CH=CC1 (CH_3)$
CF ₃	CH ₃	C(=O)OCH ₂ CH=CHBr
CF ₃	CH ₃	$C (=0) OCH_2CH=CBr_2$
CF3	CH ₃	$C (=0) OCH_2CH=CBr (CH_3)$

Table 37

R 1	R ²	R ³
CF ₃	CH ₂ CH ₃	Н
CF ₃	CH ₂ CH ₃	CH ₃
CF ₃	CH ₂ CH ₃	CH ₂ CH ₃
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₃
CF ₃	CH ₂ CH ₃	CH (CH ₃) ₂
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₃
CF ₃	CH ₂ CH ₃	CH (CH ₃) CH ₂ CH ₃
CF ₃	CH ₂ CH ₃	CH ₂ CH (CH ₃) ₂
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₃
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH (CH ₃) ₂
CF ₃	CH ₂ CH ₃	CH (CH ₃) CH ₂ CH ₂ CH ₃
CF ₃	CH ₂ CH ₃	CH ₂ CH (CH ₃) CH ₂ CH ₃
CF ₃	CH ₂ CH ₃	CH (CH ₃) CH (CH ₃) ₂
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₃
CF ₃	CH ₂ CH ₃	CH ₂ F
CF ₃	CH ₂ CH ₃	CF ₃
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ F
CF ₃	CH ₂ CH ₃	CH ₂ CF ₃
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ F
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CF ₃
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ F
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CF ₃
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CF ₃
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ Cl
CF ₃	CH ₂ CH ₃	CHClCH ₂ Cl
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ Br
CF ₃	CH ₂ CH ₃	CHBrCH ₂ Br
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ C1
CF ₃	CH ₂ CH ₃	CH2CHClCH2Cl
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ Br
CF ₃	CH ₂ CH ₃	CH ₂ CHBrCH ₂ Br
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ Cl
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ Br
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CL
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br

Table 38

Table 30		
R ¹	R ²	R ³
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Cl
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br
CF ₃	CH ₂ CH ₃	CH=CH ₂
CF ₃	CH ₂ CH ₃	CH ₂ CH=CH ₂
CF ₃	CH ₂ CH ₃	CH=CHCH ₃
CF ₃	CH ₂ CH ₃	$C(CH_3) = CH_2$
CF ₃	CH ₂ CH ₃	CH=CHCH ₂ CH ₃
CF ₃	CH ₂ CH ₃	CH ₂ CH=CHCH ₃
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH=CH ₂
CF ₃	CH ₂ CH ₃	$C(CH_3) = CHCH_3$
CF ₃	CH ₂ CH ₃	$CH(CH_3)CH=CH_2$
CF ₃	CH ₂ CH ₃	$CH=C(CH_3)_2$
CF ₃	CH ₂ CH ₃	$CH_2C(CH_3) = CH_2$
CF ₃	CH ₂ CH ₃	$C(CH_2CH_3) = CH_2$
CF ₃	CH ₂ CH ₃	CH=CHCH ₂ CH ₂ CH ₃
CF ₃	CH ₂ CH ₃	$C(CH_3) = CHCH_2CH_3$
CF ₃	CH ₂ CH ₃	CH (CH ₃) CH=CHCH ₃
CF ₃	CH ₂ CH ₃	CH (CH ₃) CH ₂ CH=CH ₂
CF ₃	CH ₂ CH ₃	CH=C (CH ₃) CH ₂ CH ₃
CF ₃	CH ₂ CH ₃	$CH_2C(CH_3) = CHCH_3$
CF ₃	CH ₂ CH ₃	CH_2CH (CH_3) $CH=CH_2$
CF ₃	CH ₂ CH ₃	CH=CHCH (CH ₃) ₂
CF ₃	CH ₂ CH ₃	$CH_2CH=C(CH_3)_2$
CF ₃	CH ₂ CH ₃	CH_2CH_2C (CH_2) = CH_2
CF ₃	CH ₂ CH ₃	$CH_2CH=C(CH_3)_2$
CF ₃	CH ₂ CH ₃	CH=CHCH ₂ CH ₂ CH ₂ CH ₃
CF ₃	CH ₂ CH ₃	CH=CHCl
CF ₃	CH ₂ CH ₃	CH=CCl ₂
CF ₃	CH ₂ CH ₃	CH=C(CH ₃)Cl
CF ₃	CH ₂ CH ₃	CH ₂ CH=CHCl
CF ₃	CH ₂ CH ₃	CH ₂ CCl=CHCl
CF ₃	CH ₂ CH ₃	CH ₂ CH=CCl ₂
CF ₃	CH ₂ CH ₃	CH=CHBr
CF ₃	CH ₂ CH ₃	CH=CBr ₂
CF ₃	CH ₂ CH ₃	CH=C(CH ₃)Br

Table 39

Table 39		
R ¹	R ²	R ³
CF ₃	CH ₂ CH ₃	CH ₂ CH=CHBr
CF ₃	CH ₂ CH ₃	CH ₂ CBr=CHBr
CF ₃	CH ₂ CH ₃	CH ₂ CH=CBr ₂
CF ₃	CH ₂ CH ₃	CH ₂ CH=C (CH ₃) Cl
CF ₃	CH ₂ CH ₃	CH ₂ CH=C (CF ₃) Cl
CF ₃	CH ₂ CH ₃	CH ₂ CH=C (CH ₃) Br
CF ₃	CH ₂ CH ₃	CH ₂ CH=C (CF ₃)Br
CF ₃	CH ₂ CH ₃	CH=CHCF ₃
CF ₃	CH ₂ CH ₃	CH=CHCH ₂ CF ₃ CH ₂ CH=CHCH ₂ CF ₃
CF ₃	CH ₂ CH ₃ CH ₂ CH ₃	
CF ₃		C≡CH
CF ₃	CH ₂ CH ₃	C≡CCH ₃
CF ₃	CH ₂ CH ₃	CH ₂ C≡CH
CF ₃	CH ₂ CH ₃	C≡CCH ₂ CH ₃
CF ₃	CH ₂ CH ₃	CH ₂ C≡CCH ₃
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ C≡CH
CF ₃	CH ₂ CH ₃	СН (СН₃) С≡СН
CF ₃	CH ₂ CH ₃	C≡CCH ₂ CH ₂ CH ₃
CF ₃	CH ₂ CH ₃	CH ₂ C≡CCH ₂ CH ₃
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ C≡CCH ₃
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ C≡CH
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ C≡CCH ₃
CF ₃	CH ₂ CH ₃	c≡ccl
CF ₃	CH ₂ CH ₃	CH ₂ C≡CCl
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ C≡CCl
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ C≡CCl
CF ₃	CH ₂ CH ₃	C≡CBr
CF ₃	CH ₂ CH ₃	CH ₂ C≡CBr
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ C≡CBr
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ C≡CBr
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ C≡CCl
CF ₃	CH ₂ CH ₃	CH ₂ OH
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ OH
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ OH
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ OH

Table 40

		·
R 1	R ²	R ³
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ CH ₂ OH
CF3	CH ₂ CH ₃	CH ₂ OCH ₃
CF ₃	CH ₂ CH ₃	CH ₂ OCH ₂ CH ₃
CF ₃	CH ₂ CH ₃	CH ₂ OCH ₂ CH ₂ CH ₃
CF ₃	CH ₂ CH ₃	CH ₂ OCH (CH ₃) ₂
CF ₃	CH ₂ CH ₃	CH ₂ OCH ₂ CH ₂ CH ₃
CF ₃	CH ₂ CH ₃	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₃
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ OCH ₃
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ OCH ₂ CH ₃
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ OCH ₂ CH ₂ CH ₃
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ OCH (CH ₃) ₂
CF ₃	CH ₂ CH ₃	CH ₂ CH ₂ CH ₂ OCH ₃
CF ₃	CH ₂ CH ₃	$C (=0) OCH_3$
CF ₃	CH ₂ CH ₃	$C (=0) OCH_2CH_3$
CF ₃	CH ₂ CH ₃	$C (=0) OCH_2CH_2CH_3$
CF ₃	CH ₂ CH ₃	C (=O) OCH (CH3)2
CF ₃	CH ₂ CH ₃	$C (=O) OCH_2CH_2CH_2CH_3$
CF ₃	CH ₂ CH ₃	$C (=O) OCH_2CH=CH_2$
CF ₃	CH ₂ CH ₃	C (=O) OCH (CH3) CH=CH2
CF ₃	CH ₂ CH ₃	C (=O) OCH (CH3) C (CH3) = CH2
CF ₃	CH ₂ CH ₃	C (=O) OCH ₂ CH=CHCH ₃
CF ₃	CH ₂ CH ₃	C (=O) OCH (CH3) CH=CHCH3
CF ₃	CH ₂ CH ₃	C (=0) OCH2CH=C (CH3)2
CF ₃	CH ₂ CH ₃	C (=0) OCH2CH=CHCl
CF ₃	CH ₂ CH ₃	C (=0) OCH2CH=CCl2
CF ₃	CH ₂ CH ₃	$C (=0) OCH_2CH=CCl (CH_3)$
CF ₃	CH ₂ CH ₃	C (=O) OCH ₂ CH=CHBr
CF ₃	CH ₂ CH ₃	$C (=0) OCH_2CH=CBr_2$
CF ₃	CH ₂ CH ₃	C (=0) OCH2CH=CBr (CH3)

Table 41

R 1	R ²	R ³
CF ₃	CH(CH ₃) ₂	Н
CF ₃	CH (CH ₃) ₂	CH ₃
CF ₃	CH (CH ₃) ₂	CH ₂ CH ₃
CF ₃	CH(CH ₃) ₂	CH ₂ CH ₂ CH ₃
CF ₃	CH (CH ₃) ₂	CH (CH ₃) ₂
CF ₃	CH(CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₃
CF ₃	CH(CH ₃) ₂	CH (CH ₃) CH ₂ CH ₃
CF ₃	CH (CH ₃) ₂	CH ₂ CH (CH ₃) ₂
CF ₃	CH(CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₃
CF ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH (CH ₃) ₂
CF ₃	CH(CH ₃) ₂	CH (CH ₃) CH ₂ CH ₂ CH ₃
CF ₃	CH (CH ₃) ₂	CH ₂ CH (CH ₃) CH ₂ CH ₃
CF ₃	CH (CH ₃) ₂	CH (CH3) CH (CH3)2
CF ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ CH ₃
CF ₃	CH (CH ₃) ₂	CH ₂ F
CF ₃	CH (CH ₃) ₂	CF ₃
CF ₃	CH (CH ₃) ₂	!
CF ₃	CH (CH ₃) ₂	
CF ₃	$CH(CH_3)_2$	l I
CF ₃	CH (CH ₃) ₂	
CF ₃	$CH(CH_3)_2$	
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ CF ₃
CF ₃	CH (CH ₃) ₂	CH ₂ CH ₂ Cl
CF ₃	CH(CH ₃) ₂	
CF ₃	CH(CH ₃) ₂	CH ₂ CH ₂ Br
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	•
CF ₃	CH (CH ₃) ₂	· ·
CF ₃	CH (CH ₃) ₂	l e e e e e e e e e e e e e e e e e e e
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	
CF ₃	$CH(CH_3)_2$	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br

Table 42

Table 42		
R ¹	R ²	R ³
CF ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Cl
CF ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br
CF ₃	CH(CH ₃) ₂	CH=CH ₂
CF ₃	CH (CH ₃) ₂	CH ₂ CH=CH ₂
CF ₃	CH(CH ₃) ₂	CH=CHCH ₃
CF ₃	CH (CH ₃) ₂	$C(CH_3) = CH_2$
CF ₃	CH(CH ₃) ₂	CH=CHCH ₂ CH ₃
CF ₃	CH (CH ₃) ₂	CH ₂ CH=CHCH ₃
CF ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH=CH ₂
CF3	CH (CH ₃) ₂	$C(CH_3) = CHCH_3$
CF ₃	CH (CH ₃) ₂	CH (CH ₃) CH=CH ₂
CF ₃	CH (CH ₃) ₂	CH=C(CH ₃) ₂
CF3	CH (CH ₃) ₂	$CH_2C(CH_3) = CH_2$
CF ₃	CH(CH ₃) ₂	$C(CH_2CH_3) = CH_2$
CF ₃	CH (CH ₃) ₂	CH=CHCH ₂ CH ₂ CH ₃
CF ₃	CH (CH ₃) ₂	$C(CH_3) = CHCH_2CH_3$
CF ₃	CH (CH ₃) ₂	CH (CH ₃) CH=CHCH ₃
CF ₃	CH (CH ₃) ₂	CH (CH ₃) CH ₂ CH=CH ₂
.CF ₃	CH (CH ₃) ₂	CH=C (CH ₃) CH ₂ CH ₃
CF ₃	CH (CH ₃) ₂	$CH_2C(CH_3) = CHCH_3$
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	CH=CHCH (CH ₃) ₂
CF ₃	CH (CH3)2	
CF ₃	CH(CH ₃) ₂	
CF3	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	CH ₂ CH=CHCl
CF ₃		CH ₂ CCl=CHCl
CF ₃		CH ₂ CH=CCl ₂
CF ₃		CH=CHBr
CF ₃		CH=CBr ₂
CF ₃	CH (CH ₃) ₂	CH=C(CH ₃)Br

Table 43

10010 10		
R 1	R ²	R ³
CF ₃	CH (CH ₃) ₂	CH ₂ CH=CHBr
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂ CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	C≡CCH ₃
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	r -
CF ₃	CH (CH ₃) ₂	CH ₂ C≡CCH ₃
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	CH ₂ C≡CCH ₂ CH ₃
CF ₃	CH (CH ₃) ₂	CH ₂ CH ₂ C≡CCH ₃
CF ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ C≡CH
CF ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ C≡CCH ₃
CF ₃	CH (CH ₃) ₂	c≡ccl
CF ₃	CH (CH ₃) ₂	CH ₂ C≡CCl
CF ₃	CH (CH ₃) ₂	CH ₂ CH ₂ C≡CCl
CF ₃	CH(CH ₃) ₂	CH ₂ CH ₂ CH ₂ C≡CCl
CF ₃	CH(CH ₃) ₂	C≡CBr
CF ₃	CH (CH ₃) ₂	CH ₂ C≡CBr
CF ₃	CH (CH ₃) ₂	CH ₂ CH ₂ C≡CBr
CF ₃	CH(CH ₃) ₂	CH ₂ CH ₂ CH ₂ C≡CBr
CF ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ C≡CCl
CF ₃	CH (CH ₃) ₂	CH ₂ OH
CF ₃	CH (CH ₃) ₂	
CF ₃		CH ₂ CH ₂ CH ₂ OH
CF ₃	CH(CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ OH

Table 44

Table 44	_	
R ¹	R ²	R ³
CF ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ OH
CF ₃	CH (CH ₃) ₂	CH ₂ OCH ₃
CF ₃	CH (CH ₃) ₂	CH ₂ OCH ₂ CH ₃
CF ₃	CH (CH ₃) ₂	CH ₂ OCH ₂ CH ₂ CH ₃
CF ₃	CH (CH ₃) ₂	CH ₂ OCH (CH ₃) ₂
CF ₃	CH (CH ₃) ₂	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₃
CF ₃	CH (CH ₃) ₂	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₃
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	CH ₂ CH ₂ OCH ₂ CH ₂ CH ₃
CF ₃	CH(CH ₃) ₂	CH ₂ CH ₂ OCH (CH ₃) ₂
CF ₃	CH (CH ₃) ₂	CH ₂ CH ₂ CH ₂ OCH ₃
CF ₃	CH (CH ₃) ₂	
CF ₃	CH(CH ₃) ₂	
CF ₃	CH(CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	· · · · · · · · · · · · · · · · · · ·
CF ₃	CH (CH ₃) ₂	
CF ₃	CH (CH ₃) ₂	C (=0) OCH2CH=CH2
CF ₃	CH (CH ₃) ₂	C (=O) OCH (CH3) CH=CH2
CF ₃	CH (CH ₃) ₂	C (=O) OCH (CH3) C (CH3) = CH2
CF ₃	CH (CH ₃) ₂	C (=O) OCH ₂ CH=CHCH ₃
CF ₃	CH (CH ₃) ₂	C (=O) OCH (CH ₃) CH=CHCH ₃
CF ₃	CH (CH ₃) ₂	C (=0) OCH ₂ CH=C (CH ₃) ₂
CF ₃	CH (CH ₃) ₂	$C (=0) OCH_2CH=CHC1$
CF ₃	CH (CH ₃) ₂	$C (=0) OCH_2CH=CCl_2$
CF ₃	CH (CH ₃) ₂	C(=0) OCH ₂ CH=CCl(CH ₃)
CF ₃	CH (CH ₃) ₂	C(=0)OCH ₂ CH=CHBr
CF ₃	CH (CH ₃) ₂	C (=0) OCH ₂ CH=CBr ₂
CF ₃	CH (CH ₃) ₂	C(=0)OCH ₂ CH=CBr(CH ₃)

Table 45

		T 3
R 1	R ²	R ³
CF ₃	C (CH ₃) ₃	Н
CF ₃	C (CH ₃) ₃	CH ₃
CF ₃	C (CH ₃) ₃	CH ₂ CH ₃
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₃
CF ₃	C (CH ₃) ₃	CH (CH ₃) ₂
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₃
CF ₃	C (CH ₃) ₃	CH (CH ₃) CH ₂ CH ₃
CF ₃	C (CH ₃) ₃	CH ₂ CH (CH ₃) ₂
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₃
CF ₃	$C(CH_3)_3$	CH ₂ CH ₂ CH (CH ₃) ₂
CF ₃	C (CH ₃) ₃	CH (CH ₃) CH ₂ CH ₂ CH ₃
CF ₃	C (CH ₃) ₃	CH ₂ CH (CH ₃) CH ₂ CH ₃
CF ₃	C (CH ₃) ₃	CH (CH ₃) CH (CH ₃) ₂
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₃
CF ₃	C (CH ₃) ₃	CH ₂ F
CF ₃	C (CH ₃) ₃	CF ₃
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ F
CF ₃	C (CH ₃) ₃	CH ₂ CF ₃
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ F
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CF ₃
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ F
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CF ₃
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CF ₃
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ Cl
CF ₃	C (CH ₃) ₃	CHC1CH2C1
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ Br
CF ₃	C (CH ₃) ₃	CHBrCH ₂ Br
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ Cl
CF ₃	C (CH ₃) ₃	CH2CHClCH2Cl
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ Br
CF ₃	C (CH ₃) ₃	CH ₂ CHBrCH ₂ Br
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ Cl
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ Br
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ CL
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ Br

Table 46

Table 40		
R ¹	R ²	R ³
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Cl
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ Br
CF ₃	C(CH ₃) ₃	CH=CH ₂
CF ₃	C (CH ₃) ₃	CH ₂ CH=CH ₂
CF ₃	C (CH ₃) ₃	CH=CHCH ₃
CF ₃	C(CH ₃) ₃	$C(CH_3) = CH_2$
CF ₃	C(CH ₃) ₃	CH=CHCH ₂ CH ₃
CF ₃	C(CH ₃) ₃	CH ₂ CH=CHCH ₃
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH=CH ₂
CF ₃	C (CH ₃) ₃	$C(CH_3) = CHCH_3$
CF ₃	C(CH ₃) ₃	CH (CH ₃) CH=CH ₂
CF ₃	C (CH ₃) ₃	$CH=C(CH_3)_2$
CF ₃	C(CH ₃) ₃	CH_2C (CH_3) = CH_2
CF ₃	$C(CH_3)_3$	$C(CH_2CH_3) = CH_2$
CF ₃	C (CH ₃) ₃	CH=CHCH ₂ CH ₂ CH ₃
CF ₃	C (CH ₃) ₃	$C(CH_3) = CHCH_2CH_3$
CF ₃	C (CH ₃) ₃	CH (CH ₃) CH=CHCH ₃
CF ₃	C (CH ₃) ₃	CH (CH ₃) CH ₂ CH=CH ₂
CF ₃	C (CH ₃) ₃	CH=C (CH ₃) CH ₂ CH ₃
CF ₃	C (CH ₃) ₃	CH_2C (CH_3) = $CHCH_3$
CF ₃	C (CH ₃) ₃	CH ₂ CH (CH ₃) CH=CH ₂
CF ₃	C (CH ₃) ₃	CH=CHCH (CH ₃) ₂
CF3	C(CH ₃) ₃	$CH_2CH=C(CH_3)_2$
CF ₃	C(CH ₃) ₃	$CH_2CH_2C (CH_2) = CH_2$
CF ₃	$C(CH_3)_3$	$CH_2CH=C(CH_3)_2$
CF ₃	C (CH ₃) ₃	CH=CHCH ₂ CH ₂ CH ₂ CH ₃
CF ₃	C (CH ₃) ₃	CH=CHC1
CF ₃	C (CH ₃) ₃	CH=CCl ₂
CF ₃	C (CH ₃) ₃	CH=C (CH ₃) Cl
CF3	$C(CH_3)_3$	CH ₂ CH=CHCl
CF ₃	$C(CH_3)_3$	CH ₂ CCl=CHCl
CF ₃	C (CH ₃) ₃	CH ₂ CH=CCl ₂
CF ₃	$C(CH_3)_3$	CH=CHBr
CF ₃	C (CH ₃) ₃	CH=CBr ₂
CF ₃	$C(CH_3)_3$	CH=C (CH ₃) Br

Table 47

Table 47		·
R ¹	R ²	R ³
CF ₃	C (CH ₃) ₃	CH ₂ CH=CHBr
CF ₃	C (CH ₃) ₃	CH ₂ CBr=CHBr
CF ₃	$C(CH_3)_3$	CH ₂ CH=CBr ₂
CF ₃	C (CH ₃) ₃	CH ₂ CH=C (CH ₃) Cl
CF ₃	C (CH ₃) ₃	CH ₂ CH=C (CF ₃)Cl
CF ₃ .	C (CH ₃) ₃	CH ₂ CH=C (CH ₃) Br
CF ₃	C (CH ₃) ₃	CH ₂ CH=C (CF ₃) Br
CF ₃	·C (CH ₃) ₃	CH=CHCF ₃
CF ₃	$C(CH_3)_3$ $C(CH_3)_3$	CH=CHCH ₂ CF ₃ CH ₂ CH=CHCH ₂ CF ₃
CF ₃	$C(CH_3)_3$	C≡CH
1	C (CH ₃) ₃	
CF ₃		C≡CCH ₃
CF ₃	C (CH ₃) ₃	CH ₂ C≡CH
CF ₃	C (CH ₃) ₃	C≡CCH ₂ CH ₃
CF ₃	C (CH ₃) ₃	CH ₂ C≡CCH ₃
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ C≡CH
CF ₃	C (CH ₃) ₃	CH (CH ₃) C≡CH
·CF ₃	C (CH ₃) ₃	$C \equiv CCH_2CH_2CH_3$
CF ₃	C (CH ₃) ₃	$CH_2C \equiv CCH_2CH_3$
CF ₃	C(CH ₃) ₃	CH ₂ CH ₂ C≡CCH ₃
CF ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH ₂ C≡CH
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ C≡CCH ₃
CF ₃	C(CH ₃) ₃	c≡ccl
CF ₃	C(CH ₃) ₃	CH ₂ C≡CCl
CF ₃	C(CH ₃) ₃	CH ₂ CH ₂ C≡CCl
CF ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH ₂ C≡CCl
CF ₃	C(CH ₃) ₃	C≡CBr
CF ₃	C(CH ₃) ₃	CH ₂ C≡CBr
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ C≡CBr
CF ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH ₂ C≡CBr
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ C≡CCl
CF ₃	C(CH ₃) ₃	CH ₂ OH
CF ₃	C(CH ₃) ₃	CH ₂ CH ₂ OH
CF ₃	C(CH ₃) ₃	CH ₂ CH ₂ CH ₂ OH
CF ₃	$C(CH_3)_3$	CH ₂ CH ₂ CH ₂ CH ₂ OH

Table 48

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R ¹	R ²	R ³
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ CH ₂ CH ₂ OH
CF ₃	C (CH ₃) ₃	CH ₂ OCH ₃
CF ₃	C (CH ₃) ₃	CH ₂ OCH ₂ CH ₃
CF ₃	C (CH ₃) ₃	CH ₂ OCH ₂ CH ₂ CH ₃
CF ₃	C (CH ₃) ₃	CH ₂ OCH (CH ₃) ₂
CF ₃	C (CH ₃) ₃	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₃
CF ₃	C (CH ₃) ₃	CH ₂ OCH ₂ CH ₂ CH ₂ CH ₃
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ OCH ₃
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ OCH ₂ CH ₃
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ OCH ₂ CH ₂ CH ₃
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ OCH (CH ₃) ₂
CF ₃	C (CH ₃) ₃	CH ₂ CH ₂ CH ₂ OCH ₃
CF ₃	C (CH ₃) ₃	C (=O) OCH ₃
CF ₃	C (CH ₃) ₃	$C (=O) OCH_2CH_3$
CF ₃	C (CH ₃) ₃	C (=O) OCH2CH2CH3
CF ₃	C (CH ₃),3	C (=O) OCH (CH3)2
CF ₃	C (CH ₃) ₃	C (=0) OCH2CH2CH2CH3
CF ₃	C (CH ₃) ₃	$C (=0) OCH_2CH=CH_2$
CF ₃	C (CH ₃) ₃	C (=0) OCH (CH3) CH=CH2
CF ₃	C (CH ₃) ₃	C (=0) OCH (CH3) C (CH3) = CH2
CF ₃	C (CH ₃) ₃	C (=0) OCH2CH=CHCH3
CF ₃	C (CH ₃) ₃	C (=0) OCH (CH3) CH=CHCH3
CF ₃	C (CH ₃) ₃	C (=0) OCH2CH=C (CH3)2
CF ₃	C (CH ₃) ₃	$C (=0) OCH_2CH=CHCl$
CF ₃	C (CH ₃) ₃	$C (=0) OCH_2CH=CCl_2$
CF ₃	C (CH ₃) ₃	$C (=O) OCH_2CH=CCl (CH_3)$
CF ₃	C (CH ₃) ₃	C (=0) OCH2CH=CHBr
CF ₃	C (CH ₃) ₃	$C (=0) OCH_2CH=CBr_2$
CF ₃	C (CH ₃) ₃	C (=0) OCH2CH=CBr (CH3)

Table 49

R ¹	R ²	R 3
CH ₂ CH ₂ CH ₃	CH ₃	H
CH ₂ CH ₂ CH ₃	CH ₃	CH ₃
CH ₂ CH ₂ CH ₃ CH ₂ CH ₂ CH ₃	CH ₃	CH ₂ CH ₃
CH ₂ CH ₂ CH ₃ CH ₂ CH ₂ CH ₃	CH ₃	CH ₂ CH ₃ CH ₂ CH ₂ CH ₃
	CH ₃	CH=CH ₂
CH ₂ CH ₂ CH ₃ CH ₂ CH ₂ CH ₃	CH ₃	CH ₂ CH=CH ₂
CH ₂ CH ₂ CH ₃	CH ₃	CH=CHCH ₃
CH ₂ CH ₂ CH ₃	CH ₃	$C (CH_3) = CH_2$
CH ₂ CH ₂ CH ₃ CH ₂ CH ₂ CH ₃	CH ₃	CH=CHBr
CH ₂ CH ₂ CH ₃ CH ₂ CH ₂ CH ₃	CH ₃	CH=CCl ₂
CH ₂ CH ₂ CH ₃ CH ₂ CH ₂ CH ₃	CH ₃	CH=CHBr
	CH ₃	CH=CBr ₂
CH ₂ CH ₂ CH ₃ CH ₂ CH ₂ CH ₃	CH ₃	C≡CH
CH ₂ CH ₂ CH ₃	CH ₃	C≡CCH ₃
CH ₂ CH ₂ CH ₃	CH ₃	CH ₂ C≡CH
CH ₂ CH ₂ CH ₃	CH ₃	C≡CC1
CH ₂ CH ₂ CH ₃	CH ₃	C≡CBr
CH ₂ CH ₂ CH ₃	CH ₃	CH ₂ OH
CH ₂ CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ OH
CH ₂ CH ₂ CH ₃	CH ₃	CH ₂ OCH ₃
CH ₂ CH ₂ CH ₃	CH ₃	CH ₂ OCH ₂ CH ₃
CH ₂ CH ₂ CH ₃	CH ₃	C (=O) OCH ₃
CH ₂ CH ₂ CH ₃	CH ₃	C (=0) OCH2CH3
CH ₂ CH ₂ CH ₃	CH ₃	C (=0) OCH2CH=CCl2
CH ₂ CH ₂ CH ₃	CH₃	C(=O)OCH ₂ CH=CBr ₂

Table 50

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R 1 .	R ²	R ³
CH ₂ CH ₂ CH ₂ CH ₃	CH ₃	Н
CH2CH2CH2CH3	CH ₃	CH ₃
CH ₂ CH ₂ CH ₂ CH ₃	CH ₃	CH ₂ CH ₃
CH ₂ CH ₂ CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ CH ₃
CH2CH2CH2CH3	CH ₃	CH=CH ₂
CH2CH2CH2CH3	CH ₃	CH ₂ CH=CH ₂
CH ₂ CH ₂ CH ₂ CH ₃	CH ₃	CH=CHCH ₃
CH2CH2CH2CH3	CH ₃	$C(CH_3) = CH_2$
CH2CH2CH2CH3	CH ₃	CH=CHBr
CH2CH2CH2CH3	CH ₃	CH=CCl ₂
CH ₂ CH ₂ CH ₂ CH ₃	CH ₃	CH=CHBr
CH ₂ CH ₂ CH ₂ CH ₃	CH ₃	CH=CBr ₂
CH ₂ CH ₂ CH ₂ CH ₃	CH ₃	С≡СН
CH ₂ CH ₂ CH ₂ CH ₃	CH ₃	C≡CCH ₃
CH ₂ CH ₂ CH ₂ CH ₃	CH ₃	CH ₂ C≡CH
CH ₂ CH ₂ CH ₂ CH ₃	CH ₃	C≡CCl
CH ₂ CH ₂ CH ₂ CH ₃	CH ₃	C≡CBr
CH ₂ CH ₂ CH ₂ CH ₃	CH ₃	CH ₂ OH
CH ₂ CH ₂ CH ₂ CH ₃	CH ₃	CH ₂ CH ₂ OH
CH ₂ CH ₂ CH ₂ CH ₃	CH ₃	CH ₂ OCH ₃
CH ₂ CH ₂ CH ₂ CH ₃	CH ₃	CH ₂ OCH ₂ CH ₃
CH ₂ CH ₂ CH ₂ CH ₃	CH₃	$C (=0) OCH_3$
CH ₂ CH ₂ CH ₂ CH ₃	CH ₃	C (=0) OCH2CH3
CH ₂ CH ₂ CH ₂ CH ₃	CH ₃	C (=0) OCH2CH=CCl2
CH2CH2CH2CH3	CH ₃	C(=0)OCH ₂ CH=CBr ₂

The noxious arthropod pests against which the compound of the present invention has activity may include noxious insect pests and noxious acarina pests, and concreatly:

Hemiptera:

Delphacidae such as Laodelphax striatellus, Nilaparvata lugens, Sogatella furcifera and the like,

Deltocephalidae such as Nephotettix cincticeps, Nephotettix virescens and the like,

Aphididae such as Aphis gossypii, Myzus persicae and the like,

Pentatomidae such as Nezara antennata, Riptortus clavetus and the like,

Aleyrodidae such as Trialeurodes vaporariorum, Bemisia argentifolii and the like,

15 Coccidae such as Aonidiella aurantii, Comstockaspis perniciosa, Unaspis citri, Ceroplastes rubens, Icerya purchasi and the like,

. Tingidae,

Psyllidae, and the like;

20 Lepidoptera:

Pyralidae such as Chilo suppressalis, Cnaphalocrocis medinalis, Notarcha derogata, Plodia interpunctella and the like,

Noctuidae such as Spodoptera litura, Pseudaletia
25 separata, Thoricoplusia spp., Heliothis spp., Helicoverpa spp.
and the like,

Pieridae such as *Pieris rapae* and the like,

Tortricidae such as Adoxophyes spp. (ex. *Adoxophyes orana*

fasciata), Grapholita molesta, Cydia pomonella and the like,

Carposinidae such as Carposina niponensis and the like,

Lyonetiidae such as Lyonetia spp. and the like,

Lymantriidae such as Lymantria spp., Euproctis spp., and

5 the like,

Yponomeutidae such as Plutella xylostella and the like, Gelechiidae such as Pectinophora gossypiella and the like,

Arctiidae such as Hyphantria cunea and the like,

Tineidae such as Tinea translucens, Tineola bisselliella
and the like;

Diptera:

the like,

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Calicidae such as Culex pipiens pallens, Culex tritaeniorhynchus, Culex quinquefasciatus and the like,

Aedes spp. such as Aedes aegypti, Aedes albopictus and the like,

Anopheles such as Anopheles sinensis and the like, Chironomidae,

Muscidae such as Musca domestica, Muscina stabulans and

Calliphoridae,

Sarcophagidae,

Fanniidae,

Anthomyiidae such as Delia platura, Delia antiqua and

25 the like,

Tephritidae,

Drosophilidae,

Psychodidae,

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Tabanidae,

Simuliidae,

Stomoxyidae,

Agromyzidae, and the like;

5 Coleoptera:

Diabrotica spp. such as Diabrotica virgifera virgifera, Diabrotica undecimpunctata howardi and the like,

Scarabaeidae such as Anomala cuprea, Anomala rufocuprea and the like,

10 Curculionidae such as Sitophilus zeamais, Lissorhoptrus oryzophilus, Callosobruchuys chienensis and the like,

Tenebrionidae such as Tenebrio molitor, Tribolium castaneum and the like,

Chrysomelidae such as Oulema oryzae, Aulacophora

15 femoralis, Phyllotreta striolata, Leptinotarsa decemlineata
and the like,

Anobiidae,

Epilachna spp. such as Epilachna vigintioctopunctata and the like,

20 Lyctidae,

Bostrychidae,

Cerambycidae,

Paederus fuscipes;

Blattodea:

25 Blattella germanica, Periplaneta fuliginosa, Periplaneta americana, Periplaneta brunnea, Blatta orientalis and the like;

Thysanoptera:

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Thrips palmi, Thrips tabaci, Frankliniella occidentalis and the like;

Hymenoptera:

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Formicidae such as *Monomorium pharaonis*, Vespidae, bethylid wasp, Tenthredinidae such as *Athalia japonica*, and the like;

Orthoptera:

Gryllotalpidae, Acrididae, and the like;
Aphaniptera:

10 Ctenocephalides felis, Ctenocephalides canis, Pulex irritans, Xenopsylla cheopis, and the like;

Anoplura:

Pediculus humanus corporis, Phthirus pubis, Haematopinus eurysternus, Dalmalinia ovis, and the like;

15 Isoptera:

Reticulitermes speratus, Coptotermes formosanus, and the like;

Acarina:

Tetranychidae such as Tetranychus urticae, Panonychus 20 citri, Oligonychus spp., and the like,

Eriophyidae such as Aculops pelekassi and the like,

Tarsonemidae such as Polyphagotarsonemus latus, and the
like,

Tenuipalpidae,

25 Tuckerellidae,

Ixodidae such as Haemaphysalis longicornis,
Haemaphysalis flava, Dermacentor taiwanicus, Ixodes ovatus,
Ixodes persulcatus, Boophilus microplus, Rhipicephalus

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sanguineus, and the like,

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Acaridae such as Tyrophagus putrescentiae, and the like,

Epidermoptidae such as Dermatophagoides farinae,

Dermatophagoides ptrenyssnus, and the like,

Cheyletidae such as Cheyletus eruditus, Cheyletus malaccensis, Cheyletus moorei, and the like,

Dermanyssidae.

The noxious arthropod controlling composition of the present invention contains the compound of the present invention and an inert carrier. Generally, it is a preparation obtained by mixing the compound of the present invention and an inert carrier such as a solid carrier, a liquid carrier, a gaseous carrier and/or bait for poison bait, and if necessary, adding a surfactant and other adjuvant for formulation. The formulation includes, for example, an emulsifiable concentrate, an oil solution, a dust, a granule, a wettable powder, a flowable, a microcapsule, an aerosol, a smoking pesticide, a poison bait, regious preparation and the like. These formulations can be converted to use into a poison bait, a sheet. In the noxious arthropod controlling composition of the present invention, the compound of the present invention is usually contained in an amount of 0.01% to 95% by weight.

The solid carrier for formulation includes, for example, a fine power and a granule of clays (e.g., kaolin clay, diatomite, bentonite, Fubasami clay, acid clay, etc.), synthetic hydrated silicon oxide, talc, ceramic, other inorganic minerals (e.g., sericite, quartz, sulfur, activated carbon, calcium carbonate,

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hydrated silica) or chemical fertilizers (e.g., ammonium sulfate, ammonium phosphate, ammonium nitrate, ammonium chloride, urea).

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The liquid carrier for formulation includes, for example, water, alcohols (e.g., methanol, ethanol, isopropyl alcohol, butanol, hexanol, benzyl alcohol, ethylene glycol, propylene glycol, phenoxyethanol), ketones (e.g., acetone, methyl ethyl ketone, cyclohexanone), aromatic hydrocarbons (e.g., toluene, xylene, ethylbenzene, dodecylbenzene, phenylxylylethane, methylnaphthalene), aliphatic hydrocarbons (e.g., hexane, cyclohexane, kerosine, light oil), esters (e.g., ethyl acetate, butyl acetate, isopropyl mylistate, ethyl oleate, diisopropyl adipate, diisobutyl adipate, propyleneglycol monomethyl ether acetate), nitriles (e.g., acetonitrile, isobutyronitrile), ethers (e.g., diisopropyl ether, 1,4-dioxane, ethylene glycol dimethyl ether, diethylene glycol dimethyl ether, diethylene 15 glycol monomethyl ether, propylene glycol monomethyl ether, monomethyl glycol dipropylene ether, 3-methoxy-3-methyl-1-butanol), acid amides (e.g., N, N-dimethylformamide, N, N-dimethylacetamide), halogenated dichloromethane, trichloroethane, (e.g., hydrocarbons 20 tetrachlorocarbon), sulfoxides (e.g., dimethylsulfoxide), propylene carbonate, and vegetable oils (e.g., soy bean oil, cotton seed oil).

The gaseous carrier for formulation includes, for example, fluorocarbons, butane gas, liquefied petroleum gas (LPG), dimethyl ether, and carbon dioxide.

The surfactant for formulation includes, for example, non-ionic surfactant, such as polyoxyethylene alkyl ether,

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polyoxyethylene alkylaryl ether, polyethyleneglycol fatty acid ester; anionic surfactant, such as alkylsulfonic acid salts, alkylbenzenesulfonic acid salts, alkylsurfic acid salts.

The other adjuvant for formulation includes, for example, binders, dispersants and stabilizers, and specifically for example, casein, gelatin, polysaccharides (e.g., starch, gum arabic, cellulose derivatives, alginic acid), lignin derivatives, bentonite, sugars, synthetic water-soluble polymers (e.g., polyvinyl alcohol, polyvinylpyrrolidone, polyacrylic acid), PAP (isopropyl acid phosphate), BHT (2,6-di-t-butyl-4-methylphenol), BHA (a mixture of 2-t-butyl-4-methoxyphenol and 3-t-butyl-4-methoxyphenol).

The method for controlling noxious arthropod pests of the present invention is applying the compound of the present invention to pests directly and/or habitats of pests (e.g., plant, soil, indoor, in-body of animals, and so on). The compound of the present invention is usually used as an active ingredient of the noxious arthropod pests controlling composition.

When the noxious arthropod pests controlling composition of the present invention is used for a control of noxious arthropos pests in agriculture and forestry, the application amount is usually 0.01 to 10,000 g, preferablly 1 to 10,000g, as an active ingredient per 10,000 m². In case of the noxious arthropod pests controlling compositions of the present invention are formulated to the emulsifiable concentrates, wettable powders and flowables, they are usually applied after dilution with water to have an active ingredient concentration of 0.01 to 10,000 ppm, while dusts and granules are usually applied as such. These

preparations and the dilution of the preparation may be sprayed directly to the plant to be protected from pests. The pests living in a soil can be controlled by treating the soil with these preparations.

Furthermore, the reginous preparations of sheets or strip form can be applied by a method such as winding around plants, stretching in the vicinity of plants and laying on the soil surface at the plant bottom.

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When the noxious arthropod pests controlling composition of the present invention is used for a control of noxious arthropod pests in indoor (e.g., fly, mesquite, cockroach), the application amount is usually 0.01 to 1,000 mg as the compound of the present invention per 1 $\rm m^2$ in case of application for plane surface, and 0.01 to 500 mg as the compound of the present invention per 1 $\rm m^3$ in case of application for open space.

In case of the noxious arthropod pests controlling composition of the present invention are formulated to the emulsifiable concentrate, wettable powders and flowables, they are usually applied after dilution with water to have an active ingredient concentration of 0.01 to 100,000 ppm, preferablly 0.1 to 1,000 ppm, while oil solutions, aerosols, smoking pesticides and poison baits are usually applied as such.

The noxious arthropod pests controlling composition of the present invention can contain other noxious arthropod pests controlling agents, nematocides, acaricides, fungicides, herbicides, plant growth regulators, synergists, fertilizers, soil conditioners, animal feeds, and the like.

The active ingredients of noxious arthropod pests

controlling agents, nematocides, and/or acaricides include, for example, organophosphorus compounds such as Fenitrothion, Chlorpyriphos, Diazinon, Pyridaphenthion, Chlorpyriphos-methyl, Acephate, Methidathion, Disulfoton, DDVP, Sulprofos, Cyanophos, Dioxabenzofos, Dimethoate, Phenthoate, 5 Malathion, Trichlorfon, Azinphos-methyl, Monocrotophos and Ethion; carbamate compounds such as BPMC, Benfuracarb, Propoxur, Carbosulfan, Carbaril, Methomyl, Ethiofencarb, Aldicarb, Oxamyl, Fenothiocarb, Thiodicarb, and Alanycarb; pyrethroid compounds such as Etofenprox, Fenvalerate, Esfenvalerate, 10 alfa-Cypermethrin, Cypermethrin, Fenpropathrin, Permethrin, Cyhalothrin, zeta-Cypermethrin, delta-Cyhalothrin, Cyfluthrin, lambda-Cyhalothrin, beta-Cyfluthrin, Cycloprothrin, Fluvalinate, Flucythrinate, Traromethrin and Silafluofen; Acrinathrin, Bifenthrin, 15 neonicotinoid compounds such as Acetamiprid, Nitenpyram, Thialoprid and Clothianidin; Nereistoxin Thiamethoxiam, derivatives such as Cartap, Thiocyclam, and Bensultap; chlorinated hydrocarbon compounds such as Endosulfan, gamma-BHC, 1,1-bis(chlorophenyl)-2,2,2-trichloroethanol; 20 and Chlorfluazuron, compounds such as benzoylphenylurea Teflubenzuron, Fulphenoxron, and Lufenuron; phenylhydrazide Chromafenozide, Tebufenozide, as such compounds Methoxyfenozide and Halofenozide; formamidine derivatives such as Amitraz and Chlordimeform; thiourea derivatives such as 25 Buprofezin; Chlorfenapyr; Spinosad and Diafenthiuron; Indoxacarb; benzoate; Emamectin thereof; derivatives Bromopropylate; Pymetrozine; phnylpyrazole derivatives;

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Tetradifon; Chinomethionat; Propargite; Fenbutatin oxide; Cyhexatin; Hexathiazox; Clofentezine; Pyridaben; Fenpyroximate; Tebufenpyrad; Pyrimidifen; Fenazaquin; Bifenazate; Acequinocyl; Spirodiclofen; Spiromesifen; polynactin complexes [e.g., tetranactin, dinactin, trinactin]; Milbemectin; Avermectin; Azadilactin; and Pyridalyl.

The present invention will be further illustrated by the following production examples, formulation examples, and test examples; however, the present invention is not limited to these examples.

The following describes the production examples for the present compounds.

15 Production Example 1

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150mg of the compound shown by the formula (i):

was dissolved in 5 ml of acetic anhydride, and the mixture was refluxed for one hour. After that, the reaction mixture which was cooled to room temperature was concentrated under reduced pressure, added water, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 125 mg of the compound shown by the formula (1):

(hereinafter, referred as the present invention compound (1)). $^{1}\text{H-NMR}(CDCl_{3}, TMS) \delta(ppm): 2.28(3H,s), 3.71(3H,s), 4.64(2H,d), 6. 16(1H,t), 6.86-7.26(8H,m)$

5 Production Example 2

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200mg of the compound shown by the formula (ii):

was dissolved in 3 ml of ethanol, 10mg of sodium borohydride was added to the mixture, and the mixture was refluxed for one hour. After that, the reaction mixture which was cooled to room temperature was concentrated under reduced pressure, added water and 10% hydrochloric acid, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 110 mg of the compound shown by the formula (2):

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Production Example 3

dissolved in 2 ml of methanol and 1 ml of trifluoroacetic acid, 350mg of sodium borohydride was added to the mixture in ten portion s, and the mixture stirred at room temperature for one hour. After that, the reaction mixture was added to dilute hydrochloric acid, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 150 mg of the compound shown by the formula (3):

(hereinafter, referred as the present invention compound (3)). 1 H-NMR(CDCl₃, TMS) δ (ppm):2.25(3H,s),3.20(3H,s),3.59(3H,s),4. 06(2H,s),4.63(2H,d),6.16(1H,t),6.85-6.96(8H,m)

Production Example 4

2.0g of the compound shown by the formula (ii) was dissolved in 30 ml of ethanol, 260mg of sodium borohydride was added to the mixture under ice-cooling, and the mixture was stirred for one hour. After that, dilute hydrochloric acid was added to the reaction mixture, stirred for 5 minutes, and concentrated under reduced pressure. Diluted hydrochloric acid was added to the residue, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated

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brine, dried over magnesium sulfate, and concentrated under reducedpressure. The residue was subjected to silica gel column chromatography to obtain 340 mg of the compound shown by the formula (4):

$$H_3C$$
 OCH_2CH_3
 $O-CH_2CH=CCl_2$
 $O-CH_2CH=CCl_2$
 $O-CH_3$

(hereinafter, referred as the present invention compound (4)). ${}^{1}\text{H-NMR}\left(\text{CDCl}_{3},\text{TMS}\right)\delta\left(\text{ppm}\right):1.11\left(3\text{H},\text{t}\right),2.24\left(3\text{H},\text{s}\right),3.34\left(2\text{H},\text{q}\right),3.}$ $59\left(3\text{H},\text{s}\right),4.10\left(2\text{H},\text{s}\right),4.63\left(2\text{H},\text{d}\right),6.16\left(1\text{H},\text{t}\right),6.84-6.95\left(8\text{H},\text{m}\right)$

Production Example 5

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100mg of the compound shown by the formula (iii):

was dissolved in 2 ml of N, N-dimethyl formamide, 60 mg of potassium carbonate and 60 mg of 1,1,3-trichloropropene were added to the mixture, and the mixture was stirred at room temperature for ten hours. After that, the reaction mixture was added to dilute hydrochloric acid, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 120 mg of the compound shown by the formula (5):

(hereinafter, referred as the present invention compound (5)). 1 H-NMR (CDCl₃, TMS) δ (ppm):2.44(3H,s),3.63(3H,s),3.64(3H,s),4.63(2H,d),6.16(1H,t),6.83-6.95(8H,m)

5 Production Example 6

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110mg of the compound shown by the formula (iv):

was dissolved in 2 ml of N,N-dimethylformamide, 110mg of potassium carbonate and 70mg of 1,1,3-trichloropropene were added to the mixture, and the mixture was stirred at room temperature for ten hours. After that, the reaction mixture was added to dilute hydrochloric acid, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 100 mg of the compound shown by the formula (6):

$$\begin{array}{c|c}
O \\
C - O - CH_2CH = CCI_2
\end{array}$$

$$\begin{array}{c|c}
O \\
O - CH_2CH = CCI_2
\end{array}$$

$$\begin{array}{c|c}
O \\
O - CH_2CH = CCI_2
\end{array}$$

$$\begin{array}{c|c}
O \\
CH_3
\end{array}$$

(hereinafter, referred as the present invention compound (6)). 1 H-NMR(CDCl₃, TMS) δ (ppm):2.61(3H,s),3.71(3H,s),4.62(2H,d),4.

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64(2H,d),5.72(1H,t),6.16(1H,t),6.79-6.98(8H,m)

Production Example 7

220mg of the compound shown by the formula (v):

was dissolved in 2 ml of N,N-dimethylformamide, 100mg of potassium carbonate and 100mg of 1,1,3-trichloropropene were added to the mixture, and the mixture was stirred at room temperature for ten hours. After that, the reaction mixture was added to dilute hydrochloric acid, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 260 mg of the compound shown by the formula (7):

$$\begin{array}{c|c} COOCH_2CH_3 \\ \hline \\ N \\ N \\ CH_3 \end{array} O - CH_2CH=CCI_2 \tag{7}$$

(hereinafter, referred as the present invention compound (7)). ${}^{1}\text{H-NMR}(\text{CDCl}_{3},\text{TMS})\,\delta(\text{ppm}):1.06\,(3\text{H,t}),2.45\,(3\text{H,s}),3.65\,(3\text{H,s}),4.}$ $09\,(2\text{H,q}),4.63\,(2\text{H,d}),6.16\,(1\text{H,s}),6.82-6.94\,(8\text{H,m})$

Production Example 8

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2.6 g of the compound shown by the formula (vi):

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was dissolved in 30 ml of N,N-dimethylformamide, 1.4 g of potassium carbonate and 1.4 g of 1,1,3-trichloropropene were added to the mixture, and the mixture was stirred at room temperature for ten hours. After that, the reaction mixture was added to dilute hydrochloric acid, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silicagel column chromatography to obtain 3.5 g of the compound shown by the formula (8):

(hereinafter, referred as the present invention compound (8)). 1 H-NMR(CDCl₃,TMS) δ (ppm):2.31(3H,s),3.58(3H,s),4.63(2H,d),5. 01(1H,dd),5.27(1H,dd),6.16(1H,t),6.32(1H,dd),6.83-6.95(8H,m)

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Production Example 9

130 mg of the compound shown by the formula (vii):

was dissolved in 1 ml of N, N-dimethyl formamide, 60 mg of potassium carbonate and 60 mg of 1,1,3-trichloropropene were added to the mixture, and the mixture was stirred at room temperature for ten hours. After that, the reaction mixture was added to dilute hydrochloric acid, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silicagel column chromatography to obtain 120 mg of the compound shown by the formula (9):

as a mixture of geometric isomers (hereinafter, referred as the present invention compound (9)).

¹ H-NMR (CDCl₃, TMS) δ (ppm): 1.63 (1.5H,dd), 1.74 (1.5H,dd), 2.17 (1.5H,s), 2.28 (1.5H,s), 3.56 (1.5H,s), 3.62 (1.5H,s), 4.63 (1H,d), 4.6 3 (1H,d), 5.57 (0.5H,m), 5.78 (0.5H,m), 5.86 (0.5H,m), 5.98 (0.5H,m), 6.15 (1H,t), 6.79-6.95 (8H,m)

Production Example 10

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By using 170 mg of the compound shown by the formula (viii):

instead of the compound shown by the formula (vii), and 70 mg of potassium carbonate and 80 mg of 1,1,3-trichloropropene, according to the similar method described in Production Example

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9 was obtained 160 mg of the compound shown by the formula (10):

$$H_3C$$
 $H_2CHCH_2CH_3$
 $O-CH_2CH=CCI_2$
 $O-CH_2CH=CCI_2$
 $O-CH_3$

as a mixture of geometric isomers (hereinafter, referred as the present invention compound (10)).

 1 H-NMR(CDCl₃, TMS) δ (ppm):0.92(3H,m),2.05(2H,m),2.17(2.1H,s), 2.28(0.9H,s),3.57(0.9H,s),3.61(2.1H,s),4.63(2H,d),5.45(0.7H ,m),5.78(1H,m),5.95(0.3H,m),6.15(1H,t),6.78-6.94(8H,m)

Production Example 11

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By using 110 mg of the compound shown by the formula (ix):

instead of the compound shown by the formula (vii), and 50 mg 10 of potassium carbonate and 60 mg of 1,1,3-trichloropropene, according to the similar method described in Production Example 9 was obtained 90 mg of the compound shown by the formula (11):

$$\begin{array}{c|c} & \text{HC=C(CH_3)_2} \\ & & \\ &$$

(hereinafter, referred as the present invention compound (11)). 1 H-NMR(CDCl₃,TMS) δ (ppm):1.60(3H,d),1.72(3H,d),2.14(3H,s),3. 15 61(3H,s),4.63(2H,d),5.59(1H,m),6.15(1H,t),6.78-6.94(8H,m)

Production Example 12

By using 140 mg of the compound shown by the formula (x):

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instead of the compound shown by the formula (vii), and 70 ${\rm mg}$ of potassium carbonate and 70 mg of 1,1,3-trichloropropene, according to the similar method described in Production Example 9 was obtained 160 mg of the compound shown by the formula (12):

$$H_3C$$
 CH_2CH_3
 $O-CH_2CH=CCI_2$
 CH_3
 CH_3

(hereinafter, referred as the present invention compound (12)). 5 1 H-NMR(CDCl₃,TMS) δ (ppm):0.99(3H,t),2.20(3H,s),2.22(2H,q),3. 56(3H,s),4.64(2H,d),6.16(1H,t),6.82-6.95(8H,m)

Production Example 13

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By using 180 mg of the compound shown by the formula (xi):

instead of the compound shown by the formula (vii), and 90 mg of potassium carbonate and 100 mg of 1,1,3-trichloropropene, according to the similar method described in Production Example 9 was obtained 210 mg of the compound shown by the formula (13):

$$H_3C$$
 $C=CH_2$
 $O-CH_2CH=CCI_2$
 CH_3
 CH_3

(hereinafter, referred as the present invention compound (13)). 1 H-NMR(CDCl₃,TMS) δ (ppm):1.92(3H,m),2.31(3H,s),3.56(3H,s),4. 63(2H,d),4.94(1H,m),4.96(1H,m),6.15(1H,t),6.79-6.95(8H,m)

5 Production Example 14

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dissolved in 2 ml of N, N-dimethylformamide, 130 mg of potassium carbonate and 110 mg of 1,3-dichloropropene were added to the mixture, and the mixture was stirred at room temperature for ten hours. After that, the reaction mixture was added to dilute hydrochloric acid, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 300 mg of the compound shown by the formula (14):

$$H_3C$$
 $C=CH_2$
 $O-CH_2CH=CHCI$
 CH_3
 $O-CH_3$

as a mixture of geometric isomers(hereinafter, referred as the present invention compound (14)).

¹H-NMR(CDCl₃,TMS)δ(ppm):2.31(3H,s),3.58(3H,s),4.49(1H,dd),4 20 .74(1H,dd),5.01(1H,dd),5.27(1H,dd),6.03-6.39(3H,m),6.82-6.9 5(8H,m)

Production Example 15

0.42 ml of lithium diisopropylamide (2.0 mol/I

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heptane-tetrahydrofuran-ethylbenzene solution) was added to 870 mg of hexane solution which contained 10 % trimethyl silyldiazomethane at -78 °C,

and the mixture was stirred at same temperature for two hours. After that, 300 mg of the compound shown by the formula (ii) was added to the mixture at -78 °C with stirring, and the mixture was warmed to 0 °C over 3 hours with stirring. After that, saturated aqueous solution of ammonium chloride was added to the reaction mixture, and extracted with ethyl acetate. The organic layer was successively washed with

diluted hydrochloric acid, water and saturated brine; dried over magnesium sulfate; and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 260 mg of the compound shown by the formula (15):

$$H_3C$$
 $C \equiv CH$
 $O - CH_2CH = CCI_2$
 CH_3
 CH_3

(hereinafter, referred as the present invention compound (15)). ${}^{1}\text{H-NMR}(\text{CDCl}_{3},\text{TMS})\,\delta\,(\text{ppm}):2.26\,(3\text{H},\text{s})\,,2.99\,(1\text{H},\text{s})\,,3.64\,(3\text{H},\text{s})\,,4.}$ $64\,(2\text{H},\text{d})\,,6.16\,(1\text{H},\text{t})\,,6.85-7.01\,(8\text{H},\text{m})$

Production Example 16

180 mg of the compound shown by the formula (xiv):

$$H_3C$$
 CH_3
 CH_3
 CH_3
 CH_3

was dissolved in 2 ml of N,N-dimethylformamide, 100 mg of potassium carbonate and 100 mg of 1,1,3-trichloropropene were

added to the mixture, and the mixture was stirred at room temperature for ten hours. After that, the reaction mixture was added to dilute hydrochloric acid, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 220 mg of the compound shown by the formula (16):

(hereinafter, referred as the present invention compound (16)). 1 H-NMR(CDCl₃,TMS) δ (ppm):1.75(3H,s),2.17(3H,s),3.58(3H,s),4. 63(2H,d),6.16(1H,t),6.82-6.99(8H,m)

Production Example 17

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0.12 ml of lithium diisopropylamide (2.0 mol/L heptane-tetrahydrofuran-ethylbenzene solution) was added to 0.12 ml of hexane solution of trimethylsilyldiazomethane (2.0 mol/L) at -78 °C, and the mixture was stirred at same temperature for one hour. After that, 90 mg of the compound shown by the formula (xv):

$$H_3C$$
 $C-CH_3$
 $C-C$

20 was added to the mixture at $-78~^{\circ}\text{C}$ with stirring, and the mixture was warmed to 0 $^{\circ}\text{C}$ over 30 minutes with stirring, and stirred

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for two hours at 0 °C. After that, saturated aqueous solution of ammonium chloride was added to the reaction mixture, and extracted with ethyl acetate. The organic layer was successively washed with diluted hydrochloric acid, water and saturated brine; dried over magnesium sulfate; and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 40 mg of the compound shown by the formula (17):

$$H_3C$$
 $C \equiv CCH_3$
 $O \rightarrow O \rightarrow CH_2CH = CCI_2$
 CH_3
 CH_3

(hereinafter, referred as the present invention compound (17)). 1 H-NMR(CDCl₃,TMS) δ (ppm):1.88(3H,s),2.23(3H,s),3.61(3H,s),4. 64(2H,d),6.16(1H,t),6.81-7.00(8H,m)

Production Example 18

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100 mg of the compound shown by the formula (xvi):

was dissolved in 2 ml of N, N-dimethylformamide, 60 mg of potassium carbonate and 60 mg of 1,1,3-trichloropropene were added to the mixture, and the mixture was stirred at room temperature for ten hours. After that, the reaction mixture was added to dilute hydrochloric acid, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column

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chromatography to obtain 130 mg of the compound shown by the formula (18):

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(hereinafter, referred as the present invention compound (18)). 1 H-NMR(CDCl₃, TMS) δ (ppm): 2.19(3H,s), 3.67(3H,s), 4.65(2H,d), 5. 37(1H,s),6.16(1H,t),6.86-7.06(8H,m)

Production Example 19

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By using 200 mg of the compound shown by the formula (xvii):

instead of the compound shown by the formula (xvi), and 90 mg 10 of potassium carbonate, 90 mg of 1,1,3-trichloropropene and 2ml of N,N-dimethylformamide, according to the similar method described in Production Example 18 was obtained 260 mg of the compound shown by the formula (19):

(hereinafter, referred as the present invention compound (19)). 15 1 H-NMR(CDCl₃,TMS) δ (ppm):2.22(3H,s),3.65(3H,s),4.64(2H,d),6. 16(1H,t),6.84-6.99(8H,m)

Production Example 20

By using 400 mg of the compound shown by the formula

(xviii):

instead of the compound shown by the formula (xvi), and 200 mg of potassium carbonate, 210 mg of 1,1,3-trichloropropene and 5 ml of N,N-dimethylformamide, according to the similar method described in Production Example 18 was obtained 490 mg of the compound shown by the formula (20):

$$H_3C$$
 $CH_2CH_2CH_3$
 O
 O
 $CH_2CH=CCI_2$
 CH_3
 CH_3

(hereinafter, referred as the present invention compound (20)). 1 H-NMR(CDCl₃, TMS) δ (ppm):0.84(3H,t),1.40(2H,m),2.16(2H,t),2. 19(3H,s),3.56(3H,s),4.63(2H,d),6.16(1H,t),6.80-6.96(8H,m)

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Production Example 21

By using 140 mg of the compound shown by the formula (xix):

instead of the compound shown by the formula (xvi), and 70 mg of potassium carbonate, 70 mg of 1,1,3-trichloropropene and 2ml of N,N-dimethylformamide, according to the similar method described in Production Example 18 was obtained 140 mg of the compound shown by the formula (21):

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(hereinafter, referred as the present invention compound (21)). 1 H-NMR (CDCl₃, TMS) δ (ppm): 2.22(3H,s), 3.63(3H,s), 4.64(2H,d), 6. 16(1H,t), 6.84-6.97(8H,m)

5 Production Example 22

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By using 120 mg of the compound shown by the formula (xx):

instead of the compound shown by the formula (xvi), and 50 mg of potassium carbonate, 50 mg of 1,1,3-trichloropropene and 2ml of N,N-dimethylformamide according to the similar method described in Production Example 18 was obtained 130 mg of the compound shown by the formula (22):

(hereinafter, referred as the present invention compound (22)). 1 H-NMR(CDCl₃,TMS) δ (ppm):2.23(3H,s),3.67(3H,s),4.64(2H,d),6. 16(1H,t),6.83-6.99(8H,m)

Production Example 23

500 mg of the compound shown by the formula (ii) was dissolved 5 ml of chloroform, 400 mg of (dimethylamino) sulfur trifluoride was added to the mixture under ice cooling, and the

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mixture was stirred at room temperature for ten hours.

After that, saturated aqueous solution of sodium hydrogen carbonate was added to the reaction mixture, and extracted with ethylacetate. The organic layer was washed with saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 60 mg of the compound shown by the formula (23):

$$H_3C$$
 CF_2H
 $O-CH_2CH=CCI_2$
 CH_3
 CH_3

(hereinafter, referred as the present invention compound (23)). 1 H-NMR(CDCl₃,TMS) δ (ppm):2.34(3H,s),3.59(3H,s),4.64(2H,d),6. 1 16(1H,t),6.37(1H,t),6.85-6.98(8H,m)

Production Example 24

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dissolved in 2 ml of N,N-dimethylformamide, 110 mg of potassium carbonate and 120 mg of 1,3-dichloro-1-butene were added to the mixture, and the mixture was stirred at room temperature for ten hours. After that, the reaction mixture was added to dilute hydrochloric acid, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reducedpressure. The residue was subjected to silica gel column chromatography to obtain 230 mg of the compound shown by the formula (24):

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as a mixture of geometric isomers (hereinafter, referred as the present invention compound (24)).

¹ H-NMR (CDCl₃, TMS) δ (ppm): 1.75(3H, s), 2.17(6H, m), 3.58(3H, s), 4. 49(0.4H, m), 4.66(1.6H, m), 5.76(0.8H, m), 5.93(0.2H, m), 6.81-6.95 (8H, m)

Production Example 25

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dissolved in 2 ml of N,N-dimethylformamide, 50 mg of potassium carbonate and 40 mg of 3-chloropropene were added to the mixture, and the mixture was stirred at room temperature for ten hours. After that, the reaction mixture was added to dilute hydrochloric acid, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 150 mg of the compound shown by the formula (25):

(hereinafter, referred as the present invention compound (25)). $^{1}\text{H-NMR}(\text{CDCl}_{3},\text{TMS})\,\delta(\text{ppm}):1.75\,(3\text{H},\text{s})\,,2.17\,(3\text{H},\text{s})\,,3.58\,(3\text{H},\text{s})\,,4.$ $51\,(2\text{H},\text{m})\,,5.35\,(2\text{H},\text{m})\,,6.05\,(1\text{H},\text{m})\,,6.81-6.95\,(8\text{H},\text{m})$

Production Example 26

dissolved in 3 ml of N, N-dimethylformamide, 100 mg of potassium carbonate and 80 mg of 1-chloro-3-methyl-2-butene were added to the mixture, and the mixture was stirred at room temperature for ten hours. After that, the reaction mixture was added to dilute hydrochloric acid, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 210 mg of the compound shown by the formula (26):

(hereinafter, referred as the present invention compound (26)). 1 H-NMR(CDCl₃,TMS) δ (ppm):1.75(6H,m),1.80(3H,m),2.17(3H,s),3. 58(3H,s),4.48(2H,d),5.49(1H,m),6.80-6.99(8H,m)

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Production Example 27

190 mg of the compound shown by the formula (xxi):

was dissolved in 2 ml of N,N-dimethylformamide, 100 mg of potassium carbonate and 100 mg of 1,1,3-trichloropropene were added to the mixture, and the mixture was stirred at room temperature for ten hours. After that, the reaction mixture was added to dilute hydrochloric acid, and extracted with ethyl

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acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 200 mg of the compound shown by the formula (27):

$$\begin{array}{c|c} H_3CH_2C & CH_3 \\ \hline N_N & O & O - CH_2CH=CCI_2 \end{array} \qquad (27)$$

(hereinafter, referred as the present invention compound (27)). 1 H-NMR(CDCl₃, TMS) δ (ppm):1.23(3H,t),1.77(3H,s),2.56(2H,q),3. 59(3H,s),4.64(2H,d),6.16(1H,t),6.83-6.96(8H,m)

10 Production Example 28

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140 mg of the compound shown by the formula (xxii):

$$F_3C$$
 CH_3
 CH_3
 CH_3
 CH_3
 CH_3

was dissolved in 2 ml of N, N-dimethylformamide, 70 mg of potassium carbonate and 70 mg of 1,1,3-trichloropropene were added to the mixture, and the mixture was stirred at room temperature for ten hours. After that, the reaction mixture was added to dilute hydrochloric acid, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 170 mg of the compound shown by the formula (28):

$$F_3C \xrightarrow{CH_3} O - O - CH_2CH=CCI_2$$

$$CH_3 \qquad (2.8)$$

(hereinafter, referred as the present invention compound (28)). 1 H-NMR(CDCl₃,TMS) δ (ppm):1.91(3H,s),3.70(3H,s),4.64(2H,d),6. 16(1H,t),6.83-6.96(8H,m)

5 Production Example 29

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120 mg of the compound shown by the formula (xxiii):

was dissolved in 2 ml of N, N-dimethyl formamide, 70 mg of potassium carbonate and 70 mg of 1,1,3-trichloropropene were added to the mixture, and the mixture was stirred at room temperature for ten hours. After that, the reaction mixture was added to dilute hydrochloric acid, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 160 mg of the compound shown by the formula (29):

$$H_3C$$
 CH_3
 (hereinafter, referred as the present invention compound (29)). 1 H-NMR(CDCl₃, TMS) δ (ppm): 1.74(3H,s), 2.17(3H,s), 3.55(3H,s), 4. 65(2H,d), 6.15(1H,t), 6.78-6.87(4H,m), 7.19-7.23(2H,m), 7.32-7.

36(2H,m)

Production Example 30

140 mg of the compound shown by the formula (xxiv):

was dissolved in 2 ml of N, N-dimethyl formamide, 80 mg of potassium carbonate and 80 mg of 1,1,3-trichloropropene were added to the mixture, and the mixture was stirred at room temperature for ten hours. After that, the reaction mixture was added to dilute hydrochloric acid, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reducedpressure. The residue was subjected to silicagel column chromatography to obtain 160 mg of the compound shown by the formula (30):

$$H_3C$$
 CH_3
 (hereinafter, referred as the present invention compound (30)). ${}^{1}H-NMR(CDCl_{3},TMS)\delta(ppm):1.73(3H,s),2.17(3H,s),3.55(3H,s),3.$ 87(2H,s),4.63(2H,d),6.15(1H,t),6.78-6.83(4H,m),7.07-7.11(4H,m)

Next, the compound which was used to produce the compound of the present invention describes the reference production examples. Some of these reference production examples are also

the production example of the intermediate compound of the present invention.

Reference Production Example 1

200 mg of the compound shown by the formula (xii):

Reference Production Example 2

300 mg of 4,4'-dihydroxybiphenylether shown by the formula:

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was dissolved in 5 ml of N, N-dimethylformamide, 120 mg of sodium hydride (60% in oil) ice-cooling under ice cooling, and was stirred at room temperature for ten minutues. After that, to

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the saidmixture was added 3 ml of N, N-dimethylformamide solution of 230 mg of 5-chloro-1, 3-dimethyl-1H-pyrazole-4-carbaldehyde shown by the formula:

$$H_3C$$
 $N-N$
 CHO
 CHO
 CHO
 CHO

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over ten minutes at 70 °C, and then the mixture was stirred at 70 °C for two hours. After that, water and 10% hydrochloric acid were added to the reaction mixture which was cooled to room temperature, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 260 mg of the compound shown by the formula (xii).

¹H-NMR(CDCl₃,TMS)δ(ppm):2.45(3H,s),3.66(3H,s),5.44(1H,br),6 .76-6.99(8H,m),9.50(1H,s)

Reference Production Example 3

2.0 g of the compound shown by the formula (ii) was dissolved in 3 ml of pyridine, 0.35 g of hydroxylamine hydrochloride was added to the mixture under ice cooling, and then the mixture stirred thirty minutes at room temperature. After that, the reaction mixture was concentrated under reduced pressure. Water and 10 % hydrocloric acid were added to the residue, and was extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried

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overmagnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 2.0 g of the compound shown by the formula (i). $^{1}\text{H-NMR}(\text{CDCl}_{3},\text{TMS})\,\delta\,(\text{ppm}):2.36\,(3\text{H,s})\,,3.61\,(3\text{H,s})\,,4.64\,(2\text{H,d})\,,6.16\,(1\text{H,t})\,,6.84-6.96\,(8\text{H,m})\,,7.08\,(1\text{H,s})\,,7.83\,(1\text{H,s})$

Reference Production Example 4

0.19 g of sodium hydride (55% in oil) was suspended to of N, N-dimethylformaide, and 1.03 10 ml οf 4,4'-dihydroxybiphenylether was added to the suspension under ice-cooling, and the mixture was stirred at 70 $^{\circ}\text{C}$ for thirty minutes. After that, to the said mixture was added 5 ml of of 0.64 of solution N, N-dimethylformamide 5-chloro-1,3-dimethyl-1H-pyrazole-4-carboxylic acid methyl ester shown by the formula:

$$H_3C$$
 I
 N
 C
 $COOCH_3$
 CH_3

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over thirty minutes at 70 °C, and then the mixture was stirred at 70 °C for ten hours. After that, saturated aqueous solution of ammonium chloride was added to the reaction mixture which was cooled to room temperature, and extracted with ethyl acetate. The organic layer was successively washed with diluted hydrochloric acid, water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 0.19 g of the compound shown by the formula (iii).

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 1 H-NMR(CDCl₃,TMS) δ (ppm):2.44(3H,s),3.63(3H,s),3.64(3H,s),4. 91(1H,br),6.79-6.91(8H,m)

Reference Production Example 5

dissolved to 3 ml of toluene, and 2 ml of aqueous solution of sodium hydroxide (1 mole/L) was added to the mixture, and the mixture was stirred at 80 °C for two hours. After that, the reaction mixture was cooled to room temperature, toluene was added to the reaction mixture, and extracted with aqueous solution of sodium hydroxide (1 mole/L). The aqueous layer was acidified by adding concentrated hydrochloric acid, and extracted by ethyl acetate. The organic layer was successively washed with diluted hydrochloric acid, water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure, to obtain 110 mg of the compound shown by the formula (iv).

 1 H-NMR((CD₃)₂SO,TMS) δ (ppm):2.29(3H,s),3.52(3H,s),6.71-6.87(8H,m),9.34(1H,br)

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Reference Production Example 6

0.43 g of sodium hydride (55% in oil) was suspended to 1.57 of N, N-dimethylformaide, and 10 of ml 4,4'-dihydroxybiphenylether was added to the suspension under ice-cooling, and the mixture was stirred at 70 °C for thirty minutes. After that, to the said mixture was added 5 ml of of 1.43 of N, N-dimethylformamide solution 5-chloro-1,3-dimethyl-1H-pyrazole-4-carboxylic acid ethyl

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ester shown by the formula:

over thirty minutes at 70 °C, and then the mixture was stirred at 70 °C for ten hours. After that, saturated aqueous solution of ammonium chloride was added to the reaction mixture which was cooled to room temperature, and extracted with ethyl acetate. The organic layer was successively washed with diluted hydrochloric acid, water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 0.85 g of the compound shown by the formula (v). $^{1}\text{H-NMR}(\text{CDCl}_{3},\text{TMS})\,\delta(\text{ppm}):1.07(3\text{H,t}),2.46(3\text{H,s}),3.65(3\text{H,s}),4.$ 10(2H,q),6.44(1H,br),6.76-6.91(8H,m)

15 Reference Production Example 7

2.2 g of methyltriphenylphosphonium bromide was suspended to 5 ml of tetrahydrofuran, 3.9 ml of hexane solution of normal butyllithium (1.58 mole/L) was dropped to the suspension, and then the mixture was stirred at room temperature for thirty minutes. 1.0 g of the compound shown by the formula (xii) was added to the mixture, and then refluxed for one hour. After that, saturated aqueous solution of ammonium chloride was added to the reaction mixture which was cooled to room temperature, and extracted with ethyl acetate. The organic layer was successively washed with diluted hydrochloric acid, water and

saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 0.9 g of the compound shown by the formula (vi).

5 ¹H-NMR(CDCl₃,TMS)δ(ppm):2.31(3H,s),3.58(3H,s),5.03(1H,dd),5 .28(1H,dd),6.02(1H,br),6.32(1H,dd),6.77-6.92(8H,m)

Reference Production Example 8

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dissolved to 1 ml of tetrahydrofuran, 0.8 ml of hexane solution of normal butyllithium (1.58 mole/L) was dropped to the solution, and then the mixture was stirred at room temperature for thirty minutes. 100 mg of the compound shown by the formula (xii) was added to the mixture, and then stirred at room temperature for three hours. After that, saturated aqueous solution of ammonium chloride was added to the reaction mixture, and extracted with ethyl acetate. The organic layer was successively washed with diluted hydrochloric acid, water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 130 mg of the compound shown by the formula (vii) as mixture of geometric isomers.

 1 H-NMR(CDCl₃, TMS) δ (ppm):1.63(1.5H,dd),1.73(1.5H,dd),2.17(1.5H,s),2.28(1.5H,s),3.55(1.5H,s),3.62(1.5H,s),5.58(0.5H,m),5.78(0.5H,m),5.86(0.5H,m),5.98(0.5H,m),6.77-6.90(8H,m)

Reference Production Example 9

260 mg of propyltriphenylphosphonium bromide was

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suspended to 1 ml of tetrahydrofuran, 0.6 ml of hexane solution of normal butyllithium (1.58 mole/L) was dropped to the solution, and then the mixture was stirred at room temperature for thirty minutes. 150 mg of the compound shown by the formula (xii) was added to the mixture, and then stirred at room temperature for three hours. After that, saturated aqueous solution of ammonium chloride was added to the reaction mixture, and extracted with ethyl acetate. The organic layer was successively washed with diluted hydrochloric acid, water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. 10 The residue was subjected to silica gel column chromatography to obtain 170 mg of the compound shown by the formula (viii) as mixture of geometric isomers.

 1 H-NMR(CDCl₃,TMS) δ (ppm):0.93(3H,m),2.04(2H,m),2.17(2.1H,s), 2.28(0.9H,s),3.57(0.9H,s),3.61(2.1H,s),5.45(0.7H,m),5.78(1H 15 ,m),5.9(0.3H,m),6.76-6.94(8H,m)

Reference Production Example 10

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400 mg of isopropyltriphenylphosphonium iodide was suspended to 2 ml of tetrahydrofuran, 0.6 ml of hexane solution of normal butyllithium (1.58 mole/L) was dropped to the solution, and then the mixture was stirred at room temperature for thirty minutes. 150 mg of the compound shown by the formula (xii) was added to the mixture, and then stirred at room temperature for three hours. After that, saturated aqueous solution of ammonium chloride was added to the reaction mixture, and extracted with ethyl acetate. The organic layer was successively washed with diluted hydrochloric acid, water and saturated brine, dried over

magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 110 mg of the compound shown by the formula (ix). $^{1}\text{H-NMR}(\text{CDCl}_{3},\text{TMS})\delta(\text{ppm}):1.60(3H,d),1.71(3H,d),2.14(3H,s),3.$ 60(3H,s),5.59(1H,m),6.76-6.94(8H,m)

Reference Production Example 11

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The compound shown by the formula (vi) was dissolved to 15 ml of methanol, to the solution was added 20 mg of 10 % palladium-carbon, and then the mixture was stirred vigorously under hydrogen atmosphere at room temperature for six hours. After that, ethyl acetate was added to the reaction mixture, and was filtered. Filtrate was concentrated under reduced pressure to obtain 790 mg of the compound shown by the formula (x).

 1 H-NMR(CDCl₃,TMS) δ (ppm):0.99(3H,t),2.21(3H,s),2.23(2H,q),3. 56(3H,s),6.77-6.91(8H,m)

Reference Production Example 12

20 470 mg of methyltriphenylphosphonium bromide was suspended to 2 ml of tetrahydrofuran, 2.5 ml of hexane solution of normal butyllithium (1.58 mole/L) was dropped to the suspension, and then the mixture was stirred at room temperature for one hour. 200 mg of the compound shown by the formula (xiii):

was added to the mixture, and then refluxed for four hours. After that, saturated aqueous solution of ammonium chloride was added to the reaction mixture which was cooled to room temperature, and extracted with ethyl acetate. The organic layer was successively washed with diluted hydrochloric acid, water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silicate column chromatography to obtain 180 mg of the compound shown by the formula (xi).

10 1 H-NMR(CDCl₃,TMS) δ (ppm):1.92(3H,m),2.31(3H,s),3.56(3H,s),4. 78(1H,s),4.94(1H,m),4.96(1H,m),6.79-6.90(8H,m)

Reference Production Example 13

15 10 ml of N,N-dimethylformaide, 140 mg of sodium hydride (60% in oil) was added to the solution under ice-cooling, and then the mixture was stirred at 70 °C for one hour. After that, to the said mixture was added 5 ml of N,N-dimethylformamide solution of 400 mg of 1-(5-chloro-1,3-dimethyl-1H-pyrazo-4-yl) ethanone shown by the formula:

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over fifteen minutes at 70 °C, and then the mixture was stirred at 70 °C for six hours. After that, diluted hydrochloric acid was added to the reaction mixture which was cooled to room temperature, and extracted with ethyl acetate. The organic

layer was successively washed with diluted hydrochloric acid, water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 340 mg of the compound shown by the formula (xiii).

 1 H-NMR (CDCl₃, TMS) δ (ppm):2.26(3H,s),2.47(3H,s),3.57(3H,s),5. 22(1H,s),6.79-6.95(8H,m)

Reference Production Example 14

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3.0 g of the compound shown by the formula (xii):

was dissolved to 30 ml of di (ethylene glycol), 0.51 g of hydrazine hydrate and 1.1 g of potassium hydroxide were added, and then stirred at 80 °C for one hour, and at 180 °C for one hour. After that, the reaction mixture which was cooled to room temparature was acidified by adding diluted hydrochloric acid, and extracted by ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 1.9 g of the compound shown by the formula (xiv).

$$H_3C$$
 CH_3
 CH_3
 CH_3
 CH_3

 1 H-NMR(CDCl₃,TMS) δ (ppm):1.75(3H,s),2.18(3H,s),3.58(3H,s),6. 27(1H,br),6.80-6.90(8H,m)

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Reference Production Example 15

270 mg of the compound shown by the formula (xiii):

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was dissolved in 2 ml of N,N-dimethylformamide, 150 mg of potassium carbonate and 140 mg of 1,1,3-trichloropropene were added to the mixture, and the mixture was stirred at room temperature for ten hours. After that, diluted hydrochloric acid was added to the reaction mixture, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 350 mg of the compound shown by the formula (xv).

 1 H-NMR (CDCl₃, TMS) δ (ppm): 2.25(3H,s), 2.47(3H,s), 3.57(3H,s), 4. 64(2H,d),6.16(1H,t),6.81-6.97(8H,m) 15

Reference Production Example 16

1.5 g of the compound shown by the formula (v):

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was suspended to 15 ml of toluene. The suspension was dissolved at 80 °C, 12 ml of aqueous solution of sodium hydroxide (1 mole/L) was added to the solution, and the mixture refluxed for two hours. After that the reaction mixture was cooled to room temperature, standed and separated to two phase. To the aquous layer, 10 ml of water was added, and then 15 ml of concentrated hydrochloric acid was added. 15 ml of toluene was added to the mixture and refluxed for seven hours. The mixture was cooled to room temperature, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 1.1 gof the compound shown by the formula (xvi).

¹ H-NMR (CDCl₃, TMS) δ (ppm):2.19(3H,s),3.67(3H,s),4.96(1H,br),5 .37(1H,s),6.80-7.05(8H,m)

20 Reference Production Example 17

300 mg of the compound shown by the formula (xvi) was dissolved 2 ml of N,N-dimethylformamide, added 200 mg of N-bromosuccinimide to the solution under ice-cooling, and then the mixture was stirred at 0 $^{\circ}$ C for one hour. After that, water

was added to the reaction mixture, and extracted with ethyl acetate. The organic layer was successively washed with diluted hydrochloric acid, water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure.

- The residue was recrystallized to obtain 340 mg of the compound 5 shown by the formula (xvii).
 - 1 H-NMR(CDCl₃, TMS) δ (ppm):2.22(3H,s),3.64(3H,s),4.69(1H,br),6 .79-6.92(8H,m)
- Reference Production Example 18 10

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690 mg of the compound shown by the formula (viii):

$$H_3C$$
 H_3C
 was dissolved 10 ml of ethyl acetate, to the solution was added 140 mg of 10 % palladium-carbon, and then the mixture was stirred vigorously under hydrogen atmosphere at room temperature for five hours. After that ethyl acetate was added to the reaction mixture, and was filtered. Filtrate was concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 690 mg of the compound shown by the formula (xviii).

$$\begin{array}{c|c} & CH_2CH_2CH_3 \\ \hline & N & O & O & O \\ \hline & CH_3 & & (xviii) \\ \end{array}$$

 1 H-NMR(CDCl₃,TMS) δ (ppm):0.83(3H,t),1.40(2H,m),2.16(2H,t),2. 20 19(3H,s),3.56(3H,s),5.34(1H,br),6.79-6.90(8H,m)

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Reference Production Example 19

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dissolved 2 ml of N,N-dimethylformamide, added 110 mg of N-chlorosuccinimide to the solution under ice-cooling, and then the mixture was stirred at room temperature for ten hours. After that water was added to the reaction mixture, and extracted with ethyl acetate. The organic layer was successively washed with diluted hydrochloric acid, water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was recrystallized to obtain 190 mg of the compound shown by the formula (xix).

$$H_3C$$
 CI
 CH_3
 CH_3
 CH_3
 CH_3

 1 H-NMR (CDCl₃, TMS) δ (ppm):2.22(3H,s),3.63(3H,s),4.82(1H,br),6.77-6.92(8H,m)

15 Reference Production Example 20

dissolved 2 ml of N,N-dimethylformamide, added 110 mg of N-iodosuccinimide to the solution under ice-cooling, and then the mixture was stirred at 0 °C for three hours. After that, water was added to the reaction mixture, and extracted with ethyl acetate. The organic layer was successively washed with diluted hydrochloric acid, water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 180 mg of the compound shown by the formula (xx).

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 1 H-NMR(CDCl₃, TMS) δ (ppm):2.23(3H,s),3.67(3H,s),4.74(1H,br),6 .79-6.93(8H,m)

Reference Production Example 21

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400 mg of the compound shown by the formula (xxv):

was dissolved to 5 ml of di (ethylene glycol), 90 mg of hydrazine hydrate and 150 mg of potassium hydroxide were added, and then stirred at 80 °C for ten minutes, and at 180 °C for one hour. After that the reaction mixture was acidified by adding diluted hydrochloric acid, and extracted by ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 340 mg of the compound shown by the formula (xxi).

$$H_3CH_2C$$
 CH_3
 CH_3
 CH_3
 CH_3

 1 H-NMR(CDCl₃,TMS) δ (ppm):1.23(3H,t),1.77(3H,s),2.57(2H,q),3. 58(3H,s),4.80(1H,br),6.77-6.91(8H,m)

Reference Production Example 22

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500 mg of the compound shown by the formula (xxvi):

was dissolved to 5 ml of di (ethylene glycol), 130 mg of hydrazine hydrate and 160 mg of potassium hydroxide were added, and then stirred at 80 °C for ten minutes, and at 180 °C for one hour. After that the reaction mixture was acidified by adding diluted hydrochloric acid, and extracted by ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 140 mg of the compound shown by the formula (xxii).

 1 H-NMR(CDCl₃,TMS) δ (ppm):1.91(3H,s),3.70(3H,s),4.80(1H,br),6 .77-6.98(8H,m)

15 Reference Production Example 23

200 mg of the compound shown by the formula ($xx \forall ii$):

was dissolved to 5 ml of di (ethylene glycol), 60 mg of hydrazine hydrate and 70 mg of potassium hydroxide were added, and then stirred at 80 $^{\circ}$ C for one hour, and at 180 $^{\circ}$ C for one hour. After

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that the reaction mixture was acidified by adding diluted hydrochloric acid, and extracted by ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 130 mg of the compound shown by the formula (xxiii).

 1 H-NMR (CDCl₃, TMS) δ (ppm):1.74(3H,s),2.17(3H,s),3.55(3H,s),5. 32(1H,br),6.78-6.82(4H,m),7.17-7.19(2H,m),7.30-7.32(2H,m)

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Reference Production Example 24

200 mg of the compound shown by the formula (xxviii):

$$H_3C$$
 N
 O
 CH_3
 CHO
 CH_3
 CHO
 CH_3
 CHO
 $CXXVIII)$

was dissolved to 5 ml of di (ethylene glycol), 60 mg of hydrazine hydrate and 70 mg of potassium hydroxide were added, and then stirred at 80 °C for one hour, and at 180 °C for one hour. After that the reaction mixture was acidified by adding diluted hydrochloric acid, and extracted by ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 150 mg of the compound shown by the formula (xxiv).

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$$H_3C$$
 CH_3
 CH_3
 CH_3
 CH_3
 CH_3

 1 H-NMR(CDCl₃, TMS) δ (ppm):1.74(3H,s),2.17(3H,s),3.55(3H,s),3.86(2H,s),5.00(1H,br),6.74-6.81(4H,m),7.02-7.10(4H,m)

Reference Production Example 25

500 mg of 4,4'-dihydroxybiphenylether was dissolved to 5 ml of N,N-dimethylformaide, 200 mg of sodium hydride (60% in oil) was added to the solution under ice-cooling, and then the mixture was stirred at room temperature for ten minutues. After that, to the said mixture was added 5 ml of N,N-dimethylformamide solution of 410 mg of

5-chloro-3-ethyl-1-methyl-1H-pyrazol-4-carbaldehyde shown by the formula:

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over ten minutes at 70 °C, and then the mixture was stirred at 70 °C for two hours. After that, water and 10 % hydrochloric acid were added to the reaction mixture which was cooled to room temperature, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 460 mg of the compound shown by the formula (xxv).

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 1 H-NMR(CDCl₃,TMS) δ (ppm):9.51(1H,s),6.79-6.94(8H,m),5.44(1H,s),3.66(3H,s),2.86(2H,q),1.27(3H,t)

Reference Production Example 26

570~mg of 4,4'-dihydroxybiphenylether was dissolved to 5~ml of N,N-dimethylformaide, 170~mg of sodium hydride (60% in oil) was added to the solution under ice-cooling, and then the mixture was stirred at room temperature for ten minutues. After that, to the said mixture was added 5~ml of N,N-dimethylformamide solution of 570~mg of

5-chloro-1-methyl-3-trifluoromethyl-1H-pyrazol-4-carbaldehy de shown by the formula:

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over ten minutes at 70 °C, and then the mixture was stirred at 70 °C for two hours. After that, water and 10 % hydrochloric acid were added to the reaction mixture which was cooled to room temperature, and extracted with ethyl acetate. The organic layer was successively washed with water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 440 mg of the compound shown by the formula (xxvi).

177

 1 H-NMR(CDCl₃,TMS) δ (ppm):9.66(1H,s),6.79-6.93(8H,m),4.95(1H,s),3.81(3H,s)

Reference Production Example 27

0.4 g of sodium hydride (60% in oil) was suspended to $15\,\mathrm{ml}$ of N,N-dimethylformamide, $1.5\,\mathrm{g}$ of 4,4'-tiodiphenol shown by the formula:

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was added at room temperature, and then the mixture stirred at 70 °C for one hour. After that, to the said mixture was added 5 ml of N,N-dimethylformamide solution of 1.0 g of 5-chloro-1,3-dimethyl-1H-pyrazole-4-carbaldehyde over ten minutes at 70 °C, and then the mixture was stirred at 70 °C for eight hours. After that, aqueous solution of saturated ammonium chloride was added to the reaction mixture which was cooled to room temperature, and extracted with ethyl acetate. The organic layer was successively washed with diluted hydrochloric acid, water and saturated brine, dried over

The residue was subjected to silica gel column chromatography to obtain 1.8 g of the compound shown by the formula (xxvii).

magnesium sulfate, and concentrated under reduced pressure.

¹ H-NMR (CDCl₃, TMS) δ (ppm): 2.45(3H,s), 3.63(3H,s), 6.82-6.90(4H, m), 7.15-7.36(4H,m), 9.53(1H,s)

Reference Production Example 28

0.4 g of sodium hydride (60% in oil) was suspended to 5 N, N-dimethylformamide, 15 1.3 g of of ml bis(4-hydroxyphenyl) methane was added at room temperature, and then the mixture stirred at 70 °C for two hours. After that, to the said mixture was added 5 ml of N, N-dimethylformamide 1.0 οf 10 solution of g 5-chloro-1, 3-dimethyl-1H-pyrazole-4-carbaldehyde over ten minutes at 70 °C, and then the mixture was stirred at 70 ℃ for seven hours. After that, aqueous solution of saturated ammonium chloride was added to the reaction mixture which was 15 cooled to room temperature, and extracted with ethyl acetate. The organic layer was successively washed with diluted hydrochloric acid, water and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure. The residue was subjected to silica gel column chromatography to obtain 1.2 g of the compound shown by the formula (xxviii). 20

$$H_3C$$
 CHO
 CH_2
 CH_3
 CHO
 CH_3
 CHO
 CH_3
 CHO
 CH_3

¹ H-NMR (CDCl₃, TMS) δ (ppm): 2.45(3H,s), 3.63(3H,s), 3.88(2H,s), 6.75-6.78(2H,m), 6.90-6.92(2H,m), 7.02-7.04(2H,m), 7.13-7.15(2H,m), 9.51(1H,s)

Reference Production Example 29

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200 g of 1,3-dimethyl-5-pyrazolone was dissolved to 156g of N,N-dimethylformamide. 629 g of phosphorous oxychloride was added to the mixture at room tempareture, and then strried at 90 $^{\circ}$ C for three hours. After the reaction mixture was cooled to room tempareture, the reaction mixture was poured into water, and extracted with ethyl acetate.

The organic layer was successively washed with water, saturated aquous solution of sodium hydrogen carbonate, and saturated brine, dried over magnesium sulfate, and concentrated under reduced pressure to obtain 223 g of 5-chloro-1,3-dimethyl-1H-pyrazole-4-carbaldehyde.

 1 H-NMR(CDCl₃, TMS) δ (ppm):2.45(3H,s),3.84(3H,s),9.86(1H,s)

Next, formulation examples are described below. Parts represent parts by weight.

Formulation Example 1

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10 parts of each of the present invention compounds (1) to (30) is dissolved in 35 parts of xylene and 35 parts of N,N-dimethylformamide, and 14 parts of polyoxyethylene styryl phenyl ether and 6 parts of calcium dodecylbenzenesulfonate are added thereto, followed by well stirring and mixing, to give 10% emulsifiable concentrate for each compound.

Formulation Example 2

20 parts of each of the present invention compounds (1) to (30) is added to a mixture containing 4 parts of sodium laurylsulfate, 2 parts of calcium lignin sulfonate, 20 parts of synthetic hydrated silicone oxide fine powder, and 54 parts

180

of diatomaceous earth, followed by well stirring and mixing, to give 20% wettable powder for each compound.

Formulation Example 3

To 2 parts of each of the present invention compounds (1) to (30) are added 1 part of synthetic hydrated silicon oxide fine powder, 2 parts of calcium lignin sulfonate, 30 parts of bentonite, and 65 parts of kaolin clay, followed by well stirring and mixing, and an appropriate amount of water is added to this mixture, followed by further stirring, granulation with a granulator, and air drying, to give 2% granule for each compound.

Formulation Example 4

1 part of each of the present invention compounds (1) to (30) is dissolved in an appropriate amount of acetone, and 5 parts of synthetic hydrated silicon oxide fine powder, 0.3 part of PAP, and 93.7 parts of Fubasami clay are well stirring and mixing, and acetone is removed by evaporation from the mixture, to give 1% dust for each compound.

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Formulation Example 5

10 parts of each of the present invention compounds (1) to (30), 35 parts of white carbon containing 50 parts of polyoxyethylene alkyl ether sulfate ammonium salt, and 55 parts of water are mixed and pulverized by the wet grinding method to give 10% flowable for each compound.

Formulation Example 6

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0.1 part of each of the present invention compounds (1) to (30) is dissolved in a mixture of 5 parts of xylene and 5 parts of trichloroethane, and the resulting solution is mixed with 89.9 parts of deodorized kerosine to give 0.1% oil solution.

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Formulation Example 7

10 mg of each of the present invention compounds (1) to (30) is dissolved in 0.5 ml of acetone, the solution is applied to 5 g of powdery solid animal food (powdery solid animal food for bleeding CE-2; a product of CLEA Japan, Inc.) and mixed uniformly, and and acetone is removed by evaporation from the mixture, to give a poison bait for each compound.

The following test example will demonstrate the noxious arthropod pests controlling activity of the compound of the present invention.

Test Example 1

The formulation obtained according to Formulation Example 1 using the present invention compounds (1) to (30) and the comparative comparative compound (a) described below respectively, was diluted with water so that the concentration of the present invention compound or the comparative compound came to 200ppm.

About twenty female adults of *Tetranychus urticae* were set free on brush bean (*Phaseolus vulgaris*) in the primary leaf stage, which had been potted in a plastic cup for 7 days after the seeding. After 1 day, a 30 ml of the diluted formulation described-above was sprayed over the plant. On the 8th and 13th

day after the application, the numbers of lived Tetranychus urticae on the leaf of brush bean plant were examined, and the Controlling Rates were calculated by the following scheme.

Controlling Rate = 100 X {1- (a number of lived Tetranychus
urticae in the treatment) / (a number of lived Tetranychus urticae
in the non-treatment)}

As a result, in the treatment of the present invention compounds (1) to (30), all of the Controlling rates were not less than 90% on 8th day and 13th day after the application.

On the other hand, in the treatment of the comparative compound (a), the Controlling rates were less than 30 % on 8th day and 13th day after the application.

Comparative compound (a)

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which is disclosed as the Compound No. 189 in the Japan Laid-Open Patent spesification sho 63-183564A, p.21.

Test Example 2

20 The formulation obtained according to Formulation Example 1 using the present invention compound (25):

$$H_3C$$
 CH_3
 $O-CH_2CH=CH_2$
 CH_3
 CH_3

and the comparative compound (b) described below respectively, was diluted with water so that the concentration of the present

invention compound or the comparative compound came to 200ppm.

30 ml of the diluted formulation described above was sprayed over the seedling of apple, which had been potted in plastic cup for 28 days after seeding about 15 cm height. After the sprayed solution was dried, about sixty first-instar larvae of Adoxophyes orana fasciata were set free on the apple seedling. On the 7 th day after application, the number of surviving or dyed Adoxophyes orana fasciata on the apple seedling was examined, and the rate of dead pests was calculated.

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As a result, in the treatment of the present invention compound (25), the rate of dead pests was 90 % or more. On the other hand, in the treatment of the comparative compound (b), the rate of dead pests was less than 80 %.

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Comparative compound (b)

$$H_3C$$
 CHO
 CH_3
 CH_3
 CHO
 CH_3

which is disclosed as the Compound No. 23 in the Japan Laid-Open Patent spesification sho 62-53970A, p.3.

20 Industrial Applicability

The compound of the present invention is useful to control pests.